ACADEMIC CURRICULA

UNDERGRADUATE/ INTEGRATED POST GRADUATE DEGREE PROGRAMMES

(With exit option of Diploma)

(Choice Based Flexible Credit System)

Regulations 2021

Volume - 19 (Syllabi for Nanotechnology Programme Courses)

Revised on July 2024



SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

Kattankulathur, Chengalpattu District 603203, Tamil Nadu, India

ACADEMIC CURRICULA

Engineering Science Course

Regulations 2021



SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

Kattankulathur, Chengalpattu District 603203, Tamil Nadu, India

Course	24NTC204T Course	MATERIALS SCIENCE	Course	ENGINEERING SCIENCE	L	Т	Р	(;
Code	Name Name	MATERIALS SCIENCE	Category	ENGINEERING SCIENCE	3	0	0	3	į

Pre-requisite Courses	Ni	Co- requisite Courses	NI	ressive urses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	11	4			Progr	am Oı	ıtcome	s (PO)					rogram
CLR-1:	understand the structure of	f crystalline mat <mark>erials</mark>	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	CLR-2: gain knowledge on the basics of material structures, properties and strength of materials				17	ф	1	ety			~					
CLR-3:					nt of	ions	Φ	society	, 1		Work		Finance			
clr-4: acquire knowledge on polymer nanocomposites, biomaterials, catalytic materials and corrosion and degradation of materials			ering Knowle	alysis	n/development	investigations problems	Usag	er and	t &		Team	tion	∞ర	earning		
CLR-5: introduce the working principle of various characterization techniques				roblem Analysis	Jn/deve	luct inversion	Aodern Tool Usage	engineer	Environment 8 Sustainability	S	ndividual &	communication	ct Mgt.	Long Le	-	ن ا ن
Course Outcomes (CO): At the end of this course, learners will be able to:		ingi	Probl	Designation	Conduct	Моде	The	Envir Susta	Ethics	ndivi	Som	Project	-ife L	-SO-1	PSO-2	
CO-1:	acquire the knowledge on	structure of crystalline materials	3	10	lk sy	2	- 1	1			-	-	-	-	2	
CO-2:	acquire the ability to idention of materials	ify <mark>enginee</mark> ring problems using plastic deformation, fatigue, fracture and creep	3	3	1	4	-	3) -	-:	-	-	-	-	3	
CO-3: understand the basic ideas about ceramics, polymers and non-crystalline solid		3	100		2	-	-	. -		-	-	-	-	-	2 -	
CO-4:	appreciate the concepts of reinforced matrix interface, corrosion parameters and uses of various nanocomposite		3	2	الزيا	3 -	_	Ċ	-	-	-	-	-	-	-	3 -
CO-5:			3		-	3	7		-	-	-	-	-	-	-	- 3

Unit-1 - Structure of Crystalline Materials

9 Hour

Introduction to materials-crystalline and amorphous-Single crystalline and polycrystalline Materials-Concept of basis and lattice, Lattice translational vectors-Primitive cell and Bravais lattice-Seven types of Bravais lattices-Symmetry operations in crystals-Rotational and translational symmetry-Point and Space groups-Indexing of crystal planes-Miller indices-directions and planes-Various planes in cubic structure-Directions in cubic structure-Packing of atoms inside solids-packing fraction in HCP-Diamond structure-APF-Cubic Zinc-Sulfide structure

Unit-2 - Defects and Material Properties

y Hour

Imperfections in solids: point defects- Equilibrium concentration of vacancies- Interstitial impurities in solids- Substitutional impurities in solids- Line defects: edge dislocations- Screw dislocations- Surface and volume imperfections- Interfacial defects, stacking faults- Elastic properties-Hooke's law- Yield strength- Tensile strength- Ductile and brittle materials- Stress strain behavior of metals- Stress strain behavior of ceramics and Polymers- Tensile test, plastic deformation- Concept of necking- FatigueCreep behavior

Unit-3 - Non-Crystalline Materials, Ceramics, Polymers and Copolymers

9 Hour

Semi-crystalline materials: introduction and classification- Structure and configuration of ceramics- Advanced ceramics-functional properties- Mechanical behavior of ceramics-flexural strength- Fabrication and processing of advanced ceramicsApplications of advanced ceramic materials- Glass ceramics-introduction- Glass forming and glass tempering- Polymers-classification- Thermoplastic and thermosetting polymers- Mechanical behavior of polymers- macroscopic deformati- Polymer synthesis-addition and condensation polymerization- Concept of copolymers- Applications of polymers- Types of liquid crystals- Construction and working of LCD- Non-crystalline materials-metallic glass- Glass transition-melting and glass transition temperature

Unit-4 - Polymer Nanocomposites, Biomaterials, Catalytic Materials

9 Hour

Introduction to composites- Classification of composites- Polymer nanocomposites materials- Polymer-matrix composites- Fiber-reinforced composites- Metal-matrix composites- Carbon-carbon composites- Degradation of polymers- Recycling of polymers- Corrosion of metals, forms of corrosion- Corrosion prevention- Biomaterials-introduction- Classification of biomaterials- Surface properties of biomaterials- Mechanical properties of biomaterials- Catalytic biomaterials – silica, enzymatic Hydrogels- Applications of biomaterials

Unit-5 - Materials Characterization Tools

9 Hour

Introduction to experimental techniques- X-Ray Diffraction (Single Crystal method- Scanning Ion Conductance Microscopy- principle- Scanning Ion Conductance Microscopy- construction and working- Molecular and spectroscopic analysis introduction- FTIR spectroscopy- Concept of Raman spectroscopy- Raman spectroscopy- instrumentation- XPS spectroscopy-concept- XPS spectroscopy- instrumentation- Introduction to Nuclear Magnetic Resonance (NMR)- Nuclear Magnetic Resonance (NMR)- Instrumentation- Introduction to Thermal analysis- Differential Thermal Analyses (DTA)- Differential Scanning Calorimetry (DSC)-Dynamic light scattering- Particle Size Analysis

Learning
Resources

- 1. V. Raghavan, Materials Science and Engineering: A First Course, 5th ed., Prentice Hall India. 2004.
- 2. WilliamD.Callister, Materials Science and Engineering, AnIntroduction, John Wiley & Sons, 2007
- 3. Kingery, W.D., Bowen H.K., Uhlmann, D.R., Introduction to Ceramics, 2nded., John Wiley & Sons, 1976.
- 4. Upadhyaya and A. Upadhyaya, Material Science and Engineering, Anshan Publications, 2007

Learning Assessme	nt			
		Continuous Learnin	g Assessment (CLA)	Summative
	Bloom <mark>'s</mark> Level of <mark>Thinking</mark>	Formative CLA-1 Average of unit test (50%)	Life-Long Learning CLA-2 (10%)	Final Examination (40% weightage)
	2 5	Theory Practice	Theory Practice	Theory Practice
Level 1	Remember	20%	20%	20% -
Level 2	Understand	20%	- 20%	20% -
Level 3	Apply	30%	30% -	30% -
Level 4	Analyze	30%	- 30%	- 30%
Level 5	Evaluate		Carrier State	-
Level 6	Create	2 - 200 32 - 10		-
	Tot <mark>al</mark>	100 %	100 %	100 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Narayanasvamy Vijayan, National Phy <mark>sical Lab</mark> oratory,	1. Prof. V. Subramaniam, IITM Chennai, manianvs@iitm.ac.in	1. Dr. C. Pr <mark>eferenci</mark> al Kala, SRMIST
nvijayan@nplindia.org	S. C. British	
2. Dr. M. Krishna Surendra, Saint-Gobain Research, Chennai,	2. Prof. D. Arivuoli, Anna University, arivuoli@annauniv.edu	2. San <mark>deep Kum</mark> ar Lakhera, SRMIST
krishna.muvvala@saint-gobain.com	Marian Marian	

ACADEMIC CURRICULA

Professional Core Courses

Regulations 2021



SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

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Kattankulathur, Chengalpattu District 603203, Tamil Nadu, India

Course	21NTC201J	Course	NANOSCALE MATERIALS CHEMISTRY	Course	(DDOEESSIONAL CODE	L	Т	Р	С
Code	2111102013	Name	NANOSCALE MATERIALS CHEMISTRE	Category	C	PROFESSIONAL CORE	3	0	2	4

Pre-requisite Courses	N	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	H.,	7		· . ·	Progra	am Oı	ıtcome	s (PC))					gram
CLR-1:	understand the role of chem	istry in nanopa <mark>rticle synthes</mark> is	1	2	3	4	5	6	7	8	9	10	11	12		cific omes
CLR-2:	LR-2: enhance knowledge about Symmetry and lattice parameters					ъ		ety			~					
CLR-3:	CLR-3: acquire knowledge about size effects, reaction kinetics and phase properties at nanoscale					ions	Φ	society			Work		Finance			
CLR-3: acquire knowledge about size effects, reaction kinetics and phase properties at nanoscale CLR-4: improve their ability in understanding and explore the subject to nanostructures and nanosystems					bme	tigat	Sag	and			Team	_	Fina	earning.		
CLR-5:						A S S S S S S S S S S S S S S S S S S S	∞ŏ	ommunication	communication Project Mgt. &							
			Ingineering	roblem)/ugi	Conduct	lern	eng	ironi	જ	ndividual	nmr	ect	Long	7 3	7 5
Course O	Course Outcomes (CO): At the end of this course, learners will be able to:		Eng	P. P.	Des		Moc	The	Env	Ethics	ndi	Son	Proj	Life	PSO	PSO-3
CO-1:		er <mark>standing</mark> the behavior of nanomaterials based on its chemistry Demonstralits application in lattice determination	е з	3	No.	+	- ,	4	-		-	-	-	-	3	
CO-2:							- (-	-		-	-	-	-	2	
CO-3:	define the existence of sur classifications and properties	<mark>rface an</mark> d their significance in explaining various systems and evaluate the sof surfactants	e 3	1	2	-	- [-	-		-	-	-	-	3	
CO-4:	demonstrate the mechanism	ns involved behind the different chemical routes involved in the synthesis	of 3	1	2	-	- 5		-		-	-	-	-	3	
CO-5:	develop their ability in understanding the behavior of nanomaterials based on its chemistry Demonstrate symmetry, point groups and its application in lattice determination			-	2	-	F	7	7	-	-	-	-	-	-	2 -

Unit-1 - Chemistry of Nanoparticles Synthesis

15 Hour

Chemical bonding and surface properties: Introduction to chemical bonding - Atomic bonding, types of bond: metallic, ionic bond - Covalent and Vander Waals bond - Surface energy, chemical potential as a function of curvature - Electrostatic stabilization - Surface charge density - Electric potential at the proximity at solidsurface - Vander Waals attraction potential - DLVO theory and steric stabilization - Influence of kinetic energy on the surface of nanomaterials. 1. Introduction to the basics of laboratory, 2. Synthesis of silica nanospheres using stober's method, 3. Synthesis of gold nanoparticles by chemical reduction Determination of absorption coefficient using UV-Vis spectrometer

Unit-2 - Symmetry and Lattice Parameters

15 Hour

Materials Structure and Features of Nanoscale Growth: Space lattice and unit cells, crystal system, symmetry operation - Structures of common metallic, semiconductor ceramic and superconductor materials - Miller indices, representation of directions - Planes packing fractions, structure determination using X-raydiffraction - Silicates and clay structures, glass transition temperature - Non-crystalline materials, imperfections in nanostructured materials - Specific features of nanoscale growth, size control, triggering the phase transition - Application to solid nanoparticles controlling nucleation, controlling growth -controlling aggregation, stability of colloidal dispersions - breaking matter into pieces. 1. Synthesis of ferro fluids using chemical precipitation, 2. Synthesis of metal oxide nanoparticles using sol-gel technique and crystallite size measurement by XRD, 3. Synthesis of zinc sulfide quantum dot using co-precipitation method

Unit-3 - Size Effects and Reaction Kinetics

15 Hour

Classification and Nomenclature of Nanomaterials: Nanosized metals and alloys – semiconductors – ceramics - a comparison with respective bulk materials -- Organic semiconductors - carbon materials - Zero-, one, two and three dimensional nanostructures - quantum dots - quantum wells - quantum rods - quantum wires - quantum rings - bulk nanostructured – nanocomposites - Nanomachines and Devices - Organic

Nanoparticles - structure, types of NP - analytical methods (Extraction and isolation, Separation, Characterization and Imaging) - general method of preparation, properties, detection, and characterization of organic nanoparticles - cyclodextrine, polysaccharides. Nanocochleates, Prospects and Future Challenges. 1. Synthesis of photocatalytic solution using co-precipitation method, 2. Repeat/Revision of experiments, 3. Synthesis of nanoparticles loaded polymer fibers using electrospinning technique and study of surface morphology using SEM

Unit-4 - Surface and its Properties

15 Hour

Surface Nanoscience and Chemistry aspects: Intermolecular Forces, Van der Waals forces (Kessorn, Debye, and London Interactions) - Dynamic properties of interfaces - Contact angle - Brownian motion - Brownian Flocculation - Surface active agents - Theory and applications - Types of surfactants - Anionic, cationic, zwitterionic& non-ionic - synthesis of surfactant - CMC - Effect of chemical structure, temperature; Kraft temperature; Emulsions & gels surfactant geometry and packing - Photochemistry and Electrochemistry of nanomaterials - Ionic properties of nanomaterials - Nanocatalysis - Nanoscale heat transfer - Electron transport in transition metals and semiconducting nanostructure. 1. Low temperature synthesis of metal nanoparticles, 2. Preparation of nanoparticles using sonochemical method, 3. Fabrication of polymer membrane using phase inversion technique and characterization using scanning electron microscope (SEM) technique

Unit-5 - Various Chemical Synthesis Routes

15 Hou

Chemical synthesis: Introduction to different synthesis route of nanoparticles - Overview on precipitative methods - Chemical precipitation and co-precipitation methods to synthesize nanomaterials - Chemical reduction method to synthesize metallic nanocrystals - Metathesis to prepare nanoparticles - Steps involved in Sol-gel synthesis - Reaction mechanisms: Hydrolysis and Polycondensation - Introduction to micelles, reverse micelles, and microemulsions - Synthesis of nanomaterials using microemulsion route - Preparation of inorganic nanomaterials using hydrothermal and solvothermal routes - Preparation of arrays of oxide nanocrystals using thermolysis route - Microwave heating assisted synthesis of nanomaterials - Sonochemical synthesis of nanometals - Core-shell synthesis of semiconductor nanocrystals - Electrochemical synthesis of nanoparticles - Photochemical synthesis of nanoparticles, 1. Synthesis of iron oxide nanoparticles using precipitation method, 2. Microwave assisted polymerization synthesis of ZnO nanowires, 3. Hydrothermal synthesis of ZnS Nanorods: Nanorods: Nanorods formation by SEM analysis

Learning Resources

- Peter Atkins, Julio de Paula, Atkins' Physical Chemistry, seventh edition, Oxford University Press (2004)
- 2. C. N. Rao, A. Muller, A. K. Cheetham, "Nanomaterials chemistry", Wiley-VCH ,2007
- A.W. Adamson and A.P.Gast, Physical Chemistry of surfaces, Wiley Interscience, NY 2004.
- 1. Guozhong Cao, Ying Wang, "Nanostructure<mark>s and N</mark>anomaterials: Synthesis, Properties, and Applications", World Scientific, 2011
- 5. C. Brechignac, P. Houdy, M. Lahmani, "Nanomaterials and Nanochemistry", Springer publication ,2007
- 6. Kenneth J. Klabunde, "Nanoscale materials in chemistry", Wiley Interscience Publications , 2001

Learning Assessm	ent	T W/ 333		E Training of the		9				
		1 1 To 1 1 To 2	Continuous Learning	g Assessment (CLA)		Cump	notivo			
	Bloo <mark>m's</mark> Level of T <mark>hinking</mark>	Form CLA-1 Averag (45	ge of unit test	Life-Long CLA (15	4-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	- 12%	-	20%	20%	-			
Level 2	Understand	20%	4.00		20%	20%	-			
Level 3	Apply	40%	-	75 -	40%	40%	-			
Level 4	Analyze	20%	ARNILL	4 D	20%	20%	-			
Level 5	Evaluate	12134	Trace Till	$AP \cdot JFA$		-	-			
Level 6	Create	- F		- Antark	7-0-	-	-			
	Total	100	1%	100	%	100) %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. C. Suresh, CSIR-Central Electro Chemical Research Institute,	1. Dr.S. Easwaramoorthi, Senior Scientist, Inorganic &	1. Dr. N.Angeline Little Flower, SRMIST
Karaikudi-630003, India csuresh@cecri.res.in	Physical Chemistry, CLRI Adayar moorthi@clri.res.in,	
2. Dr. P. Sudhakar, CLRI – CSIR, Jalandhar, sudhakarp@clri.res.in	2. Dr.Arthanreeswaran, NIT, Trichy, arthanreeg@nitt.edu	2. Dr. Venkata Ravindra, SRMIST

Course	21NTC202T	Course	QUANTUM MECHANICS FOR NANOTECHNOLOGISTS	Course	_	PROFESSIONAL CORE	L	Т	Р	С	
Code	2111102021	Name	QUANTUM MECHANICS FOR NANOTECHNOLOGISTS	Category)	FROFESSIONAL CORE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course Lo	earning Rationale (CLR):	The purpose of learning this course is to:	Η.	4 .		F	rogra	am Ou	itcome	es (PC))					rograi	
CLR-1:	the state of the s			2	3	4	5	6	7	8	9	10	11	12		pecifi itcom	
CLR-2:	R-2: analyze the bound and scattering states				of	SL	1	-	N.		ork		8				
CLR-3:	utilize quantum physics behir	nd appli <mark>cations - N</mark> ano dimension	Knowledge	S	velopment	investigations ex problems	age	ъ			M ≥		Finance	Вu			ł
CLR-4:	solve the many body problem	ns usin <mark>g variou</mark> s assumptions		Analysis	lopr	estig probl	ol Usage	er and	× ×		Team	tion	∞ర	arning			ł
CLR-5:	identify the implications of qu	antu <mark>m theory</mark> and approximations at Nano scale	neering	em An	e .	Ψ.	P	engineer stv	onment inability		dual &	ommunication	Project Mgt.	Long Le	_	2	က
Course O	urse Outcomes (CO): At the end of this course, learners will be able to:				Desig	Conduct of compl	Modern	The e	Environme Sustainabi	Ethics	Individual	Comn	Projec	Life L	PS0-1	PSO-2	PSO-3
CO-1:	avalain the need for developing quantum machanics and basics; basic non-relativistic quantum machanics;				100	2	F	Z.	-		-	-	-	-	3	-	-
CO-2:	apply principles of guantum mechanics to calculate observables on known wave functions: Salva time					3	- (0	-		-	-	-	-	2	-	-
CO-3:					j 1- 1	3	- 1	-	-	-	-	-	-	-	3	-	-
CO-4:	to solve simple problems				1-3	3	- (-		-	-	-	-	-	2	-
CO-5:	critically evaluate and interpret cross sections classical and quantal approaches to scattering and the			-	-	3	ď	5	-		-	-	-	-	-	3	-

Unit-1 - Quantum Mechanics in Nanotechnology

9 Hour

Importance of quantum mechanics in nanotechnology, Failures of classical mechanics, Basic ideas of quantum mechanics, wave particle Duality-Heisenberg uncertainty principle- Generalized Heisenberg uncertainty principle- Ehrenfest theorem- Linear vector space- Hilbert space- Statistical interpretation, stationary states- Orthogonal wave function- Normalization of wave function- Hermitian operator- Properties of Hermitian operator- Commutation- Energy eigen value equation- Boundary condition of wave function- Schrödinger's time dependent wave Equations- Schrödinger's time independent wave Equations- Schrödinger's representation, interaction picture

Unit-2 - Bound and Scattering States

9 Hour

Classical interpretation of scattering state- Quantum interpretation of scattering State- Reflection of particles (wavefunction)- Transmission of Particles (wavefunction)- Rectangular potential barrier (E<V0): quantitative- Rectangular potential barrier (E>V0)- Transmission probability plot as a function of energy of particle- Numericals in rectangular potential barrier- Tunneling effect- Relation of tunneling with nanotechnology- Alpha-particle emission- Failure of Classical Mechanics to explain Alpha-particle emission- Derivation on Alpha-particle emission- Numericals in particle emission- Resonant tunneling- Applications of resonant tunneling- Negative differential resistance- Negative differential resistance in 2D materials

Unit-3 - Quantum Physics Applications- NanoDimenstion

9 Hour

Energy eigen functions and eigen values with precession coordinates- Infinite well potential in one dimension- Numericals on infinite well potential in one and three dimensions- Quantum confinement effect in nanoscale- Finite Well Potential, Delta potential- Eigen values, Schrödinger equation in spherical coordinates- Angular equation- Introduction on radial equation- Derivation of radial equation- Infinite spherical well- Numerical on infinite spherical well- Ground state properties of hydrogen atom- Angular momentum (Lx,Ly,Lz)- Angular momentum (Lx,Ly,Lz) in spherical coordinate- Generalized angular momentum (Jx,Jy,Jz), Eigen values of momentum operator- Spin ½, spin for two particle system- Role of spin in nanospintronics

Unit-4 - Solving Many Body Problems

9 Hour

Principle of variational method- Proof of variational method and Implementation- Energy eigen value in case of time independent perturbation theory for non- degenerate energy levels- Eigen function in case of time independent perturbation theory for non-degenerate energy levels- Eigen function in case of time independent perturbation theory for non-degenerate energy levels- Eigen function in case of time independent perturbation theory for non-degenerate energy levels- (quantitative approach)- Energy eigen value in case of Time independent perturbation theory for degenerate energy levels- Quantitative approach of energy eigen value in case of Time independent perturbation theory for two-level systems- Quantitative approach of eigen Function in case of Time dependent perturbation theory for two-level systems- Sinusoidal perturbations (quantitative approach)- Incoherent perturbation- Role of incoherent perturbation- Transition rate- Transition rate role is perturbation- Adiabatic approximations (elementary concepts)- Sudden approximations (elementary concepts)

Unit-5 - Implications of Quantum Theory and Approximations at Nano scale

9 Hour

Two particle system's Schrödinger Equation- Derivation of two particle system's Schrödinger equation- Transformation to center of mass frame from laboratory frame- Exchange operator- Symmetrization of wave function- Antisymmetric wave function- Bosons and Fermions- Exchange forces- Solids, free electron gas- Band structure of solids- Quantum scattering theory- Applications in nanotechnology- Overall role and implication of quantumphenomena in nanotechnology (Low-Dimensional Quantum Systems, properties of quantum dots, Mesoscopic systems and disorder in them, Kondo effect, Graphene)

Learning	1. G. Aruldhas, Quantum Mechanics, 2nd ed., PHI, 2013	3. Ajoy Ghatak, S. Lokanathan, Quantum Mechanics, 6th ed., Macmillan, 2009
Resources	2. David J. Griffiths, Introduction to Quantum Mechanics, 2nd ed., Pearson, 2009	4. Bransden B.H., Joachain C.J. Quantum Mechanics, 2nd ed., Pearson, 2000

Learning Assessm	nent			THE PARTY IN						
			Continuous Learnin	g Assessment (CLA)		Cuma	mativa			
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	CLA-1 Avera	native age of unit test 0%)	CL	g Learning .A-2 0%)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	12 Table 25	20%		20%	-			
Level 2	Understand	20%	N. 19 J. P	20%		20%	-			
Level 3	Apply	30%	10 mar - 42 N	30%		30%	-			
Level 4	Analyze	30%		30%		30%	-			
Level 5	Evaluate		The state of the s	A service of	7.0		-			
Level 6	Create		···	· -	-4	- 1	-			
	Tota <mark>l</mark>	10	0 %	10	0 %	100	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. Noriaki Terakubo, Jgc Corporation, Japan,	Dr. Uday Narayan Maiti, IITG Guwahati, udaymaiti@gmail.com	1. Dr. Kiran Mangalampalli, SRMIST
terakubo.noriaki@jgc.co.jp	VITEARA - FEAR TRIPLE	
2. Mr. R. Seshadri, TITAN Company Limited, seshadri@titan.co.in	2. Dr. Noejung Park, Ulsan National Institute of Science and	2. Dr. Debabrata Sarkar, SRMIST
	Technology,noejung@unist.ac.kr	

Course	21NTC203T Course	THERMODYNAMICS AND STATISTICAL MECHANICS	Course		PROFESSIONAL CORE	L	T	Р	С	;
Code	Name	THERMODYNAMICS AND STATISTICAL MECHANICS	Category	C	PROFESSIONAL CORE	3	0	0	3	,

Pre-requisite Courses	N	Co- requisite Courses	Nil	Progressive Courses	Nil	
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil	
·			THE PARTY OF THE P			

Course L	Learning Rationale (CLR): The purpose of learning this course is to: utilize the basic principles and laws of thermodynamics identify the thermodynamic properties of pure substances and different kinds of equilibrium utilize the concept of ensembles and classical statistics analyze the concepts of quantum statistics analyze the principles of Nano thermodynamics, Apply the concepts of non-equilibrium thermodynamics Nano scale systems			4			- T	Progra	ım Oı	ıtcome	s (PC))				Prog	
CLR-1:	identify the thermodynamic properties of pure substances and different kinds of equilibrium utilize the concept of ensembles and classical statistics analyze the concepts of quantum statistics analyze the principles of Nano thermodynamics, Apply the concepts of non-equilibrium thermodynamics				2	3	4	5	6	7	8	9	10	11	12	Spe Outco	
CLR-2:	identify the thermodynamic p	roperties o <mark>f pure subs</mark> tances and different kinds of equilibrium		a)		1	of	1	ciety			~					
CLR-3:				ering Knowledge		nt of	ions	- Φ	socie			Work		Finance			
CLR-4:	R-4: analyze the concepts of quantum statistics				Sis	pme	stigations Ilems	Sag	and			eam	_		earning		
CLR-5:	analyze the principles of Nano thermodynamics, Apply the concepts of non-equilibrium thermodynamics to				roblem Analysis	ign/development tions	inve	ern Tool Usage	engineer a	Environment & Sustainability	S	ndividual & Te	ommunication	ct Mgt. &	ong Lear	- σ	4 (ن
Course C	urse Outcomes (CO): At the end of this course, learners will be able to:			Engine	Prob	Designation of the solution of	□ ⊏	Modern	The (Envir Susta	Ethics	ndiv	Com	Project	Life L	PSO-1	80
CO-1:	describe various thermodyna	mic processes and concepts explained by laws		3	3	No.	4.	-	L	-	Н	_	-	-	-	2	. -
CO-2:	analyze the concepts of enth	alpy, entropy, chemical potential, fugacity	1 .	3	3		- }-	- 7	-	-		-	-	-	-	3 -	
CO-3:	3: describe the postulates of statistical mechanics			3	3	-	-	- 1	-	-		-	-	-	-	- 2	2 -
CO-4:	enumerate on Bose-Einstein condensation and Fermi gas			3	1		3	- 1	-	-		-	-	-	-	- 3	} -
CO-5:	describe the concept of Hill's	Nano thermodynamics, Analyze the fluctuations in small systems	4	3	9	1.0	3	- (-		-	-	-	-	- 2	2 -

Unit-1 - Basic Principles and Laws Principles and Laws of Thermodynamics

9 Hour

Properties of a thermodynamic system- concept of system and boundaries - Concept of continuum - Thermodynamic equilibrium - Path and point functions - Extensive and intensive properties - Zeroth law of thermodynamics and concept of temperature - Energy transfer by heat and work - Isothermal process - Adiabatic process - Isochoric process - Isobaric process - First law of thermodynamics - Specific Heat at constant Pressure and constant volume - Second law of thermodynamics - Reversibility, irreversibility and Carnot cycle - Reversed Carnot Cycle as a refrigeration cycle- Third law of thermodynamics - Unattainability of absolute zero.

Unit-2 - Thermodynamic Properties and Equations

9 Hour

Thermodynamic properties of pure substances in solid, liquid, vapor phases - Phase diagrams of a pure substance - Gibb's phase rule - Different kinds of equilibrium - Entropy and energy criteria for equilibrium - Ideal gas equation of a state - Deviation from ideal gas behavior - VanderWaal's equation of state - Law of corresponding states - Determination of critical constants - Temperature and entropy (T-dS) relations - Helmholtz Function Gibbs Function - General Thermodynamic equations - Joule-Thomson coefficient - Co-efficient of volume expansion - Adiabatic and isothermal compressibility - Clapeyron equations - Clausius equations.

Unit-3 - Ensembles and Classical Statistics

9 Hour

Fundamentals of statistical physics- microscopic approach - Concept of phase space - Concept of gamma space and μ space - Volumes in phase space - Difference between microstate and macrostate - Most probable distribution - Equal apriori probability and ergodicity - Ensemble averages - Derivation of Boltzmann equation S=KlnW - Thermodynamics of Ensembles - Canonical Ensemble and its thermodynamic parameters - Microcanonical Ensemble and its thermodynamic parameters - Stirling Approximation - Classification of statistical distributions - Maxwell-Boltzmann distribution for classical particles - Concept of degrees of freedom - Law of equipartition of energy - Specific heat capacities of gases.

Unit-4 - Concepts of Quantum Statistics

9 Hour

Quantum statistics for identical particles - Distinguishable and indistinguishable particles - Grand canonical ensemble - Determination of Gibbs factor - Photons in an oven - Principle of detailed balance - Energy flux - Structureless Bose gas - Bose Einstein distribution law for bosons - Bose-Einstein condensation - Observation of BECs of cold atoms - Superfluid liquid helium - Fermi gases for electrons - Fermi energy - Fermi Dirac distribution law for fermions - Fermions at low temperatures - Comparison of 3 statistics

Unit-5 - Thermodynamics for Nano systems

9 Hour

Thermodynamics of small systems and Gibbs equation for nanosystems - Features of Hill's nanothermodynamics - Comparison with classical equilibrium thermodynamics - Nanoensemble and its thermodynamic parameters - Gibbs energy of single-component nanoparticles - Fluctuations in small systems - Jarzyanki's inequality - Classical nucleation thermodynamics - Phase diagrams of small systems - Thermodynamics of metastable phase nucleation at the nanoscale - Nanoscale thermodynamic approach in CVD diamond - Nucleation thermodynamics of cubic boron nitride - Nonextensivity of nanosystems - Nonintensivity of nanosystems - Principles of non-equilibriumThermodynamics - Concept of Pseudo equilibrium - Self organization - Benard cells

Learning	
Resources	
. 10000	

- Keith Stowe, "An Introduction to Thermodynamics and Statistical Mechanics", Cambridge University, New York, 2007
- Richard E.Sonntag, Gordon J.VanWylen, "Introduction to Thermodynamics, Classical and Statistical", Wiley Publishing, 2010
- 3. Yunus. A.Cengel, Michael Boles, "Thermodynamics-An Engineering Approach", Tata McGraw Hill. New Delhi. 2008
- 4. Pathria, R. K., Statistical Mechanics, Oxford: Pergamon Press, 1972

Learning Assessm	nent		will be a		THE PARTY						
•	Bloo <mark>m's</mark> Level of <mark>Thinkin</mark> g	7.1	Formative CLA-1 Average of (50%)	A P Marin Inc.	CL	Learning A-2 9%)	Summative Final Examination (40% weightage)				
	2	33	Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember		20%	77.5	20%		20%	-			
Level 2	Understand		20%	737 2	20%	N -	20%	-			
Level 3	Apply		30%		30%		30%	-			
Level 4	Analyze		30%		30%		30%	-			
Level 5	Evaluate				1			-			
Level 6	Create			- 1977	?	- 4	-	-			
	Total	-	100 %	1.7	100	0 %	100	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	I <mark>nternal E</mark> xperts
1. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.c	org 1. Prof. V. Subramaniam, IITM, Chennai, manianvs@iitm.ac.in	1. Dr.R.Annie Sujatha, SRMIST
2. Dr. C. Suresh, CSIR-Central Electro Chemical Research Institute,	2. Prof. C. Venkateswaran, Univ. of Madras, cvenkateswaran@unom.ac.in	2. Dr.Bhaskar Behera, SRMIST
Karaikudi-630003, India csuresh@cecri.res.in	Monney MONEY FAIR	

Course	24NTC2041 Course	ADVANCED CHARACTERIZATION OF NANOMATERIALS	Course	_	PROFESSIONAL CORE	L	Т	Р	С	
Code	21NTC204J Name	ADVANCED CHARACTERIZATION OF NANOMATERIALS	Category	U	PROFESSIONAL CORE	3	0	2	4	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil	
Course Offer	ing Department	Physics and Nanotechnolog	gy Data Book / Codes / Sta	andards	Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	// ·	4		Ī	rogra	<mark>ım</mark> Oı	utcome	es (PC	0)					rogra	
CLR-1:	utilize the concepts of optica	I imaging and <mark>characterize</mark> nanomaterials	1.	2	3	4	5	6	7	8	9	10	11	12		pecifi utcom	
CLR-2:	analyze morphology and ele	ments of nanomaterials using SEM and ED's technique	Knowledge		of	of		ety	N.		~						
CLR-3:	CLR-3: analyze nanomaterial TEM, RHEED, LEED, XRD						Φ	society	١,		Work		ance				
CLR-4:	777						sag	and			Team	_	& Finance	earning			
CLR-5:	asses the advanced techniques VPS AES and SIMS for solving problems in materials science and					t investigations x problems	Tool Usage	engineer a	ment & ability		∞ర	ommunication					
Cauraa						Conduct	Aodern	The en	Environm <mark>e</mark> S <mark>ustain</mark> abi	Ethics	ndividual	Jmmc	Project Mgt.	ife Long	30-1	-SO-2	SO-3
Course Outcomes (CO): At the end of this course, learners will be able to:					م ۾	8 8	Σ	È	<u>ந</u> ல	Ψ	<u> </u>	ŏ	Ā	Ξ	PS	<u>8</u>	ď
CO-1:	explain the principles of option	c <mark>al imagi</mark> ng and perform microstructural analysis	3		3	2		7-	-	-	-	-	-	-	3	-	-
CO-2:	describe the construction and operation of SEM and EDS characterization techniques and analyzed morphology and elements of a nanomaterial					3	- (3	-		-	-	-	-	3	-	-
CO-3:	explain the construction and	-3	1	3	-	- 1	-	-		-	-	-	-	-	2	-	
CO-4:	3					3	- 7		-	-	-	-	-	-	-	3	-
CO-5:	describe the working principles of XPS, AES and SIMS techniques, Apply the skills acquired for advanced experimental characterization					-	-2	7	-		-	-	-	-	-	-	2

Unit-1 - Optical Imaging Techniques for Nanomaterials Characterization

15 Hour

Image formation, numerical aperture, resolution, effective magnification, Brightness and contrast, depth of field, aberrations, Instrumentation: illumination system, objective lens and eyepiece, Steps for optimum resolution, steps to improve depth of field, Imaging modes: bright-field and dark-field imaging, Kohler illumination, Phase-contrast microscopy, The behavior of waves from phase objects in brightfield microscopy, Properties of polarized light, Polarized-light microscopy, Differential interference contrast microscopy and modulation contrast microscopy: DIC optical system, Modulation contrast microscopy, Physical basis of fluorescence, Fluorescence microscopy, Confocal laser scanning microscopy: the optical principle of confocal imaging, Techniques for improving imaging of nanoscale materials, Diffraction limit, Breaking the diffraction limit

Lab 1: Introduction to the basics of laboratory, Lab 2: Optical microscope-based investigation of microfabricated structures, Lab 3: Bioimaging using fluorescence microscopy

Unit-2 - Scanning Electron Microscopy and Compositional Analysis of Nanomaterials

15 Hour

Scanning electron microscopy, electron optics, imaging with electrons, Magnetic and electrostatic lenses, Signal detection Detector, Probe size and current, Electron–specimen interactions, Topographic contrast, Compositional contrast, working distance and aperture size, Acceleration voltage and probe current, Astigmatism, Specimen preparation, Elemental imaging using EDS, Applications of elemental imaging, Field emission SEM, Environmental SEM, Time resolved microscopy and Applications

Lab 4: Morphological study of nanostructured material using SEM, Lab 5: SE and BSE imaging with SEM, Lab 6: EDS for chemical identification

Unit-3 - Anaysis of Nanomaterials Using Transmission Electron Microscopy and Diffraction Tools

15 Hour

TEM imaging system, Instrumentation of TEM, Electron sources, Specimen stage and specimen preparation, Kinematics of scattering by nucleus, Electron – electron scattering, Image modes: Mass—density contrast, Diffraction contrast, phase contrast Selected-area diffraction (SAD) and characteristics, Single-crystal diffraction, polycrystalline diffraction, Dark field images, Phase control, High resolution images, Interpretation of

high-resolution images, Ultrahigh resolution TEM, Dynamic TEM, z-contrast imaging, Coherent and incoherent imaging, Reflection High Energy Diffraction (RHEED), Low Energy Electron Diffraction (LEED), X-ray Diffraction (XRD) Lab 7: Imaging and analysis using transmission electron microscope, Lab 8: Selected area electron diffraction (SAED) using TEM, Lab 9: Grain Size determination from XRD

Unit-4 - Scanning Probe Microscopy Techniques in Nanotechnology

15 Hour

Scanning probe microscopy, Scanning probe microscopy; Instrumentation, Scanning tunnelling microscopy, tunnelling current, Probe tips and working environments, Scanning tunnelling Spectroscopy (STS), Atomic force microscopy, Cantilevers and deflection measurements, Contact AFM. Non-contact AFM. Dynamic contact AFM, Taping AFM, Force modulation, Manipulation of atoms, Advanced SPM techniques, Kelvin probe force microscopy. Scanning capacitance microscopy. Scanning thermal microscopy. Magnetic force microscopy Piezoelectric force microscopy.

Lab 10: Tunnelling current measurements using scanning tunnelling microscope (STM), Lab 11: Nanoparticle size determination using atomic force microscopy (AFM)

Lab 12: Surface morphology by STM and roughness determination by AFM

Unit-5 - Spectroscopy Tools for Nanomaterials Characterization

15 Hour

Basic principles: X-ray photoelectron spectroscopy (XPS), Auger electron spectroscopy (AES), Instrumentation: XPS, Instrumentation: AES, Photoelectron spectra, Auger electron spectra, Qualitative analysis, Peak identification, chemical shifts composition imaging, Quantitative analysis: peaks and sensitivity factors, Composition depth profiling, Secondary ion mass spectrometry (SIMS): Basic principles, Secondary ion generation, Dynamic and static SIMS, SIMS -instrumentation, Sample handling Spectrum interpretation, Element identification SIMS depth profiling

Lab 13: Interpretation of XPS spectra, Lab 14: Peak identification of in AES spectra, analysis of the AES depth profile, Lab 15: Analysis of SIMS profile spectra

Learning Resources
Resources

- 1. Douglas B. Murphy, Michael W. Davidson, Fundamentals of light microscopy and 4. Ray, F. Egerton, Physical principles of electron microscopy, Springer, 2005 electronic imaging, 2nd ed., John Wiley & Sons, 2013
- 2. Yang Leng, Materials characterization, introduction to microscopic and spectroscopic methods, 2nd ed., Wiley, 2013
- 3. Guy Cox. Optical imaging techniques in cell biology. CRC press. 2012

- 5. Bharat Bhusan, Scanning probe microscopy in nano-science and nanotechnology, Springer,
- 6. Nan Yao, Zhong Lin Wang, Handbook of microscopy for nanotechnology, Kluwer Academic Publisher, 2005

Learning Assessm	ent	257777	THE PERSON NAMED IN	 But Wileys 			
		100 CC	Continuous Learning	g Assessment (CLA)		Cum	matius.
	Blo <mark>om's</mark> Level of <mark>Thinking</mark>	CLA-1 Avera	native age of unit test 5%)	CL	n Learning A-2 5%)	Final Exa	native amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	- 1	-	20%	20%	-
Level 2	Understand	20%	- 1/1/	-	20%	20%	=
Level 3	Apply	40%	- /3%	-	40%	40%	-
Level 4	Analyze	20%			20%	20%	-
Level 5	Evaluate	<- C				-	-
Level 6	Create	7/11/	TARA-II	4 D		-	-
	Total	10	00 %	100	0 %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr.N.Vijayan, CSIR-NPL, nvijayan@nplindia.org	1. Dr. K.Ganesan, IGCAR, Kalpakkam, kganesan@igcar.gov.in	1. Dr.Jitendra Kumar Tripathi, SRM IST
2. Mr. K.R.Navaneethakrishnan, GLR Laboratories Pvt Ltd	2. Dr. Ashutosh Rath, CSIR-Institute of Minerals and Materials	2. Dr.S.Chandramohan, SRM IST
	Technology, Bhubaneswar, ashutosh@immt.res.in	

Course	21NTC205T Course	DESIGN AND SYNTHESIS OF NANOMATERIALS	Course	_	PROFESSIONAL CORE	L	Τ	Р	С	
Code	Name	DESIGN AND STRITLESIS OF NANOWATERIALS	Category	U	PROFESSIONAL CORE	3	1	0	4	

Pre-requisite Courses	Nil	Co- requisite Courses	Nil	Progressive Courses		Nil
Course Offering Depart	ment	Physics and Nanotechnology	Data Book / Codes / Standards		•	Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	11				F	rogra	<mark>am</mark> Ou	itcome	s (PO))					ogra	
CLR-1:	gain insight into fundamenta	I principles inv <mark>olved in the g</mark> rowth of nanomaterials		1	2	3	4	5	6	7	8	9	10	11	12		pecifi ıtcom	
CLR-2:	familiarize with zero dimensi	ional materi <mark>als and the</mark> ir synthesis techniques		lge		of	SL	1		h.		Nork		e				
CLR-3:	know the concept of one-din	nensiona <mark>l materials</mark> and fabrication procedures		Knowledge	(n	velopment	stigations oblems	Usage	70			_		nance	б			
CLR-4:					Analysis	lopi	estig	Us	er and	∞ ∞ >		Team	igi	⊗ E	aming			
CLR-5:	R-5: acquire knowledge on special nanomaterials and their fabrication methods					deve	t inve lex pr	Tool	ine	ment ability		<u>8</u>	ommunication	Project Mgt.	g Le			Į I
					lem	gn/	duc	en	e ≷	ironm tainab	S	vidual	I I	헗	Long	7	-2	5-
Course C	ourse Outcomes (CO): At the end of this course, learners will be able to:				Proble	Desi	Condi of con	Modern	The	Environi Sustaina	Ethics	Indi	Com	Proj	Life	PSO.	PS0-2	PSO.
CO-1: describe the fundamental concepts and theory behind nanoparticle synthesis				-	-	3	2	-	7	-	-	-	-	-	-	2		-
CO-2: identify various synthesis techniques involved in solution-based synthesis of nanoparticles				1	-	1	3	- 1		2	-	-	-	-	-	3	-	-
CO-3:	0-3: distinguish nanowires, nanorods and nanotubes from bulk materials and 1D nanostructures				10	3	4-	- (2	-	-	-	-	-	-	2	-
CO-4:	29-4: apply the knowledge of thin films growth using PVD and CVD techniques				7.0	1- (-	3	-	2		-	-	-	-	-	2	-
CO-5:					F	2	_	- 1		-	-	-	_	-	_	_	-	2

Unit-1 - Fundamentals In the Growth of Nanomaterials

12 Hour

Introduction to nanomaterials-Nanomaterials classification based on dimension-Surface energy-Surface energies of different surfaces of FCC structure-Surface energy reduction-Mechanisms to reduce the surface energy-Chemical potential as a function of surface curvature-Gibbs-Thompson relation-Concept of Ostwald ripening-Role of Ostwald ripening in nanoparticle synthesis-Fundamentals of homogeneous nucleation-Critical radius and critical energy-Effect of temperature on critical size and critical free energy-Process of nucleation and subsequent growth-Growth controlled by diffusion-Growth controlled by diffusion (quantitative approach)-the Relations between the nucleation and growth rates and the concentration of growth species-Fundamentals of heterogeneous nucleation-Fundamentals of heterogeneous-nucleation (Quantitative approach)

Unit-2 - Classification of Synthesis Techniques

12 Hour

Classification of nanoparticle synthesis techniques-Top down and bottom up approach of nanoparticles synthesis-Nanoparticle synthesis by mechanical alloying-Nanoparticle synthesis by mechanical milling-Vapor-phase synthesis of nanoparticles-Inert gas condensation of nanoparticles-Plasma-based synthesis of nanoparticles-Spark plasma method for nanoparticles synthesis-Flame-based synthesis of particles-Combustion synthesis of nanoparticles-Spray pyrolysis based synthesis of nanoparticles-Nanoparticles-Nanoparticles-Plasma-based synthesis using microemulsion-Aerosol synthesis of nanoparticles-Colloidal methods-solvothermal/hydrothermal synthesis of nanoparticles-Precipitation and Co-precipitation

Unit-3 - One Dimensional Materials and Fabrication Methods

12 HOU

1-Dimensional nanostructures: introduction-Various examples of 1D nanostructures-Spontaneous growth of 1D nanostructures-Evaporation (dissolution) condensation growth-Fundamentals of evaporation (dissolution) condensation growth (quantitative approach)-Various steps in crystal growth-Fundamental aspects of (vapour-liquid-solid) VLS growth-Fundamental aspects of SLS growth-Au-Si phase diagram-VLS growth of various nanowires-Control of the size of the nanowires-Catalyst size dependent nanowires growth-Various precursors and catalysts used for nanowires growth-SLS growth of various nanowires-Comparison between VLS and SLS methods-Stress induced recrystallization growth-Template based synthesis of NWs-Template filling-Nanofibres producion using Electrospinning

Unit-4 - Thin Film Growth Methods

Fundamentals of thin film growth-Basic nucleation modes-Fundamentals of thin film growth (Quantitative approach)-Growth conditions for the single crystalline, polycrystalline and amorphous films-Physical vapor deposition-Evaporation-Molecular beam epitaxy (MBE)-principle-Epitaxial growth of thin films using MBE-Sputtering and Sputtering targets-DC and RF sputtering-Magnetron sputtering-Chemical vapor deposition (CVD)-Basic chemical reactions in CVD-Reaction kinetics in CVD-Transport phenomena-Atomic layer deposition (ALD)-Self-limiting growth using ALD-Electrochemical and Electrophoretic deposition-Nernst equation and film growth-Sol-Gel Films-spin coating-Dip coating

Unit-5 - Self Assembly Methods for Nanomaterials

12 Hour

Self-assembly-Self-assembled monolayers-Monolayers of organosilicon-Monolayers of alkanethiols and sulphides-Langmuir-Blodgett (LB) technique-Monolayer thin film formation using LB technique-Schaefer's method-Graphene-Introduction-Bonging in graphene-Properties of grapheme-Methods to prepare graphene-Mechanical exfoliation-Liquid phase exfoliation-Role of intercalation in graphene exfoliation-Large area synthesis of grapheme-CVD synthesis of graphene-Biological synthesis of nanoparticles-Nanoparticles synthesis using viruses-Nanoparticles synthesis using bacteria-Role of bacteria in nanoparticle synthesis-Green chemistry of nanoparticles-Nanoparticles synthesis using plant extract

	1. C. Cao, Nanostructures & Nanomaterials – Synthesis, Properties & Applications, Imperial 3. Rai M and Poston C, Green biosynthesis of nanoparticles: mechanisms and applications
Learning	College Press, 2004 Cabi, 2013
Resources	2. Abdullaeva Zhypargul, Synthesis of Nanoparticles and Nanomaterials -Biological
	Approaches, Sp <mark>ringer, 20</mark> 17

earning Assessm	nent	27		3 (34.5)	84948 L. K.	 *** Destruit 							
				Conti	nuous Learning	g Assessment (CLA)			C	mmativa			
	Bloom's Level of Thinking		Form CLA-1 Averag (50	ge of unit te	est	C	g Learning LA-2 0%)		Summative Final Examination (40% weightage)				
		T	heory	Pı	actice	Theory	Practice		Theory	Practice			
Level 1	Remember		20%	40.77		20%	-	-	20%	-			
Level 2	Understand		20%	10 July 10 Jul	- 4	20%			20%	-			
Level 3	Apply		30%			30%	- L		30%	-			
Level 4	Analyze		30%		- 1/	30%			30%	-			
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Level 6	Create	me '	-		- 1.7	-			-	-			
	Total		100) %	11/11/	10	00 %		1	00 %			

Course Designers	
Experts from Industry	Experts from Higher Technical Institutions Internal Experts
1. Dr. M. Krishna Surendra, Saint-Gobain Research, Chennai,	1. Prof. S. Balakumar, University of Madras, balakumar@unom.ac.in 1. Dr. Venkata Ravindra A, SRMIST
krishna.muvvala@saint-gobain.com	A Limite Control FAII I
2. Dr. M. Sathish, CSIR-CECRI, Karaikudi, msathish@cecri.res.in	2. Prof. S. Ramaprabhu, IIT Madras, ramp@iitm.ac.in 2. Dr. Bhaskar Chandra Behera, SRMIST

Course	21NTC206T	Course	SOLID STATE ENGINEERING	Course	_	PROFESSIONAL CORF	L	Т	Р	С	,
Code	2111102001	Name	SOLID STATE ENGINEERING	Category	٥	PROFESSIONAL CORE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

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Course L	earning Rationale (CLR):	The purpose of learning this course is to:	AR.	4			F	rogra	ım Oı	itcome	s (PC))					rogra	
CLR-1:	acquire knowledge on variou	us chemical bo <mark>nding in solid</mark> s	1	2	2	3	4	5	6	7	8	9	10	11	12	_	pecifi utcom	
CLR-2:	understand theory of crystal	diffraction, vibrations and heat capacity	4		7,	7)	of		ciety			~						
CLR-3:	understand theory of crystal diffraction, vibrations and heat capacity describe the concept of free electron Fermi gas and transport properties classify semiconductors, metals and insulators via band theory gain knowledge on excitons, plasmons, polarons and polaritons, Understand the principles of Raman ar optical spectroscopy At the end of this course, learners will be able to:					to E	ions	Φ	socie			Work		Finance				
CLR-4:	 classify semiconductors, metals and insulators via band theory gain knowledge on excitons, plasmons, polarons and polaritons, Understand the principles of Raman an optical spectroscopy 					bme	vestigat oblems	Sag	and			Team	_	Fins	earning			
CLR-5:		, pla <mark>smons, p</mark> olarons and polaritons, Understand the principles of Raman			II Alialy	sign/development utions	.⊆ b	n Tool Usage	engineer a	ment &		∞ర	ommunication	Mgt. &	ong Lear			
Course C	se Outcomes (CO): At the end of this course, learners will be able to:					Design solution	Conduct	lodern	The en	Environm Sustainab	Ethics	ndividual	omm	roject Mgt.	ife Lo	SO-1	⁵ SO-2	SO-3
CO-1:	` '		- H		-	3 3	2	2	7.	υ О		<u>-</u>	-		-	2		<u> </u>
CO-2:	analyze crystalline materials	and their thermal properties using the concept of phonons	1 13	Τ.		T	3	-7	-	2		-	-	-	-	3	-	-
CO-3:	utilize the Fermi-Dirac distrib	oution function for electrical transport properties of solids	114 39	114	7	3 .	-	- 3		2		-	-	-	-	-	2	-
CO-4:	D-4: calculate carrier concentration and mobility of metals and intrinsic and extrinsic semiconductors					-4	-	3	-	2		-	-	-	-	-	2	-
CO-5:	apply the concept of quasi-p	p <mark>articles</mark> to understand the optical properties of solids, Utilize the spectros	copic 3	3		2	-	- (3	-		-	-	-	-	-	-	2

Unit-1 - Bonding in Solids 9 Hour

Amorphous and crystalline materials - Introduction to crystal structure: lattice, basis and primitive cell. Crystal diffraction: Bragg's law and Reciprocal lattice vectors. Brillouin Zones (BZ) - BZ of square lattice and oblique lattice. Crystal binding - Bonding in solids: Inert gas crystals - Van der Waals interaction - Quantitative approach of London interaction. Ionic crystals: Madelung constant and Madelung energy, Evaluation of Madelung constant of NaCl. Covalent, Metallic and hydrogen bonding.)

Unit-2 - Crystal Diffraction, Vibrations and Phonons

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Hooke's law in solids – Analysis of elastic strain and stress components (Quantitative treatment). Vibration of crystals with monoatomic basis - Dispersion relation, Group velocity, Quantization of elastic waves (concept of phonon). Phonon heat capacity - Planck's distribution, Normal modes. Debye model for density of states (modes) - Debye – T3 law (Quantitative approach) Einstein model for density of states Einstein model for density of states

Unit-3 - Fermi Gas and Transport Properties

9 Hour

Free electron Fermi gas: Energy levels of free electron gas in one dimension, Fermi- Dirac distribution - Effect of temperature on the Fermi – Dirac distribution function. Free electron gas in three dimensions - Fermi energy, density of states. Heat capacity of the free electron gas. Electrical conductivity and Ohm's law, Motion of electron in magnetic field - Hall effect: quantitative approach - Hall coefficient. Thermal conductivity of metals: Wiedemann-Franz law Lorentz number

Unit-4 - Band Theory of Solids

9 Hour

Energy bands in solids: Nearly free electron model - Origin and magnitude of the energy gap - Bloch function. Direct and indirect band gap semiconductors. Concept of holes and effective mass. Intrinsic carrier concentration (quantitative approach) - Impurity conductivity – doping: Donor and acceptor states. Super lattices and Zener tunnelling

Unit-5 - Quasi-Particles and Defects 9 Hour

Concept of excitons: Energy level diagram of excitons – Frenkel excitons - Mott-Wannier excitons. Raman effect in crystals. Concept of plasmons in metals - Concept of polarons - Concept of polaritons. Defects in solids – lattice vacancies: Schottky and Frenkel defects. Color centers: F centers - Other centers in alkali halides

Learning	1. Charles Kittel, Introduction to Solid State Physics, 8th ed., Wiley, 2015	3. Solid State Electronic Devices, Ben. G. Streetman amd Sanjay Banerjee, 7thEdison,
Resources	2. Ashcroft and Mermin, Solid State Physics, 1st ed. Sounders College Publishing, 1976	Pearson, 2006

rning Assessn			Continuous Learning	Assessment (CLA)		Commen			
	Bloom's Level of Thinking	CLA-1 Aver	mative age of unit test 50%)		ng Learning CLA-2 10%)	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%	75 - 15 - 16	20%		20%	-		
Level 2	Understand	20%	\$ 7.2. 770	20%		20%	-		
Level 3	Apply	30%		30%		30%	-		
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Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Hemant Dixit, GlobalFoundaries, USA,	1. Dr. Ranjit Kumar Nanda, IIT Madras, nandab@iitm.ac.in	1. Dr. E. Senthil Kumar, SRMIST
aplahemant@gmail.com		
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research	2. Dr. M. S. Ramachandra Rao, IIT Madras, msrrao@iitm.ac.in	2. Dr. Jaivardhan Sinha, SRMIST
India, Krishna.muvvala@saintgobain.com		Hard Hard Bridge

Course	21NTC301J	Course	MICRO AND NANOFABRICATION	Course	_	PROFESSIONAL CORE	L	Т	Р	С
Code	2111103013	Name	WIICKO AND NANOFABRICATION	Category	C	PROFESSIONAL CORE	3	0	2	4

Pre-requisite Courses	N	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

LONG TO BE I SHOW I

Course L	earning Rationale (CLR):	erstand methodology of lithography and etching to pattern materials uire knowledge of different deposition techniques and ion implantation acquainted with CMOS fabrication rules oduce next generation printed electronics technology, Make aware of VLSI technology					F	rogra	<mark>am</mark> Ou	tcome	s (PC))					rogra	
CLR-1:	overview the techniques and	ale materials in device form	1	2	3	4	5	6	7	8	9	10	11	12		pecifi itcom		
CLR-2:	understand methodology of l	ithography <mark>and etchin</mark> g to patter	n materials			tof	Sus	1		N				ce				
CLR-3:	acquire knowledge of differer	nt depos <mark>ition techni</mark> ques and ior	n implantation		Sis	elopment	estigations roblems	Usage	ō			Ε		Finar	В			
CLR-4:	get acquainted with CMOS fa	abricati <mark>on rules</mark>			alysi	lopi	estic		er and	∞ ∞ >		Team	ţion	⊗ T	arning			l
CLR-5:	introduce next generation pri	nted <mark>electroni</mark> cs technology, Ma	ke aware of VLSI technology	aring dge		è	t inve	2	enginee etv	ment		ual &	ommunication	roject Mgt.	ong Le			
				Ne Ne	oblem	ign/d	0 >	dem	et ei	tain	S	lë *	שר	ect		7)-2	-3
Course C	Outcomes (CO):	At the end of this course, le	earners will be able to:	Engine	Prof	Des	o Con	Me	The	Env	Ethics	Mor	Col	Proj	Life	PSC	PSO.	PSO
CO-1:	realizing the technology of Si	wafer manufacturing	The second second second second	3	-	F - 1	2	1	-	-	-	-	-	-	-	2	-	-
CO-2:	pattern diverse materials usin	n <mark>g li</mark> th <mark>og</mark> raphy techniques to enl	hance the device density on chip		1	2	2	3	Z.	2	-	-	-	-	-	3	-	-
CO-3:	applying basic diffusion proc	<mark>esses im</mark> portance in semicondu	ctor technology	2		-	- 3	3	-	2		-	-	-	-	-	3	-
CO-4:	fabricate small-scale devices	<mark>and ch</mark> ip level device space ma	anagement	3	3	-	-	2		2		-	-	-	-	-	3	-
CO-5:	envision low-cost production		printed technology, margining importance of	of 2	 	2	-	3	-	-		-	-	-	-	-	-	2

Unit-1 - Production of Silicon and Wafer Technology

15 Hour

Importance of micro and nanofabrication techniques in IC: front and back plane, Over view of crystal and lattices, Classification of grades of silicon, Production of electronic grade, silicon, Czochralski growth technique, float zone growth technique, Silicon wafer shaping, Wafer manufacturing steps and inspection, Overview of types of epitaxy, Definition-epitaxy, Comparison of vapour phase epitaxy (VPE), liquid phase epitaxy (LPE) and molecular beam epitaxy (MBE), Working of MBE process, General epitaxy growth mechanism, Epitaxy growth kinetics and examples, Understanding silicon oxide properties, Thermal oxidation furnace, Silicon oxide growth kinetics: Deal-Groove model, Thin oxide growth and process of oxidizing polysilicon.

Lab 1: Introduction to the basics of laboratory, Lab 2: To perform wafer cleaning processes followed by thermal oxidation, Lab 3: Crystallographic studies of single crystalline Silicon and Silicon Dioxide wafers by

Unit-2 - Lithography and Etching Tools

15 Hour

Need and basics of lithography, Optical lithography, Optical lithography controls and mask making, Working concept and controls of e-beam lithography, Resolution of electron beam lithography, X-ray lithography, Stamp based lithography, Nanoimprint lithography and applications, Etching processes: Wet etching of semiconductors, metals and insulators, disadvantages; Various types of dry etching-ion beam etching, Sputter etching, Ways of plasma generation for etching processes- Classification of plasma using its density- Capacitively coupled plasma, Inductively coupled plasma, Reactive ion etching, Deep reactive ion etching and bosh process. Lab 4: To perform patterning by photolithography process, Lab 5: To perform wet chemical etching of silicon dioxide and metal films, Lab 6: Si NW array fabrication via wet lithography process

Unit-3 - Deposition Techniques and Ion Implantation Process

15 Hour

Classification of material deposition techniques, Overview of physical and chemical deposition technique, Physical vapour deposition, Resistive heating evaporation, Electron beam heating evaporation, Pulsed laser evaporation, Basics of sputtering, DC and magnetron sources for sputtering, Introduction to atomic layer deposition, Working principle of atomic layer deposition, Concepts of diffusion in solids, Using Fick's diffusion in semiconductor doping, Process of ion implantation, Ion implantation tool, Fundamentals of ion energy loss and stopping, Damage due to implantation, Ion distribution, junction control, Types of annealing tools-Carrier recovery using annealing process. Lab 7: To deposit Al thin film on the oxidized silicon surface by e-beam evaporation Lab 9: To estimate energy loss of ions in silicon for implantation process using SRIM software

Unit-4 - Small-Scale Devices and Chip Level Device

15 Hour

History of complementary metal-oxide- semiconductor (CMOS), Requirements of device isolation, Types of isolation, Local Oxidation of Silicon (LOCOS) and shallow trench isolation (STI) processes for local isolation, Concept of self-alignment-advantages and applications, MOS fabrication with self-alignment, Requirement of planarization, Local and global planarization using chemical-mechanical polishing, Importance of MOS devices, Working principle of integrated CMOS inverter, Fabrication process of CMOS inverter, Usage of isolation and biasing of inverter, 'Latch up' concept for inverter, Design rules for CMOS, MOSIS specifics for inverter, Introduction to silicon-on-insulator (SOI), On chip fabrication processes of passive components.

Lab 10: To form local anodic oxidation pattern by scanning probe microscopy, Lab 11: To fabricate MOS capacitor and study its I-V characteristics

Lab 12: Fabrication of ZnO nanowires on ITO substrate for UV detection Applications

Unit-5 - Next Generation Printed Electronics Technology

15 Hour

History and overview of printing processes, Necessity of printed electronics technology, Requirements of printing, Printing tools, Types of fluids for ink, Properties of fluids in printing processes, Working principle of flexographic printing (FP), Advantages and disadvantages of FP, Working principle of gravure printing (GP), Advantages and disadvantages of GP, Working principle of screen printing (SP), Advantages and disadvantages of SP, Working principle of inkjet printing (IP), Advantages and disadvantages of printed devices, Comparison of printed devices with lithographically fabricated devices, Concept of hybrid printed electronics, Advantages of printing, Future of printed low-cost electronics.

Lab 13: To perform contact angle measurement of solvents used in printing process on glass and plastic substrates

Lab 14: To measure temperature dependent electrical characteristics of P-N junction diode and estimation of activation energy, Lab 15: Repeating of experiments

Lograina	lans H. Gatzen, Volker Saile, Jürg Leuthold, "Micro and Nano Fabrication", Springer 3. Giovanni Nisato, Donald Lupo, Simone Ganz, "Organic and Printed Electronics", CRC Pres	∍ss,
Learning	015 2016.	
Resources	S. M. Sze, and <mark>S. Lee. "</mark> Semiconductor Devices Physics and Technology". Wiley, 2012 4. Sorab K. Gandhi, "VLSI Fabrication and Principles", McGraw Hill, 2005	

Learning Assessm	ent		Block Brown Walk							
			Continuous Learning	Assessment (CLA)		Cumn	native			
	Blo <mark>om's</mark> Level of <mark>Thinkin</mark> g	Forma CLA-1 Average (45%	e of unit test	CL	g Learning A-2 5%)	Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%		A Property of	20%	20%	=			
Level 2	Understand	20%	- NW	,	20%	20%	=			
Level 3	Apply	40%	- 1.7	-	40%	40%	=			
Level 4	Analyze	20%	- 1/11/1	-	20%	20%	=			
Level 5	Evaluate		- 1/2/6	-	7 - /1 -	-	-			
Level 6	Create				- / - <u>_</u>	-	=			
	Total	100 9	%	10	0%	100) %			

Course Designers	PLANT - LEATH ATT	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Pramod Rajanna, HHV Bangalore, pramod@hhv.in	 Dr. Aditya Sadhanala, IISc Bangalore, sadhanala@iisc.ac.in 	1. Dr. Abhay Sagade, SRMIST
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research India, , Krishna.muvvala@saintgobain.com	2. Dr. N. N. Murthy, IIT Tirupati, nnmurty@iittp.ac.in	2. Dr. P. Malar, SRMIST

Course	21NTC302J	Course	NANOELECTRONICS	Course	(DDOEESSIONAL CODE	L	Т	Р	С
Code	2111103023	Name	INANOELECTRONICS	Category	٥	PROFESSIONAL CORE	2	0	2	3

Pre-requisite Courses	N	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

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Course L	earning Rationale (CLR):	The purpose of learning	g this course is to:				- 1	Progr	am Ou	itcome	s (PO))					gram	
CLR-1:	acquire knowledge on quantu	m confineme <mark>nt and low-di</mark> n	nensional nanostructures for use in nanoelectronics	1	2	3	4	5	6	7	8	9	10	11	12		ecific come:	
CLR-2:	understand the key aspects of	of electron <mark>tunnelling</mark> and it	s application in the operation of nanodevices	ge		of	SI					ork		9				
CLR-3:	understand the functioning of	tunnel j <mark>unctions</mark> in single e	electron devices	Knowledge	S	velopment	stigations oblems	Usage	ъ			Μ		Finance	βL			
CLR-4:	understand the concept of me	olecul <mark>ar electro</mark> nics for real	ization of device miniaturization	X Sn	Analysis	lobu	estigation problems		r and	∞ × >	L.	Team	ioi	∞ర	arning			
CLR-5:	acquire knowledge on the fat	rica <mark>tion, cha</mark> racterization a	nd modelling of nanodevices,	ring		Ð	i ×	100	enginee etv	Environment Sustainability		<u>8</u>	ommunication	Mgt.	Ľ			
				Engineering	Problem	ign/d	Conduct of comple	Modern	eng et<	roni	g	ndividual	חשר	Project I	Long	7	7.5	-3
Course C	outcomes (CO):	At the end of this cours	se, learners will be able to:	Eng	Prof	Des	o d	Mo	The	Env	Ethics	Indi	Sol	Proj	Life	PSO	PS0-2	PSO-:
CO-1:	acquaint with the fundamenta	n <mark>ls o</mark> f <mark>nan</mark> oelectronics	1 2 2 A 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	3	3	2	-	Ŧ	7	-		-	-	-	-	2	-	-
CO-2:	utilize the knowledge on the	<mark>electron</mark> tunneling phenome	ena in semiconductor nanodevices	3	3	100	2	- 4	-	2		-	-	-	-	3	-	-
CO-3:	apply the knowledge on the d	<mark>peratio</mark> n and application p	erspectives of various tunnel devices	3	3		3	-	-	2	-	-	-	-	-	-	3	-
CO-4:	analyze the concept of molec	rular electronics		-2		2	2	-	-	2		-	-	-	-	-	2	-
CO-5:	apply knowledge on the fab		nanodevices, Demonstrate skills required for usin	g 3		7.3	3	3	-	-	-	-	-	-	-	-	-	2

Unit-1 - Quantum Confinement in Low Dimensional Systems

12 Hour

Introduction to nanoelectronics - Review of basic quantum physics - Moore's law and its consequences - Silicon electronics - Limitations - International technology roadmap characteristics (ITRC) - ITRC and nanoscale importance - Need for new concepts in electronics - Challenges in micro to nano conversion - Dimensionality in materials - Density of states of materials at nanoscale - Effect of band gap of material at different dimensions - Length scales of charge scattering - Special dimensionality case of carbon - Introduction to 0D, 1D, 2D and 3D carbon forms - Nanocomputing - Device simulation software at nanoscale - Future Prospects of Nanoelectronic Devices - Progress in Nanoelectronic Architectures.

- 1. Introduction to the experiments and basic demonstration, 2. Determination of electron concentration for various temperature
- 3. Determination of electron (µn) and hole (µp) mobilities for various doping concentration in semiconductor

Unit-2 - Quantum Tunneling in Semiconductor Nanostructures

12 Hour

Tunnel effect and tunnelling elements - Nanoelectronics in tunnelling devices - Tunnelling of electrons through a potential barrier - Electron tunnelling - Potential energy profiles for material interfaces - Metal-semiconductor and metal- insulator junctions - Metal-insulator-metal junctions - Metal work function and electron affinity - Tunnelling applications - Field electron emission - Double barrier tunnelling - Resonant tunnelling diodes - Tunnelling in MOS Transistors - Hot electron effects in MOSFETs - Gate-oxide tunnelling - Principles of scanning tunnelling microscopy (STM) - Applications of STM in nanotechnology

4. Determination of Fermi function for different temperature, 5. Determination of resistivity for various doping concentration, 6. Four probe resistivity measurement

Unit-3 - Electron Transport in Nanodevices

12 Hour

Classical and semi-classical transport - Ballistic transport in nanostructures - Coulomb blockade - an overview - Single electron tunnelling and Coulomb blockade - Coulomb blockade in a quantum dot circuit - Coulomb blockade in a nano-capacitor Ballistic transport and the Landauer formula - Quantized Conductance - Working principle of Single Electron Transistor (SET) - A single-electron pump and turnstile - Quantum dot - Cellular automata - Electron transport in quantum dots - Electron transport in quantum wires - Introduction to spintronics - Giant magneto resistance - Tunnel magneto resistance — Spintronic devices and applications. 7. Hall effect of semiconductors, 8. Repeat/Revision of the experiments, 9. Simulation of Zener diode and its I-V characteristics

Unit-4 - Molecular Scale Electronics 12 Hour

Introduction to molecular electronics - Atomic-scale junctions: an overview - Schrodinger equation - Self-consistent field - Molecular functionalities - Metal-molecule interfaces - Molecular band Structure - Level broadening - Atomistic view of electrical resistance - Conductance of atomic-scale contacts - Coherent transport through molecular junctions - Non-coherent transport in molecular electronics devices - Molecular diodes - Conducting mechanism of single- molecule junctions - Single-molecule transistors - Elastic and inelastic tunnelling - Molecular devices and logic switches - Interface engineering issues.

10. Simulation of diode and its I-V characteristics with smoke analysis, 11. Simulation of BJT and its I-V characteristics, 12. Simulation of diode in nano dimension and its characterization

Unit-5 - Design And Modelling of Nanoelectronic Devices

12 Hour

Introduction to computational methods - Necessity of computational methods - Molecular wire - Molecular wire conductance - Theoretical aspects on molecular conductance - Computational aspects on molecular conductance - Various modelling techniques - Monte Carlo method - Ab initio simulations - Ab initio simulations: examples and problems - Multi scale modelling - Modelling of nanodevices and applications. TCAD - examples and problems - NEH DFT: examples and problems

Materials studio - Future of nanoscale modelling.

13. Designing of 2D MOSFET in nano dimension, 14. Designing of Molecular Electronic Device, 15. Simulation of I-V Characteristics for Molecular Electronic Device

Learning Resources

- 1. G. W. Hanson, Fundamentals of Nanoelectronics, Pearson Education; 2009
- 2. V. V. Mitin, V. A. Kochelap, M. A. Stroscio, Introduction to Nanoelectronics, Cambridge University Press; 2012
- E. Scheer and J. C. Cuevas, Molecular Electronics: An Introduction to Theory and Experiment, World Scientific Pub Co Inc; 2017
- 4. K. I. Ramachandran, Computational Chemistry and Molecular Modeling, Springer, 2010
- 5. Nanoelectronics simulation laboratory course manual, 2016

- 6. Sarhan. M. Musa, Computational Nanotechnology: Modeling and Applications with MATLAB, CRC Press. 2018
- 7. John O. Attia, Electronics and Circuit Analysis using Matlab, CRC Press, 2018
- 8. Mitchell A. Thornton, PSpice for Circuit Theory and Electronic Devices, Morgan & Claypool Publishers series, 2007
- Simon Li and Yue Fu, 3D TCAD Simulation for Semiconductor Processes, Devices and Optoelectronics, Springer, 2012
- 10. https://docs.guantumatk.com/tutorials/tutorials.html

Learning Assessmen	ıt 💮		B 77 77 7		7.5	 But 数 0.60%。 			
			500 00	Continuous I	earnin	g Assessment (CLA)		Cumr	mative
	Blo <mark>om's</mark> Level of <mark>Thinking</mark>		CLA-1 Aver	mative age of unit test 15%)		CL	g Learning A-2 5%)	Final Exa	nauve amination eightage)
		45-1	Theory	Practice	JAPA.	Theory	Practice	Theory	Practice
Level 1	Remember	a. P.	20%	-	1		20%	20%	-
Level 2	Understand	-	20%	-	11/1/		20%	20%	-
Level 3	Apply		40%	-	10%		40%	40%	-
Level 4	Analyze		20%		4.5		20%	20%	-
Level 5	Evaluate	1	<- (-	-
Level 6	Create	· \	7/1/1	IARN.	TI	A D. Transie		<u>-</u>	-
	Total		/1	00 %	$T^{-1}T$	10	0 %	100	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Dr. Krishna Surendra Muvvala, Saint Gobain Research India, krisha.muvvala@saintgobain.com	1. Prof. V. Subramaniam IIT M, manianvs@iitm.ac.in	1. Dr. D. John Thiruvadigal, SRMIST
2. Dr. Hemant Dixit, Global Foundaries, USA, aplahemant@gmail.com	2. Prof. C. Venkateswaran, Univ. of Madras, cvenkateswaran@unom.ac.in	2. Dr. Arijith Sen, SRMIST

Course	21NTC303T Cours	NANOPIOTECHNOLOGY	Course	PROFESSIONAL CORE	L	Т	Р	С	
Code	Name	NANOBIOTECHNOLOGY	Category	PROFESSIONAL CORE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil Progres Cours	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards	 Nil

Course L	Learning Rationale (CLR): The purpose of learning this course is to:		4	-		Pro	g <mark>ram</mark> O	utcome	es (PC))				Progi	
CLR-1:	understand the cell structure interaction of nanomaterials with biological systems	1	2	7	3 4	5	6	7	8	9	10	11	12	Spec Outco	
CLR-2:	know about various methods of membr <mark>ane transp</mark> ort the properties of biomaterials	950	5	of			. "			જ		9			
CLR-3:	know about biomaterials	Zalwork Zalwork	3	velopment	vestigations	oroblems	D D	δ \.		≽ ≥		Finance	Б		
CLR-4:	learn about different delivery systems			lopn	estig	orobi	er and	∞ >		Teal	ig	∞ర	earning		
CLR-5:	understand the use of nanopartic <mark>les in se</mark> nsors	Dairea		<u> </u>	.⊆	ă Z	- .⊆	ronment ainability		lal &	mmunication	Mgt.	Long Le		
Course C	Outcomes (CO): At the end of this course, learners will be able to:	Fnoing	Problem	Design/d	필호	of comple	The en	Envirol Sustair	Ethics	Individual	Comm	Project	Life Lo	PSO-1	PSO-3
CO-1:	explain the functions of cell organelles Choose appropriate biomaterial for biological application	3	}		- "		-	-	-	-	-	-	-	3 -	-
CO-2:	describe the mode of nanoparticle transport Explain the concept of biocompatibility	í	3 -	9 177		١ .	4	-	1	-	-	-	-	2 -	-
CO-3:	analyse the interaction of biomaterial with biological system	, x6	1 1 2	4	- 1 4	-		-		-	-	-	-	- 2	-
CO-4:	differentiate traditional and novel drug delivery systems	-3	}		- -	-	-	-	-	-	-	-	-	- 2	-
CO-5:	design sensors based on na <mark>nomater</mark> ials	3	}		-7	-		-	2	-	-	_	-		2

Unit-1 - Cell Structure

Cell structure, cellular organelles and functions, cell membrane, Structure of membranes, Lipid bilayer, Membrane proteins

Unit-2 - Membrane Transport Properties of Biomaterials

Nanoparticles transport across membrane, Active transport, Passive Transport, Membrane transporters, Endocytosis, Exocytosis, receptor mediated endocytosis

Unit-3 - Interactions of Biomaterials

Biomaterials, Surface and bulk properties of bio materials, Nanoceramics, Polymers, Hydrogels, Surface modification of biomaterials, Surface immobilized in biomaterials, Interaction of biomaterials with cells, Blood-Biomaterial Interactions, Interactions with Proteins, Immune response to biomaterials. Biocompatibility, Hydroxyapatite: Structures, Chemical composition and application

Unit-4 - Drug Delivery Systems 9 Hour

Drug delivery systems, Traditional drug delivery, Controlled drug delivery, Nanoparticle based drug delivery, Targeted drug delivery, Types of drug targeting, Hyperthermia treatment, Dental implants, Tissue engineering, Scaffold design and fabrication,

Unit-5 - Nano Biosensor 9 Hour

Monoclonal antibodies, Biosensor, Nano biosensors design, Nanoimmuno sensors, Nano diagnosis, blotting techniques used in Nano biotechnology, Polymerase chain reaction, Detection of tumors, In vivo imaging, Nanotechnology in gene therapy

9 Hour

9 Hour

	Cell Biology, Gerald Karp, Janet Iwasa, Wallace Marshall, 8th Edition, John Wiley & Sons, 2018
Learning	Nanoparticulates Drug Carriers, Edited by Vladimir P Torchilin, 2006, Imperial College Press
Resources	3. The Chemistry of Medical and Dental Materials, John W. Nicholson, Rsc Materials Monographs, Published by The Royal Society of Chemistry,

- Tissue Engineering, Clemens van Blitterswijk, Peter Thomsen, Anders Lindahl, Jeffrey Hubbell, David Williams, Ranieri Cancedda, Joost de Bruijn, Jérôme Sohier, Academic Press, Elsevier,
- 5. Nanoscale Technology in Biological Systems, edited by Ralph S. Greco, Fritz B. Prinz, R. Lane Smith, CRC PRESS
- Nanoparticulate Drug Delivery Systems, Edited by Deepak Thassu, Michel Deleers, Yashwant Pathak, 2007

rning Assessn	iont .		Continuous Learnin	g Assessment (CLA)			
	Bloom's Level of Thinking	CLA-1 Avera	mative age of unit test i0%)	Life-Long CL	g Learning .A-2 0%)	Final Ex	mative amination eightage)
	/ 3 /	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	F2.3-u. 30%	20%		20%	-
Level 2	Understand	20%		20%	(-4	20%	-
Level 3	Apply	30%	12 TH WEST 1	30%		30%	-
Level 4	Analyze	30%	Carlotte Market Control	30%		30%	-
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Level 6	Create	A - 1	1021 / 1 - Jan 197	201 30 7		-	-
	T <mark>otal</mark> —	10	00 %	10	0 %	10	0 %

Course Designers	Mark the Barry Park Care and	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, HCL Health care division, Chennai	1. Dr. Mukesh Doble, IIT M	1. Dr. G. Devanand Venk <mark>atasubbu</mark> , SRMIST
2. Dr. Asifkhan Shanavas, INST Mohali	2. Dr. T. Prakash, UOM	2. Dr. N. Selvamurugan,, SRMIST

Course	21NTC304T Course	NANOTOXICOLOGY	Course	PROFESSIONAL CORE	L	Т	Р	С	
Code	Name	NANOTOXICOLOGI	Category C	PROFESSIONAL CORE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

THE RESERVE

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	1	- 4			٦, ٦	rogr	am Oı	itcome	s (PO))					gram	
CLR-1:	understand the concept of to.	xicity		1	2	3	4	5	6	7	8	9	10	11	12		ecific comes	
CLR-2:	acquire knowledge on physic	al properti <mark>es of nano</mark> structured materials on toxicity		lge		oŧ	SI					ork		9				
CLR-3:	learn about nanoparticle inter	raction w <mark>ith cells</mark>		Knowledge	(C)	evelopment	vestigations problems	Usage	ъ			Μ		Finance	Б			
CLR-4:	know about various methods	of tox <mark>icity asse</mark> ssment			Analysis	lopn	estig		er and	∞ >		Team	igi	& F	earning			
CLR-5:	learn various in vivo toxicity r	neth <mark>ods</mark>	ď.	Engineering		deve	.⊑ ∺	Tool	enginee	ronment		<u>ھ</u>	ommunication	Project Mgt.				
	<u>.</u>		7.7	inee	Problem	ign/de	onduct i	Modern	eng etv	Environ	S	ndividual	nur	ect	Long	7	2 2	<u>بر</u>
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	-324	Eng	Pro	Des	of Co	Moc	The	Sus	Ethics	Indi	Sol	Proj	Life	PSO.	PSO-2	PSO-3
CO-1:	aware about toxicity caused I	b <mark>y nanom</mark> aterials	1	3	}	- "	-	-	7	-	-	-	-	-	-	3	-	-
CO-2:	relate the physical properties	of nanostructured materials to its toxicit	,	3		1971	14	- 4		-	1	-	-	-	-	-	3	-
CO-3:	analyze the various symptom	s caused due to toxicity of nanoparticles		3	e de la constante de la consta		- -	-		-		-	-	-	-	-	3	-
CO-4:	apply the various methods of	toxicity assessment	131	3	1	r- (-	-	-	-	-	-	-	-	-	-	-	2
CO-5:	analyze the in vivo toxicity da	ta .		3	εĘ,	1.7	-	-	-	-	-	-	-	-	-	-	2	-

Unit-1 - Toxicity Concept

Size and charge specific behavior of nanomaterials, source of nanoparticles, epidemiological evidences, entry routes for nanoparticles in human body: lungs, intestinal tract and skin, Deposition and translocation in the body

Unit-2 - Nanostructured Materials Toxicity

9 Hour

Lung Inflammation, Nanoparticles and the Blood-Brain Barrier, Placental Barrier, Nanoparticles on the Cardiovascular System; Nanoparticles Translocation and Direct Vascular Effects; Endothelial Dysfunction and Endogenous Fibrinolysis; Coagulation and Thrombosis; Effects of Nanoparticles on the Liver and Gastrointestinal Tract; Effects of NP on the Nervous System

Unit-3 - Nanomaterial Interaction with Cells

9 Hour

Mechanisms of nanomaterial toxicity: oxidative stress, ecotoxicity, genotoxicity, hemolytic toxicity, mutagenicity and immunotoxicity

Unit-4 - Toxicity Assessment

9 Hour

n vitro toxicity assessment-cell viability, lactate dehyd<mark>rogenase rel</mark>ease, reactive oxygen species generation, change in mitochondrial membrane potential and nuclear fragmentation. In vivo toxicity assessment: inflammatory response, acute toxicity studies, LD50 determination, histopathological studies

Unit-5 - Environmental Toxicity

9 Hour

Nanopollution – Nanomaterials in environment-sources of pollution-transport through environment

Learning
Resources

- Handbook of Nanotoxicology, Nanomedicine and Stem Cell Use in Toxicology. Saura C Sahu, Daniel A Casciano, 2014.
- Nanotoxicology Interactions of Nanomaterials with Biological Systems. Yuliang Zhao and Hari Singh Nalwa, 2006.
- 3. Biointeractions of Nanomaterials. Vijaykumar B. Sutariya, Yashwant Pathak, 2014.
- 4. New Technologies for Toxicity Testing. Michael Balls DPhil, Robert D. Combes PhD, Nirmala Bhogal, 2012.
- Challa. S. S. R, Kumar, "Nanomaterials Toxicity, Health and Environmental Issues", Wiley-VCH publisher, 2006.
- Nanotoxicology: Characterization, Dosing and Health Effects- Nancy. A, Monteiro-Riviere, Lang Tran. C Informa healthcare, 2007

Learning Assessm	nent					1			
	Bloom's Level of Thinking	CLA-1 Avera	Continuous Learning native ge of unit test %)	CI	g Learning LA-2 0%)	Summative Final Examination (40% weightage)			
	_	Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%	10 P. P. P. P. B.	20%		20%	-		
Level 2	Understand	20%	. All 1977	20%		20%	-		
Level 3	Apply	30%		30%	- C- Z-	30%	-		
Level 4	Analyze	30%	ay that Waster a fire	30%		30%	-		
Level 5	Evaluate		Carlot Mary Mary	-17 - 77			-		
Level 6	Create			11		-	-		
	To <mark>tal</mark>	100)%	10	00 %	100) %		

Course Designers	그런 경우 나무를 내려면 얼마를 받았다. 생각한	, 4
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, HCL Health care division, Chennai	1. Dr. Vignesh Muthuvijayan, IITM	1. Dr. G. Devanand Venka <mark>tasubbu</mark> , SRMIST
2. Dr. Asifkhan Shanavas, INST Mohali	2. Dr. G. Hariharan, NCSCM	2. Dr. S. Sahabudeen,, SRMIST

Course	21NTC2051	Course	NANORIOTECHNOLOGY AND NANOTOXICOLOGY LARORATORY	Course	_	DBUEESSIONAL CODE	L	Т	Р	C	
Code	21N1C3U5L	Name	NANOBIOTECHNOLOGY AND NANOTOXICOLOGY LABORATORY	Category	C	PROFESSIONAL CORE	0	0	6	3	

Pre-requisite Courses	Nil	Co- requisite Courses	Nil Progressive Courses	Nil
Course Offerin	g Department	Physics and Nanotechnology	Data Book / Codes / Standards	Nil
			THE NAME OF	

Course L	earning Rationale (CLR):	The purpose of learning	g this course is to:	$\mathcal{M}_{\mathcal{A}}$				F	rogra	m Ou	tcome	s (PO)					gram	
CLR-1:	know about microbial culture	/ 80 /	11.3		1	2	3	4	5	6	7	8	9	10	11	12		ecific come	
CLR-2:	learn isolation of DNA	3.7	V ().		ge	7	of	SL					ork		9				
CLR-3:	utilize nanoparticles for drug	delivery		dia	Knowledge	S	nent	vestigations problems	Usage	ъ	. \		≥		Finance	Б			
CLR-4:	understand the methods of a	nimal <mark>cell cultur</mark> e	N. S.		Αno	Analysis	lobi	estig	- N	r and	× ×		Team	Į.	≪	earning			
CLR-5:	know about the interaction ar	nd to <mark>xicity of</mark> nanomaterials		NAV.	Engineering		sign/development utions	.⊑ ≼	<u>P</u>	engineer sty	Environment Sustainability		<u>8</u>	ommunication	Project Mgt.				
			- 1 - 1 - 1 - 1 - 1 - 1 - 1 - 1 - 1 - 1	741	inee	Problem	sign/d utions	onduct i	Modern		ron	S	ndividual	핕	ect	Long	7	7-5	က္
Course C	Outcomes (CO):	At the end of this cour	se, learners will be able to:	The said	Eng	Prot	Des	of or	Moo	The	Envi	Ethics	lndi	S	Proj	Life	PSO.	PS0-2	PSO-3
CO-1:	culture microorganisms		- C. S.	by the co	-	1	- 1	3	-	1	-		-	-	-	-	3	-	-
CO-2:	isolate and analyse DNA	2 (2)	TANK A STANK	1801	1.5	1.3	42.5	3	- /	i.	-	1	-	-	-	-	-	2	-
CO-3:	fabricate drug delivery syster	ns			ME 0	200	-1	3	- (-		-	-	-	-	-	-	2
CO-4:	culture animal cells in laborat	ory Tory			121	7	1- [3	- 1	-	-		-	-	-	-	3	-	-
CO-5:	understand different biologica	al applications and the toxi	city of nanomaterials	Carlo Sale	F,	e		3	- 3	-	-	7	-	-	-	-	-	2	_

List of Experiments 90 Hour

- Lab 1. Introduction to Nanobiotechnology laboratory
- Lab 2. Inhibition of microbial growth by nanoparticles
- Lab 3. Estimation of membrane damage by nanoparticles
- Lab 4. Determination of DNA fragmentation by nanoparticles
- Lab 5. Fabrication of nanoparticles incorporated scaffolds for tissue engineering
- Lab 6. Amplification of DNA by PCR for tissue engineering
- Lab 7. Estimation of drug loading percentage
- Lab 8. Determination of controlled drug release
- Lab 9. Synthesis of polymeric nanoparticles for drug delivery
- Lab 10. Fluorescent imaging of nano-bio interaction
- Lab 11. Analysis of biocompatibility of nanoparticles by MTT assay
- Lab 12. Analysis of apoptosis induced by nanoparticle

Learning	1. Introduction of Practical Biochemistry by David T. Phummer. (II Edition) 2. Cappuccino, J.G. and N. Sherman "Microbiology: A Laboratory Manual", 4th Edition,		Sambrook, Joseph and David W. Russell "The Condensed Protocols: From Molecular Cloning: A Laboratory Manual" Cold Spring Harbor, 2006.
Resources	Addison-Wesley, 1999.	4.	Masters J.R.W. Animal Cell Culture: Practical Approach. Oxford University Press.2000

			Co	onti <mark>nuous Learning</mark>	Assessment (C	LA)			
	Bloom's Level of Thinking	exper	ge of first cycle iments 0%)	CLA-2 Avera cycle exp (30	eriments		Examination eightage)		amination eightage)
		Theory	Practice Practice	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember		20%		20%		20%	-	-
Level 2	Understand	7	20%		20%		20%	-	-
Level 3	Apply	/ o" -/	30%	-	30%	A	30%	-	-
Level 4	Analyze	77.	30%		30%	2 V 3	30%	-	-
Level 5	Evaluate	- 4	V .	-	-	7.1	- · · ·	-	-
Level 6	Create		- 4		-			-	-
	Total	10	0 %	100) %	10	00%		-

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr.K.Chandru, HCL Health care division, Chennai	1. Dr.Mukesh Doble, IIT M	1. Dr. G. Devanand Venkatasubbu, SRMIST
2. Dr. Asifkhan Shanavas, INST Mohali	2. Dr.T.Prakash, UOM	2. Dr. N. Selvamurugan, SRMIST



Course	21NTC401J	Course	POLYMER AND NANOCOMPOSITES	Course	_	PROFESSIONAL CORE	L	Т	Р	С
Code	2111104013	Name	POLYMER AND NANOCOMPOSITES	Category	C	PROFESSIONAL CORE	2	0	2	3

Pre-requi	· · · · /	Co- requisite Courses	Nil	Progressive Courses	Nil
Course	Offering Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	1	4		- T	rogra	am Oı	ıtcome	s (PC))				Prog		
CLR-1:	acquire knowledge about fur	damentals of p <mark>olymers</mark>	1	2	3	4	5	6	7	8	9	10	11	12		pecifi ıtcom	
CLR-2:	understand basics concepts	about con <mark>ducting pol</mark> ymers	dge		1	of		ciety			~						
CLR-3:	R-3: gain insight into the importance of polymers in nanotechnology			1	nt of	ions	Ф	socie	١.		Work		Finance				1
CLR-4:					bme	vestigat oblems	sag	and	1		eam	_	Fina	earning			į.
CLR-5:	gain knowledge about the parameter and contains a polymer	repa <mark>ration an</mark> d properties of nanocomposites, Understand the significance mposites	l glineering Knowlec	roblem Analysis	ign/development	duct investigations	7	engineer a	rironment &		~ ~	ommunication	roject Mgt. &	Long Lear	_	2	3
Course C	urse Outcomes (CO): At the end of this course, learners will be able to:				Desig	Cond	Modern	The	Environi S <mark>ustaina</mark>	Ethics	Individual	Comr	Proje	Life L	PSO-	PSO-	PSO-
CO-1:	apply the chemical concepts	to understand the basics principles of polymer and polymerization reaction	3	2	W.	-	1	Æ.	- 1	-	-	-	-	-	3	-	-
CO-2:	analyze the conduction me conducting polymers	chanism, various methods of synthesis, characterization and application	s in 3	3	-	- 3	- (0	-	1	-	-	-	-	3	-	-
CO-3:	apply the knowledge in maki	ng nanocomposites with different class of nanofillers and matrix materials	-3		2	-	2	-	-		-	-	-	-	-	2	-
CO-4:	incorporate nano based mod	<mark>ification</mark> in different polymeric based composites	3	10	3	-	- 7	-	-	-	-	-	-	-	-	2	-
CO-5:		polymer nanocomposites in various fields, Implement the polymeriza	tion 3	74	-	2		7	-		-	-	-	-	-	-	2

Unit-1 - Fundamentals of Polymers

12 Hour

Importance of polymers: basic concepts - Classification of polymers on the basis of microstructures & macrostructures - polymer classifications based on-occurrence, types, process and applications - Chain structure, configuration and conformation - Homo and heteropolymers - copolymers - Crystalline nature of polymers - Factors affecting crystallization phenomenon - Glass transition temperature (Tg) - Melting temperature(Tm) - Factors affecting Tg and Tm - Importance of Tg - Molecular weight distribution - Degree of polymerization - Reaction kinetics of polymerization - Molecular solution, Melt and elastomer - Dielectric constant - Polarization; Dissipation factor

1. Introduction to the basics of Polymer science, 2. Polymerization of Urea- formaldehyde resin, 3. Interfacial Polymerization of polyamide from Diamine and Diacid Chloride.

Unit-2 - Conducting Polymers

12 Hour

Conducting polymers – Discovery and structural characteristics - Intrinsic and extrinsic conduction in polymers - Charge carriers, polarons, bipolarons, and conducting mechanism - Chemical and electrochemical methods of synthesis of conducting polymers - Synthesis method of polyacetylene - polyaniline – Polypyrrole - advantage and disadvantage of various synthesis methods - Characterization methods – elemental analysis for dopants - Characterization using UV-Visible and FTIR spectrometer Morphological study using SEM and TEM - Applications of conducting polymers in corrosion protection – sensors - electronic and electrochemical energy devices

- 4. Preparation of poly vinyl alcohol nanofibers by electro spinning technique, 5. Characterization of the fibers prepared using SEM and wettability test,
- 6. Fabrication of polymer membrane using phase inversion techniques

Unit-3 - Nanocomposites, Nanofillers and Polymeric Matrices

12 Hour

Introduction to nanocomposites -reinforcements - matrix materials- - nanofillers - classification of nanofillers - Carbon and Noncarbon based nanofillers - Metal matrix, Polymeric and Inorganic composite matrix -Polyamide Matrices, Polypropylene and Polyethylene Matrices, Liquid-Crystal Matrices, Epoxy and Polyurethane Matrices, Rubber Matrices - Synthesis of Nanocomposite: Direct Mixing, Solution Mixing, In-Situ Polymerization - Super hard nanocomposites - Self-cleaning nanocomposites - Metal matrix nanocomposites: Metal with nanoceramic fillers such as SiC, CeO2, TiO2, ZrO2 PTFE, CNTs. 7. Fabrication of polymer thin film composites using phase inversion techniques, 8. Repeat/Revision of experiments, 9. Preparation of metal-polymer nanocomposites

Unit-4 - Nano Based Modification in Polymeric Nanocomposites

12 Hour

Polymer- Clay Nanocomposites - Synthesis of Nylon 6-clay hybrid (NCH) composites and characterization - Crystal structure of NCH and properties of NCH - layered silicate nanocomposites - Structure, properties and characterization - Ceramic Matrix Nanocomposites - Fibrous monolithic ceramic, fiber reinforced ceramic composites - Whisker reinforced ceramic matrix composite - Particulate reinforced, graded and layered ceramic composite - Nanophase ceramic composites - Metal reinforced ceramic matrix nanocomposites - Non-oxide ceramic composites - Functionally graded ceramics- clay nanocomposites 10. Preparation of ceramic based nanocomposites, 11. Morphological characterization of prepared composites using SEM, 12. Synthesis of Nylon-6 polymer

Unit-5 - Application of Polymeric Nanocomposites

12 Hour

Nanocomposites – Optical, Structural applications - Nanocomposites containing functionalized nanoparticles; Organic and polymer materials for light-emitting diodes, Luminescent polymer for device applications -Polymer Nanocomposites for Bio-medical applications - antimicrobial coatings- medical implants - Nanocompoites catalysts for Fischer-Tropsch synthesis- methane oxidation and biofuels - Nanocomposites films for gas sensing - Hybrid composite materials fo<mark>r theraph</mark>y and food packaging

13. Synthesis of particulate reinforced composites, 14. Synthesis of hydrogel using cellulose acetate polymer, 15. Mini Project

Learning Resources

- international publications, 2005
- 2. Luigi Nicolais, Gianfranco Carotenuto, Metal-polymerNanocomposites, Wiley-Interscience, 2005
- 3. BorZ.Jang, Advanced Polymer composites, ASM International, USA, 1994.
- 1. Gowariker V.R., Viswanathan N.V., Sreedhar J., Polymer Science, New age 4. Alfred rudin, The elements of polymer science and engineering, 2nd edition. Academic press publication, 1999
 - 5. Lowl.M., Ceramicmatrixcomposites: Microstructure, properties and applications, Woodhead Publishing Limited.2006
 - 6. Anke Krueger, Carbon Materials and Nanotechnology, Wiley-VCH Verlag GmbH & Co. KGaA, 2010

Learning Assessm	ent		11 1 7 2 1 L 2 L				
Bloom's Level of Thinking			Continuous Learnin ormative erage of unit test (45%)	CL	g Learning A-2 5%)	Final Ex	mative amination eightage)
	10.0	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	- 1	-	20%	20%	-
Level 2	Understand	20%	4/1/	-	20%	20%	-
Level 3	Apply	40%	100		40%	40%	-
Level 4	Analyze	20%	. 10.3		20%	20%	-
Level 5	Evaluate	/ 13	MARKALI	AD TRU		-	-
Level 6	Create	12/1	11 2 2 2 2 1 1	WITH THAT		-	-
	Total		100 %	10	0 %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Dr. P. Sudhakara, CLRI – CSIR, Jalandhar, sudhakarp@clri.res.in	Dr. Kothandaraman Ramanujam, IITM Chennai, rkraman@iitm.ac.in	1. Dr. N. Angeline Little Flower. SRMIST
2. Dr. Sudhakar Selvakumar, CSIR-Central Electrochemical Research	2. Dr.Arthanreeswaran, NIT, Trichy,	2. Dr. C. Siva, SRMIST
Institute, ssudhakar79@gmail.com	arthanareeg@nitt.edu	

Course	21NTC402T Course	MODELLING AND COMPUTATIONAL TOOLS	Course	^	PROFESSIONAL CORF	L	T	Р	С	;
Code	Name	MODELLING AND COMPUTATIONAL TOOLS	Category		PROFESSIONAL CORE	3	0	0	3	,

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ressive urses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:			7		F	rogra	am Ou	itcome	s (PC))					rograi	
CLR-1:	know the basics of GNU Octa	ve and C++		1	2	3	4	5	6	7	8	9	10	11	12		pecifi itcom	
CLR-2:	acquire detailed knowledge of	Density F <mark>unctional</mark> Theory		dge		of	SL			la.		ork		9				
CLR-3:	utilize and gain knowledge of	Molecul <mark>ar Dynam</mark> ics	h m	Knowlec	S	velopment	vestigations problems	зде	ъ			N W		inance	Б			
CLR-4:	The state of the s				alysis	lopr	estig	ol Usage	er and	۲ × × ×		Team	ţi	∞ ⊏	arning			
CLR-5:	understand the basics of modelin <mark>g and co</mark> mputational tools for materials modeling				Α	deve	ĕ ÷	٩	enginee ety	ment		<u>&</u>	ommunication	roject Mgt.	ig Le			
			ALC:	Engineering	roblem	ign/	onduc onduc	Modern		ᆲᅙ	S	ndividual	E E	ect	Long	7	7-5	-
Course C	se Outcomes (CO): At the end of this course, learners will be able to:				Prof	Des	o o	Me	The	Envil	Ethics	lndi	Col	Proj	Life	PSC	PSO-2	PSO
CO-1:	execute and solve problems v	vith the basics of computational tools	177	3	6-1	-	3	4	7	-	-	-	-	-	-	3	-	-
CO-2:	utilize the principles of DFT		Sec. 1	1.5	3	3	15	- 1		-		-	-	-	-	3	-	-
CO-3:	20-3: apply the knowledge of molecular dynamics to solve problems		3	10.00	- 1	-3	- (-	ė	-	-	-	-	-	2	-	
CO-4:	solve and perform modeling w	<mark>rith Mo</mark> nte Carlo method	11.7		3	1- (-	-	-	-		-	-	-	-	-	2	-
CO-5:	execute the computational co	des and predict the physical properties from modeling and simulation		3	F .	1	3	3		-	-	-	-	-	-	-	-	2

Unit-1 - Basics of GNU Octave

Introduction to GNU Octave -Arrays and Matrices-Matrix operation- Eigen value problem- Solution of simultaneous equation- Arithmetic operations- Logical operations- If-else clause- Loop control structure and statements- Break statement, Switch statement- Self-consistent method- Functions-data visualization in 2D and 3D- Contour Plots using GNU Octave, Plot of Fermi-Dirac Distribution Function using GNU Octave - Reciprocal (K)-space and K-space integration using GNU Octave

Unit-2 - Basics of C++

9 Hour

Introduction to C++- Algorithms- Structured-programing- I/O statements- Control statement- Looping (loop statement)- Matrix: Basic matrix operations-Functions-data visualization in 2D- Examples on data visualization in 3D- Basic idea of parallel programming- Basic concept of Computer clusters, Master Node, Working Node - Bewolf and Shared memory clusters in introductory level-Structure Visualization tools (VESTA)

Unit-3 - Density Functional Theory

9 Hour

Schrodinger equation- Schrodinger equation for Many Body problem- Born-Oppenheimer approximation- Hartee-Fock-method (discussion only)- Slater Determinant- Variational Principle- Introduction to DFT-Hohenberg-Kohn Theorem 1- Discussions on Hohenberg-Kohn theorem 1- Hohenberg-Kohn Theorem 1- Discussions on Hohenberg-Kohn theorem 1- Hohenberg-Kohn Theorem 2- Discussions on Hohenberg-Kohn theorem 2- Kohn-Sham Equation- Discussion on Kohn-Sham Equation- Exchange-correlation functions LDA (Basic Concept)- LDA (explanation of the equation)- Exchange-correlation functions GGA (Basic Concept)- GGA (explanation of the equation)- LSDA+U method-Basis set-Types of basis set (basic level)- Flow chart of DFT scf procedure- Discussions on Flow chart-Discussion on DFT codes-Example of Si (determination of lattice parameter and ban gap)

Unit-4 - Molecular Dynamics and Simulations

9 Hour

Classical molecular dynamics- Discussions on Classical molecular dynamics- Tight binding molecular dynamics- Discussions on Tight binding molecular dynamics- The basics of molecular dynamics (MD) algorithm-Discussions with examples on MD algorithm- Verlet algorithms- Discussions Verlet algorithms- Predictor - Corrector algorithm- Discussions on - Corrector algorithm- MD in different ensembles- Discussions MD in different ensembles- Examples of MD simulation- Discussions on qualitative results- Temperature variation effects in MD- Examples on Temperature variation effects in MD- Limitations of MD- Case study examples- Scope for Quantum Molecular Dynamics Simulations.-Molecular Dynamics Simulation of water molecule

Unit-5 - Monte-Carlo Method and Modelling

9 Hour

Monte-Carlo method and modelling tools: Introductory examples- Brief history- Fundamental key concepts- Transformation methods- Rejection sampling- Discussions of Rejection sampling- Importance sampling- Integration by importance sampling- Integr

Learning
Resources

- Jörg-Rüdiger Hill, Lalitha Subramanian, AmiteshMaiti, Molecular modeling techniques inmaterial sciences, Taylor & Francis 2005
- 2. J.M. Thijssen, Computational Physics, Cambridge University Press, 2007
- 3. Andrew R. Leach, Molecular modelling: principles and application, Pearson Education, 2001
- 4. Rizwann Butt, Introduction to Numerical Analysis using MATLAB, Jones and Bartlett Publishers, 2008
- Daan Frenkel and BerendSmit, Understanding molecular simulation: from algorithms to applications, Academic Press, 2001
- 6. Feliciano Giustino, Materials Modelling using Density Functional Theory: Properties and Predictions, Oxford University Press, 2014

earning Assessm	nent		Continuous Learning	g Assessment (CLA)						
	Bloom's Level of T <mark>hinking</mark>	Bloom's Life-Long Learning CLA 1 Average of unit test				Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	District Control of the	20%	- 4	20%	-			
Level 2	Understand	20%	William September 1	20%	- (20%	-			
Level 3	Apply	30%	71 172 75	-30%		30%	-			
Level 4	Analyze	30%	W 19 3 P 1 2 P 1	30%	-	30%	-			
Level 5	Evaluate	477-	A STATE OF THE STA)	-	-			
Level 6	Create			Fig. 34		-	-			
	Total	100	%	100 %	6	10	0 %			

Course Designers	1.9	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Hemant Dixit, GlobalFoundaries, USA, aplahemant@gmail.com	1. Dr. Ranjit Kumar Nanda, IIT Madras, nandab@iitm.ac.in	1. Dr. Saurabh Ghosh, SRMIST
2. Dr. Murali Kota, Global Foundaries, USA, kvrmmurali@gmail.com	2. Dr. Biswarup Pathak, IIT Indore, biswarup@iiti.ac.in	2. Dr. Arijit Sen <mark>, SRMIST</mark>

ACADEMIC CURRICULA

Professional Elective Courses

Regulations 2021



SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

Kattankulathur, Chengalpattu District 603203, Tamil Nadu, India

Course	21NTE201T Course	CARBON NANOTECHNOLOGY		_	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name Name	CARBON NANOTECHNOLOGY	Category	L	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		1			Prog	ram O	utcome	s (PO)					gram	
CLR-1:	acquire knowledge various	s forms of carbon	1	2	3	4	5	6	7	8	9	10	11	12		ecific comes	
CLR-2:	understand the use of car	bon forms in <mark>applications</mark>	dae	9	of	SI					Work		8				
CLR-3:	understand the physical a	nd chemica <mark>l properti</mark> es of fullerenes	Knowled	alvsis	evelopment of	vestigations problems	Usage	ъ			N W		Finance	Вu			
CLR-4:	-4: understand the physical and chemical properties of graphene				, ldol	estig		r and	∞ ×	l.	Team	ion	≪	arni			
CLR-5:	-5: understand the physical and chemical properties of carbon nanotubes					1.⊑ ‰	Tool	engineer stv	ronment tainability		<u>रू</u>	ommunication	Mgt.	g Le			
					ign/d	onduct	lern	e eng	Tain	SS	/idu	ות	Project	Long	SO-1	SO-2	က
Course O	ourse Outcomes (CO): At the end of this course, learners will be able to:		Engi	Problem	Des	5 6 6 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8	Mod	The	Sus	Ethics	Individual	Sol	Proj	<u>l</u> e	PSC	PSC	PSO-3
CO-1:	define different allotropes	of <mark>carbon, t</mark> heir structure, and bonding in carbon	2	- 2	1.5	-	-		-		-	-	-	-	3	-	-
CO-2:	evaluate the potential of fu	ıll <mark>erene for</mark> various applications	2	12-	40.50	2	-	1	-	-	-	-	-	-	-	2	-
CO-3:	CO-3: define different carbon nanotubes and evaluate their applications		.3	MIL TE	D.	2	-	-	-		-	-	-	-	3	-	-
CO-4:	express the key concepts of CVD, epitaxy, and exfoliation methods of graphene production and applications of graphene		and 3			2	_	-	_		-	-	-	-	3	-	-
CO-5:			_2	7	2	1 -	_	-	-		-	-	-	-	-	-	2

Unit-1 - Various Forms of Carbon 9 Hour

Introduction to carbon molecules – Atomic structure of carbon, Carbon hybridization; Dimensionality forms of carbon, Graphite and diamond structure, Discovery and atomic structure of fullerene (C60), Carbon nanotubes (CNTs) and their classification, From graphene sheet to a nanotube, Zigzag and armchair nanotubes, Chirality in nanotubes, Defects in carbon nanotubes, Defective nanotubes and Euler's theorem

Unit-2 - Physical and Chemical Properties of Carbon Nanotub

Fullerenes - Structure, Bonding, Nomenclature; C60 and higher fullerenes - Growth mechanisms, production and purification; Fullerene preparation by pyrolysis of hydrocarbons and partial combustion of hydrocarbons, Physical properties of fullerene, Chemical properties of fullerene, Hydrogenation of fullerene, Applications of fullerenes in – polymer solar cell, hydrogen storage 21, biomedical, donor-acceptor systems

Unit-3 - Synthesis, Characterization and Applictions of Carbon Nanotubes

9 Hour

Carbon Nanotubes - Structure of carbon nanotubes, Nomenclature of carbon nanotubes, Electronic properties of carbon nanotubes, Synthesis and production of Multi-Wall CNTs (MWCNTs), Growth mechanism of CNTs, Analysis of carbon nanotubes by X-ray diffraction and Raman Spectroscopy, Carbon nanotubes as - Field Effect Transistors (FET), chemical sensors, bio-sensors, gas sensors; Electronic and sensor applications of carbon nanotubes – CNT based field-emission display, FETs, Computers; Applications in solar cells, hydrogen storage, heterogeneous catalysis; Biological applications of carbon nanotubes

Unit-4 - Synthesis, Characterization and Applictions of Carbon Graphene

9 Houi

Graphene – Discovery, Atomic structure of graphene, Band structure of graphene, Graphene derivatives – graphene oxide; Graphene production by - Exfoliation, Chemical Vapor Deposition, and Epitaxy; Properties of graphene, Raman spectroscopy of graphene - Phonon modes in graphene, Layer dependence of Raman spectra, Raman spectroscopy of graphene under strain; Characterization of graphene by – Fourier Transform Infrared Spectroscopy (FTIR), X-Ray Diffraction (XRD), Electron Energy Loss Spectroscopy (EELS), and X-ray Photoelectron Spectroscopy (XPS); Graphene as transparent electrode, FETs, photodetectors; Applications in solar photovoltaics, chemical sensing, and energy storage

Unit-5 - Diamond and Amorphous Carbon Coatings

9 Hour

Diamond thin films - Structure of diamond films, Single-, poly-, and ultranano-crystalline diamond; Preparation and growth mechanism of CVD diamond films, Structure of CVD diamond, Chemical properties of CVD diamond, Chemical properties of CVD diamond, Covalent functionalization of diamond films, CVD diamond as - wear resistant coating, bio-chemical sensors. Optical applications - infrared windows, lenses, X-ray windows Amorphous carbon (a-C) thin films - Ternary phase diagram of a-C, Hydrogenated amorphous carbon films (a:C-H), Physical and chemical properties of amorphous carbon film, PECVD of a:C-H; Amorphous carbon films as anti-reflection and anti-corrosive coatings

Learning
Learning Resources

- 1. Anke Krueger, "Carbon Materials and Nanotechnology", Wiley-VCH, 2010
- 2. Yury Gogotsi, "Carbon Nanomaterials", Taylor and Francis, Second edition, 2014
- 3. C. N. R. Rao, Ajay K. Sood, "Graphene: Synthesis, Properties, and Phenomena"- Wiley-VCH, 2013
- 4. Wonbong Choi, Jo-won Lee, "Graphene: Synthesis and Applications" CRC Press, Taylor and Francis, 2012.

Learning Assessm	nent						
	Bloom's Level of Thin <mark>king</mark>	CLA-1 Avera	Continuous Learnin native ge of unit test 0%)	g Assessment (CLA) Life-Long CLA (10	4-2	Final Ex	mative amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	2004 8420 - 1	20%		20%	-
Level 2	Understand	20%	Carlot of the same	20%		20%	-
Level 3	Apply	30%	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	30%	. 7	30%	-
Level 4	Analyze	30%	William Comment of	30%		30%	=
Level 5	Evaluate —	S 477 6	A22 - 1920 - 1921	7 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	- 2	-	-
Level 6	Create	42.773	FE 17 19 19 19 19 19 19 19 19 19 19 19 19 19	1. 机毛发放性机		-	-
	Total	10	0%	100) %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. R. Easwaramoorthy, ARCI, easwar@arci.res.in	1. Prof. M.S. Ramachandra Rao, IITM Chennai, msrrao@iitm.ac.in	1. Dr. S. Chandr <mark>amohan,</mark> SRMIST
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	2. Prof. S. Balakumar, University of Madras, balakumar@iunom.ac.in	2. Dr. Abhay Sa <mark>gade, SR</mark> MIST



Course	21NTE202P Cou		Course _	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Nai	e VACOON AND ITHIN FILM TECHNOLOGI	Category	PROFESSIONAL ELECTIVE	2	1	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

THE RESERVE

Course Le	Course Learning Rationale (CLR): The purpose of learning this course is to:		11	4			Progr	am Ou	tcome	s (PO))					ogram	1
CLR-1:	acquire knowledge on vacuum systems and technology	11.2	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcomes	
CLR-2:	understand the functionalities of various vacuum pumps and	gauges	dge		o	SL	1	. "			Work		8				1
CLR-3:	gain Knowledge on various physical and chemical vapor depo	sition techniques	a)	S	nent	estigations problems	Usage	ъ			am W		Finan	В			
CLR-4:	understand the various thin film growth mechanisms and the	ries explaining them	Knowle	alysis	velopment	estig/ probl	ol Us	er and	۲ × ×		Теа	tion	∞ర	arning			
CLR-5:	gain knowledge on various characterization techniques tools	o characterize thin films	ering	Α	(D)	$=$ \sim	0	engineer ety	ment ability		al &	nica	Mgt.	g Le			
Course Or	atcomes (CO): At the end of this course, learn	ore will be able to:	nginee	oblem	esign/de	onduct ir compley	Aodern T	Φ.∺	nviron Ist <mark>ain</mark>	Ethics	ndividual	ommunication	roject	ife Long	2SO-1	PSO-2 PSO-3	
CO-1:	apply the functionalities of vacuum systems and can operate		3	٦	ے کے	5 G	Σ.	Ļ S -	<u>ய் ல</u>	Ti .	<u>=</u>	ŏ	<u>-</u>	<u> </u>	å	2 -	-
CO-2:	utilize the knowledge acquired to operate vacuum pumps ar regimes		_	1	100	3	-	£	-	-	-		-	-	-	2 -	
CO-3:	grow thin films using various physical and chemical vapor dep	osition techniques	11-5	144	3	-	-	-	-		-	-	-	-	3		1
CO-4:	explore the physical and chemical properties of thin films	North Barnella, a	ملعة			2	-	-	-		-	-	-	-	3		1
CO-5:	apply the concept of various characterization tools and opera	e them	_2		- '- 1	-	-	-	-	-2	-	-	-	-	-	2 -	1

Unit-1 - Introduction to Vacuum Systems

9 Hour

Over view, working and principles of vacuum systems and technology-Units and different regions of vacuum-Kinetic theory of gases-Gas flow and mean free path-Conductance-Different types of pumps-Mechanical Pumps-Diffusion and turbo molecular pump-lon Pumps-Measurement of vacuum-Direct and indirect gauges-Pirani Gauge-Capacitance gauge-Penning gauge-Vacuum system-Leak detection methods-Components and operation of vacuum system-Safety practices in vacuum systems-Applications of vacuum technology

Unit-2 - Physical Vapor Deposition Methods

9 Hour

Over view of Physical vapor deposition techniques-Thermal evaporation, Resistive heating and RF-heating-Flash evaporation-Laser evaporation-Co-evaporation-Electron bombardment heating-Sputtering plasma, discharges and arc-Sputtering variants, yield and low pressure sputtering-Resctive sputtering-Magnetron sputtering-Magnetron configurations-Bias sputtering-Evaporation versus sputtering-Pulsed laser deposition (PLD) design and basics-PLD operating procedure and its various application-Molecular beam epitaxy (MBE) basics-MBE operating procedure — Substrate types and cleaning methods — Substrate dependence on thin film quality

Unit-3 - Chemical Vapor Deposition Methods

9 Hour

Introduction to chemical deposition methods-Electrodeposition-Electrolytic Deposition-Electro less deposition-Anodic Oxidation-Spray Pyrolysis-Dip coating and Spin Coating-Chemical vapor deposition (CVD)-Homogenous and heterogeneous process-CVD reactions-Hydrogen Reduction-Halide disproportionation, transfer reactions-CVD processes and systems-Low pressure CVD-Laser enhanced CVD-Metalorganic CVD (MOCVD)- Plasma Assisted Chemical Vapor Deposition (PACVD)- Safety considerations

Unit-4 - Thin Film Nucleation and Growth, Thickness Measurement Methods

9 Hour

Basic physics and chemistry behind thin films layer formation-Nucleation and thin thin film formation concepts-Thermodynamic aspects of nucleation-thin film growth modes-Capillary theory-Volmert-Weber growth-Frank-van der Merwe (FM) growth-Stranski-Krastanov Growth-Thickness dependent properties of thin films-Thickness Measurements-Roughness-Electrical Methods-Microbalance monitors-Quartz crystal monitor-Mechanical method (stylus)- Optical interference methods-Ellipsometry-Interference fringes

Unit-5 - Structural, Compositional and Electrical Characterization

9 Hour

Thin films characteristics-Topography-Structure integrity- X-ray diffraction (XRD)- Scanning electron microscopy-Transmission electron microscopy-Energy dispersive analysis of thin films-Auger electron spectroscopy-X-ray photoelectron spectroscopy-Rutherford backscattering spectroscopy-Secondary ion mass spectrometry-Resistance – 2-point probe-Resistance – 4-point probe-Optical properties-Characterization of layered structures-Atomic force microscopy (AFM)- Raman Spectrocopy- Hall effect measurements- Reflection high energy electron diffraction (RHEED)- In-situ RHEED

Learning
Resources

- 1. M. Ohring, Materials Science of Thin Films: Deposition and Structure, 2nd Ed., Academic 3. S. Campbell, the Science and Engineering of Microelectronic Fabrication, 2nd Ed., OUP, 1996. Press (An Imprint of Elsevier), 2002.
- 2. K.L.Chopra, Thin Film Phenomena, Robert E.Krieger Publishing Company, 1979.
- 4. Kaufmann, Characterization of Materials, 2 nd Ed., Wiley, 2003.

			Co	ontinuous Learnin	g Assessment (C	LA)			
	Bloom's Level of Think <mark>ing</mark>	CLA-1 Averag	Formative CLA-1 Average of unit test (20%)		Project Based Learning CLA-2 (60%)		d Viva Voce 0%)	Final Examination (0% weightage)	
		Theory	Practice	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	with the fill	1.388	20%	-	20%	-	-
Level 2	Understand	20%	5.90	海南南 医足	20%	-	20%	-	-
Level 3	Apply	30%		17 Mars 160	30%		30%	-	-
Level 4	Analyze	30%	1000	10 A.	30%	Alleria 3	30%	-	-
Level 5	Evaluate		14,631	1. Oct 197	For 1- 30.	77.3		-	-
Level 6	Create	-	ALL STATES	300 Feb.	2 10 10	10 m		-	-
	Total	100) %	10	0 %	10	00%		-

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Mohan Bhan, OAI, USA, mbhan@oainet.com	1. Dr. Ramesh Chandra Mallik, IISc Bangalore, rcmallik@iisc.ac.in	1. D <mark>r. P. Mal</mark> ar, SRMIST
2. Mr, C P Sridhar, SIMCO Groups, Bangalore, sridhar.cp@simcogrou	p.in 2. Dr. Bhaskar Chandra Mohanty, Thapar University, bhaskar@thapar	r.edu 2. D <mark>r. C. Go</mark> palakrishnan, SRM IST

Course	21NTE203T	Course	NANOTRIBOLOGY	Course	Е	PROFESSIONAL FLECTIVE	L	Т	Р	С	
Code	Z 11N 1 E 2031	Name	INANOTRIBOLOGY	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	Learning Rationale (CLR): The purpose of learning this course is to:	4	7			Progr	am Oı	ıtcome	s (PO)					rogram
CLR-1:	acquire knowledge on nanotribology	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes
CLR-2:	gain insight on surfaces forces and its measurement techniques	a)		11	of		ety			~					
CLR-3:	enhance the knowledge on lubrication, friction and wear and their importance	edge		nt of	stigations lems	Φ	society	10 7		Work		Finance	1		
CLR-4:	know about mechanisms involved in tribology related mechanical properties	Knowle	.8	bme	tigat	sag	and a		N.	eam	_		arning		
CLR-5:	attain knowledge on tribological applications in day to day life. Understand paperibology and		m Analysis	n/development of	prob	dern Tool Usage	engineer a	Environment & Sustainability	. `	~ ~	ommunication	t Mgt. &	Long Lear		
Course C	Outcomes (CO): At the end of this course, learners will be able to:	Engine	Problem	Design solutio	Conduct	Moder	The er	Enviro Sustai	Ethics	Individual	Comm	Project	Life Lo	PSO-1	PSO-2 PSO-3
CO-1:	strengthen knowledge in the basic tribological concepts required for nanotechnology	3	10	No.	3	-	1	-	-	-	-	-	-	3	- -
CO-2:	identify, formulate, and solve engineering problem of interacting surfaces in relative motion	3	47 -	2	-	-	7			-	-	-	-	3	
CO-3:	realize the significance of lu <mark>brication</mark> , friction and wear	3	1.4	- A-	2	-	-	-		-	-	-	-	-	- 3
CO-4:	· ·			2	44	-		-	-:	-	-	-	-	-	3 -
CO-5:	utilize nanotribological principles for any applications, Emphasize the knowledge of scientific discipling in understanding tribological phenomenon	lines	3	1	-	2		-	-	-	-	-	-	3	

Unit-1 - Introduction to Nanotribology

9 Hour

History of tribology-origin- Introduction to micro and nanotribology - Significance of micro/nanotribology- Tribology in design-Methods of solution of tribological problems- Purpose and necessity of lubrication- Modes of lubrication- hydrodynamic- Hydrostatic lubrication- Boundary lubrication- Elasto hydrodynamic lubrication- Extreme pressure lubrication- Lubricants - types and lubricating oils - working principles of liquid and solid lubricants - Lubricant properties-effect of temperature and pressure- Oxidation stability- Thermal conductivity- Type of additives- Bearings- classification based on mode of lubrication- Bearing-Classification based on relative motion between contact surfaces- Comparison of sliding and rolling contact bearing- essential properties of a lubricant

Unit-2 - Surface Forces and Its Measurements

9 Hour

Surface Forces- Methods used to study surface forces- Force laws- Surface force apparatus (SFA)- Force between dry surface- Force between surfaces in liquid- Adhesion- Capillary forces- Modes of deformation-Description of AFM/FFM- Other measurement techniques- Surface roughness- Friction force- Scratching- Wear and machining- Surface potential measurements- Nanoindentation measurement- Boundary lubrication

Unit-3 - Lubrication, Friction and Wear

9 Hour

Lubrication- Lubricant States- Viscosity of lubricant- Fluid film lubrication- Theories of hydrodynamics lubrication- Lubrication design of typical mechanical elements- Transformation- Parameter of surface topography-Friction- Basic laws of friction- Static and kinetic friction- Friction of materials- Solid – solid contact- Liquid mediated contact- Interfacing temperature of sliding surfaces- Wear-Laws of wear- Mild and Severe wear-Identification of wear mechanism- Typical test geometries

Unit-4 - Tribology Related Mechanical Properties

9 Hour

Scale Effects in Mechanical Properties- Nomenclature- Yield strength and Hardness- Shear strength at the interface- Scale dependence on surface roughness and contact parameters- Dependence of contact parameters on load- Scale effects in friction- Adhesion Friction- Two body deformation- Three body deformation- Ratchet mechanism- Meniscus Analysis- Total value of coefficient of friction- Transformation from leastic to plastic regime- Tribological properties of SAMs- Tailoring surfaces- Modifying surface composition for application in Tribology – Lubricant re-use and disposing methods

Unit-5 - Nanotribology Applications and Its Importance

9 Hour

Applications of Tribology-Introduction to various tribological phenomenon- Bio-Tribology in the human body- Tribology in the artificial organs- Tribology in medical devices- Natural human synovial jointsTotal joint replacements- Wind turbine Tribology- Biorefining- Coating applications- sliding bearings- Rolling contact- Bearings- Gears- Erosion and scratch resistant- Magnetic recording devices- Micro componentsMEMS/NEMS

Learning	
Resource	S

- 1. G. Phakatkar and R.R. Ghorpade, "Tribology", Nirali publication, 2009
- 2. Bharat Bhushan, "Nanotribology and Nanomechanics", Springer Publication, Second edition, 2011
- 3. Bharat Bhushan," Principles and Applications to Tribology", Wiley Publication, 2013
- 4. C. Mathew Mate, "Tribology on the Small Scale" Oxford University Press, 2008
- 5. Nicholas D. Spencer, "Tailoring surfaces", World Scientific IISC Press, 2011

earning Assessm			Continuous Learnin	g Assessment (CLA)		0			
	Bloom's Level of Think <mark>ing</mark>	CLA-1 Aver	mative age of unit test 50%)	Life-Long CLA (10	1-2	Summative Final Examination (40% weightage)			
	4.57	Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%		20%	G- 2	20%	-		
Level 2	Understand	20%	40, CH (8425) + 5	20%		20%	-		
Level 3	Apply	30%	Carlot of Mary and	30%		30%	-		
Level 4	Analyze	30%	A 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	30%	. 1	30%	-		
Level 5	Evaluate		Village To State	Port 1 30 7		-	-		
Level 6	Create		All the same of th	The second section	- C	-	-		
	Total	10	00 %	100	%	10	0 %		

Course Designers	- The second second	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Shinji Yamada, Kao Corporation, Tokyo, Japan, Yamada.s@kao.co.jp	Dr. M. Balasubramanian, IIT Madras, mbala@iitm.ac.in	1. Dr. S. Yuvaraj, SRMIST
2. Dr. Sridhar M. R, Senior Engineer, GE Global Research, Bangalore,	2. Dr. M. S. Ramachandra Rao, IIT Madras,	2. Dr. Kiran Ma <mark>ngalampa</mark> lli, SRMIST
India.	msrrao@iitm.ac.in	

Course	21NTF204T	Course	SLIDEACES AND INTEDEACES	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	2111112041	Name	SUNFACES AND INTERFACES	Category	E	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	I^{r}	4			Progr	<mark>am</mark> Ou	ıtcome	es (PO)				P	rogram
CLR-1:	introduces the basic concepts that are used to describe the atomic or molecular structure of surfaces and help the students to understand why/how surfaces play paramount significances in nanotechnology	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes
CLR-2:	explain various mechanisms involved in surfaces/interfaces and fundamentals of various types of bonding at surfaces/interfaces		1	7	7	λ.		ability							
CLR-3:	describe strategies for manipulating the surfaces and how those strategies help them depending upon the application of such modified surface	edge		int of	ions of	Θ	society	Sustainat	h	Work		Finance			
be familiar with property equations and thermodynamic properties of gas-surface interactions along with the concepts of phase equilibrium of multi-component systems		Knowle	Analysis	n/development of	investigations problems	Usage	and	∞ ŏ		Team	tion	∞ర	ä		
CLR-5:	acquire the knowledge in Ads <mark>orption a</mark> nd desorption kinetics	eering	em An	n/deve	act inve	m Tool	engineer a	Environment		dual &	Communication	Project Mgt.	Long Le	_	2 8
Course C	outcomes (CO): At the end of this course, learners will be able to:	Engin	Problem	Desig	Conduct	Modern	The e	Enviro	Ethics	Individual	Comn	Projec	Life Lo	PSO-1	PSO-2 PSO-3
CO-1:	apply the knowledge in surfaces; their structure and physical-chemical properties, and interfaces between solids	3	1	1	12	-	U) -		-	-	-	-	3	
CO-2:	anticipate the stability of a given interface and the behaviour of molecules close to the interface	3	-	2	100	-	-	-) <u>-</u> ‡	-	-	-	-	-	- 2
CO-3:	decide what are the necessary thermodynamics concept to describe an interface	_2		-54	16.	-		-	-0	-	-	-	-	3	
CO-4:	develop sound understanding in new phenomena such as curved surfaces, facets and fractal formations	3		2	-	-		-		-	-	-	-	-	2 -
CO-5:	validate sound understanding in collective phenomena at the surfaces/interfaces	2	-	-	2	/ _ I		- 1	7	١.	-	-	-	3	

Unit-1 - Atomic or Molecular Surface 9 Hour

Introduction to surface quantities – Physics of Surface and interface - its importance/significance-Surface creation- Extension of a surface - Relations among surface quantities- Relations between γ and σ - Determination of surface parameters - Equilibrium at intersections of surfaces: wetting - Non-reactive wetting - Non-reactive wetting - Work of adhesion - Capillary rise - Small droplets - Non-ideal surfaces - Reactive wetting - Selected values of interfacial energiesMolecular Interactions-General concepts of Internal Energy and Free Energy-Intramolecular Forces: Formation of a Molecule by Chemical Bonding-Interatomic forces, bonds - -Polar Interactions-van der Waals Interactions- Collective phenomena at interfaces – a) Superconductivity-Superconductivity at interfaces —-Ferromagnetism at interfaces- Magnetic layer coupling

Unit-2 - Mechanisms in Surfaces/Interfaces 9 Hour

Trends in activation energies for surface reactions - Electronic effects in surface reactivity- Geometrical effects in surface reactivityThe Hierarchy of Equilibria-Thermodynamics of Flat Surfaces and Interfaces- The Interface Free Energy- Surface Excesses- Charged Surfaces at Constant Potential- Charged Surfaces at Driven potential- Maxwell Relations-Their Applications-Solid and Solid interfaces- Solid-Liquid Interfaces- Step Line Tension- Stiffness at its interfaces- Equilibrium Fluctuations of Line Defects and Surfaces- The Terrace-Step-Kink Model - Basic Assumptions and Properties- Step-Step Interactions on Vicinal Surfaces- The Ising-Model- Application to the Equilibrium Shape of Islands- Simple Solutions for the Problem of Interacting Steps

Unit-3 - Thermodynamic Considerations In Tailoring Surfaces/Interfaces For Specific Applications

9 Hour

Bond formation and breaking dynamics - Adiabatic dynamics (Born-Oppenheimer approximation) - Non-adiabatic dynamics- Hot electrons from chemistry - Chemistry from hot electrons - Adsorption and Desorption Kinetics- Physisorption and Chemisorption- - Molecular adsorbates - local sites, orientations and intramolecular bondlengths- Experimental background/ techniques - Typical measurements - Rate measurements 3.2.2 Adsorption-trapping and sticking-Desorption - Symmetry of Adsorption Sites- Vibrational Frequencies of Isolated Adsorbates- Desorption - Desorption Spectroscopy- Theory of Desorption Rates-

Photochemistry/femtochemistry- Single molecule chemistry (STM) - The Langmuir Isotherm- Lattice Gas with Mean Field Interaction- The Fowler-Frumkin Isotherm- Reduction to the Langmuir Isotherm- The Chemical Bond of Adsorbates of Hydrogen, Oxygen molecules- The Chemical Bond of Adsorbates of Water, Hydrocarbons, aliphatic and aromatic molecules

Unit-4 - Phase Equilibrium of Multicomponent Systems

9 Hour

Structure of Surfaces - Surface Crystalliography- Surface stress, Surface energy- Relaxation, Reconstruction - Surfaces of crystalline solids - Surface energy for crystalline solids- Equilibrium crystal shape - Internal boundaries - types of grain boundaries - Intersections of grain boundaries with free surfaces - Faceting - Measurement of surface and grain-boundary energies - The zero-creep technique - The multiphase-equilibrium (MPE) technique - Interphase interfaces - Interface classifications - a) Coherent interfaces - Semicoherent interfaces, c) Incoherent interfaces - d) Interface mobility - Defects at surfaces/interfaces - line & point defects- Vibrational Excitations at Surfaces - -Statistics of Random Walk- Absolute Rate Theory- Calculation of the Pre-factor- The Ehrlich-Schwoebel Barrier- The Concept of the Ehrlich-Schwoebel Barrier- The Kink Ehrlich-Schwoebel Barrier-

Unit-5 - Adsorption and Desorption Kinetics

9 Hour

Introduction to Thin-film and its formation - Growth of thin oxide films - Formation of metal films by physical vapor deposition/evaporation - self-assembly- self-organization - Curved surfaces - Derivation of the Laplace equation - techniques that use the Laplace equation to measure surface energy - Phase equilibria in one-component and multicomponent systems - Adsorption - The Gibbs adsorption equation- The origin of stresses in multilayer systems - Formation stresses - Thermal stresses-Applied stress - Electronic Properties at the surfaces- Beyond the Surface Selection Rule-Empty and image - potential surface states- Case studies - protective layers on superalloys in gas turbines- Formation and adhesion of protective oxide layers - Multilayer systems - thermal barrier coatings - Linear Optical Techniques at Surfaces and Interfaces- Spectroscopic Ellipsometry (SE)- Reflection Difference Techniques (Surface Differential Reflectivity (SDR)- Kelvin Probe measurements for the study of work-function changes

- G. Bordo Vladimir and Horst-Günter Rubahn, Optics and Spectroscopy at Surfaces and Interfaces, WILEY-VCH Verlag GmbH & Co. KGaA, Weinheim 2005
- Harald Ibach, Physics of Surfaces and Interfaces, Springer-Verlag Berlin Heidelberg 2006
- H. Yıldırım Erbil, Surface Chemistry of Solid and Liquid Interfaces, First published in 2006 by Blackwell Publishing Ltd, Oxford, UK
- Anders Nilsson, Lars G.M. Pettersson, Jens K. Nørskov, Chemical Bonding at Surfaces and Interfaces, Elsevier, Amsterdam. The Netherlands 2008
- John C. Riviere, Sverre Myhra, Handbook of Surface and Interface Analysis: Methods for Problem-Solving, 2nd Edition, CRC Press Taylor & Francis Group 2009
- Gerald H. Meier, Thermodynamics of Surfaces and Interfaces (Concepts in Inorganic Solids), Cambridge CB2 8BS, United Kingdom 20147. Klaus Wandelt, Surface and Interface Science, Volume Solid-Gas Interfaces II, Wiley VCH Verlag, Weinheim, Germany 2015

Learning Assessm	ent			Carlot All			
			Continuous Learnin	g Assessment (CLA)		Sumi	native
	Bloo <mark>m's</mark>	Formative CLA-1 A	verage of unit test	Life-Long Le	arning CLA-2		amination
	Level of T <mark>hinking</mark>	(50	%)	(10	0%)	(40% we	eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	- 12%	20%	7 71- 1	20%	-
Level 2	Understand	20%		20%	~/. <u> </u>	20%	-
Level 3	Apply	30%		30%		30%	-
Level 4	Analyze	30%	ARNILI	30%	2/2/0	30%	-
Level 5	Evaluate	1 1 1 1	Traces III	MESTER		-	-
Level 6	Create			And	/	-	-
	Total	100) %	100	0 %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.org	1. Prof. V. Subramaniam, Physics Department, IITM, Chennai, manianvs@iitm.ac.in	1. Dr. AAlagiriswamy A A, SRMIST
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research India, India,	2. Prof. Gridhar U. Kulkarni, Director at CeNS, Bangalore, guk@cens.res.in	2. Dr. E. Senthil Kumar, SRMIST
Krishna.muvvala@saintgobain.com		

Course	21NITE 201T Course	SPECTROSCOPY TOOLS FOR NANOSCALE ANALYSIS	Course	_	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name	SPECTROSCOPT TOOLS FOR NANOSCALE ANALTSIS	Category	Е	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to	CUILING	Program Outcomes (PO)							Pro	ograr	n									
CLR-1:	acquire the knowledge in the basic concepts of interaction of radia spectroscopy	ion with matter and rotational	1 2 3 4 3 0 7 0 9 10 11 12									12	Sp Out								
CLR-2:	comprehend the principles of vibrational spectroscopy		dge		of	าร					Work		ce								
CLR-3:	understand the principles and techniques involved in of Raman scatteri	ng - The Thirt	Knowledge	S	elopment of	stigations roblems	age	ъ					Finance	Вu							
CLR-4:	emphasize the significance of various techniques in electronic spectros	сору		alysis	lopr	estig orobl	ol Us	er and	t &		Team	tion	∞ŏ	aming							
CLR-5:	expose to concepts and applicat <mark>ions of m</mark> agnetic resonance	A STATE OF THE STA	ering	₹	8	t inv	٩	ingineer ty	ment <mark>ability</mark>		<u>8</u>	Sommunication	Mgt.	ıg Le							
		5781.483027.1.4.77%	ĕ	roblem	ign/d tions	duct	ern		ronm ainab	SS	/idu	l mr	roject	Lon	7	7-2	-50-3				
Course O	Outcomes (CO): At the end of this course, learners will b	e able to:	Engi	Pro	Des	Con	Modern	The	Envir Susta	Ethics	Individual	Con	Proj	Life	Life Long Lea PSO-1 PSO-2						
CO-1:	interpret the processes of ab <mark>sorption</mark> and radiation and analyse the rota	tional motion in molecules	3	3	V_{2N}		-	1	-		-	-	-	1	3	-	2				
CO-2:	analyze the vibrational spec <mark>tra of dia</mark> tomic and polyatomic molecules		3	3	1		-	1	-	-	-	-	-	-	-	-	-				
CO-3:	3	3	7	-	-	-	-		-	-	-	-	-	3	-						
CO-4:	CO-4: elucidate the various optical processes involved in the electronic spectra						-	-	-		-	-	-	-	-	-	2				
CO-5:	apply the concept magnetic resonance in chemical analysis and structu	re determination	3			3	-	-	-		-	-	-	-	3	-	-				

Unit-1 - Interaction of Radiation with Matter

9 Hour

Introduction to Electromagnetic spectrum and its applications, spectral Regions- Types of molecular energies- Interaction of light with matter- Methods of obtaining a spectrum, components and various construction types of a spectrometer- Various accessories used in a spectrometer – Various sourcer of electromagnetic spectrum used in a spectrometer - Spectral line width and broadening of spectral lines- Intensity of spectral lines- Absorption and emission of radiation- Spontaneous and stimulated processes- Einstein's co-efficients and its derivation- Laser as a spectroscopic light source- Rotational spectra of rigid diatomic molecules - Rigid rotator- Isotope effect in rotational spectra, Intensity of rotational spectroscopy.

Unit-2 - Principles of Vibrational Spectroscopy

) Hour

Vibrational energy of a diatomic molecule - Classical approach - Wave mechanical approach - Morse curve and energy levels of a diatomic molecule - Selection rules for vibration - Fundamental overtones and hotbands in the vibrational spectrum - Accidental degeneracy - Diatomic vibrating rotator - Selection rules for vibration - Vibrations of polyatomic molecules - Normal vibrations of CO2 and H2O molecules - Interpretation of IR spectra - Group frequencies and various regions in IR spectrum - Perturbation of group frequencies: mass effects - Perturbation of group frequencies: inductive effects - Fourier transform infrared spectroscopy: principle and interferometer arrangement - Elucidation of molecular structure using IR Spectroscopy - Identification of molecular constituents using IR spectroscopy

Unit-3 - Vibrational Spectra of Diatomic and Polyatomic Molecules

9 Hour

Born oppenheimer approximation - Vibrational coarse structure - Band system and vibrational transitions - Progressions and sequences - Franck condon principle - Intensity of vibrational electronic spectra - Rotational fine structure - Assignment of bands in a fine structure - Dissociation energy and dissociation products - Predissociation - Electronic absorption spectra - Electronic angular momentum in diatomic Molecules - Singlet and doublet states - Jablonski diagram - Phosphorescene - Fluorescence - Photoelectron spectroscopy: principle - Photoelectron spectroscopy: instrumentation

Unit-4 - Fundamentals of Raman Scattering

9 Hour

Quantum theory of Raman scattering - Classical theory of Raman scattering - Rotational Raman spectra - Vibrational Raman spectra - Mutual exclusion principle - Polarization of Raman scattered light - Raman spectrometer - Analysis of Raman spectra - Structure determination using Raman spectroscopy - Raman investigation of phase transitions - Resonance Raman scattering - Surface enhanced Raman scattering - Non-linear Raman phenomena- preliminaries - Hyper Raman effect - Stimulated Raman scattering - Inverse Raman effect - Coherent Antistokes Raman scattering - Photo acoustic Raman scattering - Laser selection for Raman spectroscopy of materials

Unit-5 - Magnectic Moment and Spectroscopy Tools

9 Hour

Magnetic moments – Quantization - Larmor precession - Resonance condition in Nuclear magnetic resonance (NMR) - Spin –spin relaxation - Spin-lattice relaxation - NMR spectrometer - Chemical shift - Factors contributing to screening- Double resonance technique - NMR imaging - Fourier transform NMR techniques – Applications of NMR spectroscopy - Electron spin resonance - Resonance condition in Electron spin resonance (ESR) - ESR spectrometer - Nuclear- electron spin coupling - Applications of ESR spectroscopy

Learning
Learning Resources

- Peter Atkins, Julio de Paula Atkins, "Physical Chemistry", W. H. Freeman and Company, New York, 2010
- Collin Banwell, Mc Cash, "Fundamentals of Molecular Spectroscopy", McGraw Hill publishing, 2001
- 3. G. Aruldhas," Molecular structure and spectroscopy", Prentice Hall, 2001
- 4. P.S.Sindhu, "Fundamentals of molecular spectroscopy" New age international publishers, 2006

earning Assessm	nent			THE PARTY OF THE P						
			Cum	Summative						
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	Formative CLA-1 Average of (50%)		CL	Learning A-2 0%)	Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	200	20%		20%	-			
Level 2	Understand	20%	707 2	20%	3	20%	-			
Level 3	Apply	30%	1 mg - 466 - N	30%		30%	-			
Level 4	Analyze	30%		30%		30%	-			
Level 5	Evaluate			/ L			-			
Level 6	Create	III.	- 1977	-	- 4		-			
	Total	100 %	1.7	100	0 %	10	0 %			

Course Designers		7
Experts from Industry	Experts from Higher Technical Institutions	Internal Expe <mark>rts</mark>
1. Dr. D.K. Aswal, National Physical Laboratory,	Dr.G. Aravind, IIT Madras, garavind@iitm.ac.in	1. Dr. R. Annie Sujatha, SRMIST
dkaswal@nplindia.org	VIVEARN-IEAD room	/ / 5
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research India,	2. Dr. M. S. Ramachandra Rao, IIT Madras, msrrao@iitm.ac.in	2. Dr. E. SenthilKumar, SRMIST
India, Krishna.muvvala@saintgobain.com	4313111	J 400

Course	21NTE302P Course	LITHOGRAPHY TECHNIQUES AND FABRICATION	Course	_	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name	LITHOGRAFITI TECHNIQUES AND PADRICATION	Category	L	PROFESSIONAL ELECTIVE	2	1	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses		Nil	
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		• •	Nil	

Course L	earning Rationale (CLR): The purpose of learning this course is to:	W	Program Outcomes (PO)						gram									
CLR-1:	understand the physical significance of lithography tools in micro/nano structures creation	1	2	3	4	5	6	7	8	9	10	11	12		cific omes			
CLR-2:	acquire knowledge on masked lithography, uv and deep uv lithography, its merits and demerits			77				oility										
CLR-3:	understand the concept of direct lithography, its advantages; electron beam for lithography and thei applications	ŏ		ant of	ions of	<u>o</u>	society	Sustainability		Work		Finance	_					
CLR-4:	applications acquiring comparative knowledge of different lithography tools acquiring knowledge on the replication tools such as pane imprint lithography injection molding and so a such as pane injection molding and so a suc																	
CLR-5:	acquire knowledge on the replication tools such as nano imprint lithography, injection molding and others	ering K	n Analysis	ign/development of	inve	00	engineer a	Environment &	1	∞ర	ınicatio	Mgt. &	မ					
0	100	_ Engine	Problem	sign/	Conduct	Modern		viron										
Course C	outcomes (CO): At the end of this course, learners will be able to:	핍	- P	De la	8 8	ĕ	The	핍	Ē	<u>u</u>	ပိ	Pro	Lif	S S	3 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8 8			
CO-1:	make use of top-down appro <mark>ach for </mark> micro/nano fabrication	3	j	10 31	- 1	-	4	-	-	-	-	-	-	3	- -			
CO-2:	analyze the limitation of ma <mark>sked litho</mark> graphy with respect to incident radiation	(A)	2	42	13	-	-	- 1	-	-	-	-	-	-	2 -			
CO-3:	using electron beams for the creation of nano structures	1 3-1	- 1	2		_	-	-		-	-	-	-	2				
CO-4:	know the other techniques o <mark>f nano fa</mark> brication using light and heavy ion beams	-			χ-	-		-		-	-	-	-	2				
CO-5:	apply knowledge of mass production replication tools	2	- 1	100	-			-	_0	_	-	-	:					

Unit-1 - Top-Down and Bottom-Up Approaches for Micro/Nano Fabrication

9 Hour

Micro/nano fabrication-Top-down & bottom-up approach-Necessity for clean room, types of clean room-Construction and maintenance of clean room-Clean room standards, protocols-Lithography- process steps-Photo resists materials, types and characteristics-Spin coating methods-Exposure dose-chemical development, optimization-Etching methods, resist and other materials-Dry and wet methods-Wet etching chemicals, Si etching-Wet etching examples-Reactive ion etching-Isotropic and non-isotropic etching-Types of lithography: classification-Introduction to next generation lithography tools.

Unit-2 - Optical Lithography

y mour

Introduction to lithography - Optical(photo) lithogr<mark>aphy-Proc</mark>ess steps-Optical lithography mask-Mask definition, and different materials-Lamp and LED UV sources-Contact and proximity exposures-Diffraction limit and resolutions enhancement methods-Projection lithography-Extreme UV (EUV) lithography-EUV: Scope and demerits-Interferometric and holographic tools-Laser writer: near UV and Deep UV masks-Synchrotron radiation for lithography processes-X-ray lithography mask-X-ray lithography, merits and demerits-Comparison of all masked lithography tools-Specific applications of different lithography tools – Defects in lithography processes(undercut/overcut)

Unit-3 - Electron Beam Lithography

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Introduction-maskless/direct lithography tools-Difference between masked and maskless lithography-Advantages and disadvantages of maskless lithography-Principles of electron beam lithography (EBL) system-Electron properties for lithography-Design of electron beam lithography system-Operation of electron beam lithography system-E-beam resists-E-beam resist properties-Comparison with optical lithography resists-Dose calculation-Significance of beam blanking-Patterning resolution comparison with other methods-EBL for mask preparation-Nanofabrication with EBL – MEMS-Nanofabrication with EBL – Nanofabrication wit

Unit-4 - Ion Beam Lithography 9 Hour

on beam lithography (IBL) types-Heavy and light ions for lithography-Focused ion beam properties-Beam scanning-Resists for ion beam lithography-Electron lithography process flow-Focused ion beam lithography-Incident ion properties-Principle, design and operation-Masked ion beam structuring: Broad beam patterning-Atom lithography-Proton beam lithography-Comparison of electron, proton and gallium for resist patterning-Limitation and suitability of each technique in comparison with one another-IBL resists, dose calculation and process optimization-Nanofabrication with IBL – MEMS-Nanofabrication with IBL – Nanofabrication with IBL – Nanof

Unit-5 - Replication tools 9 Hour

Micro/ Nano replication tools-Mass production tools-Application areas-MEMS/NEMS, micro/nanofluidics-Soft lithography-PDMS Casting-Mold fabrication for soft lithography-Micro injection molding-Hot embossing-Nano imprint lithography NIL principles-Mold fabrication for hot embossing and NIL-Mold fabrication for injection molding-Process flow and requirements-Polymers for imprinting-Polymer characteristics and performance-Master mold preparation for replication tools, comparison-Application-microfluidics-Application-nano fluidics-Industrial applications

Learning
Resources

- Chris A. Mack, Fundamental Principles of Optical Lithography: The Science of Microfabrication, John Wiley & Sons, London 2007
- 2. Stefan Landis, "Lithography and nanolithography", Published by Wiley ISTE, 2010
- 3. Theodore C HennessyLithography: Principles, Processes & Materials (Engineering Tools, Techniques and Tables), Nova Science Publishers Inc., 2011.
- 4. José María De Teresa, Introduction to nanolithography techniques and their applications, IOP Publishing Ltd 2020

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			Co						
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	Formative CLA-1 Average of unit test (20%)		CL	ed Learning A-2)%)		d Viva Voce 0%)		amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%		700	20%	문자 - 4	20%	-	-
Level 2	Understand	20%	10 mm	2012-2013	20%		20%	-	-
Level 3	Apply	30%	12-1	- 44 N	30%	100	30%	-	-
Level 4	Analyze	30%	100		30%	4.7	30%	-	-
Level 5	Evaluate			4	A service of	-		-	-
Level 6	Create		,100	- 777	-	-	₩ 3	-	-
	Total	100) %	10	0 %	10	0%		-

Course Designers			<i></i>
Experts from Industry	and the same	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Mohan Bhan, OAI, USA, mbhan@oainet.com		1. Prof. M. S. Ramachandra Rao, IIT Madras,	1. Dr. P. <mark>Malar, SR</mark> MIST
		msrrao@iitm.ac.in	
2. Mr, C P Sridhar, SIMCO Groups, Bangalore,	10	2. Prof. S. Balakumar, Madras University,	2. Dr <mark>. Abhay S</mark> agade, SRM IST
sridhar.cp@simcogroup.in	p	balakumar@unom.ac.in	

Course	21NTE303T	Course	SENCODE AND TRANSPIREDS	Course	П	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	Z 11N 1 E 303 1	Name	SENSORS AND TRANSDUCERS	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	NI	ressive urses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	am Ou	tcome	s (PO)					rogram
CLR-1:	understand basic principles and characteristics of sensors and transducers	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	gain knowledge on mechanical and ele <mark>ctromecha</mark> nical sensors	dge		of	SI		. ".			Work		8			
CLR-3:	LR-3: get acquainted with thermal sensors and its types				atior	Usage	ъ			N K		Finan	б		
CLR-4:	know about magnetic sensors and radiation sensors	Knowle	Analysis	evelopment	restigations problems) Us	r and	∞ >	h.	Team	ion	⊗ E	arning		
CLR-5:	gain knowledge on electrochemical sensors, and applications of other sensors in our life	ring				. 1	inicat Mgt.			L L					
Course	curse Outcomes (CO): At the end of this course, learners will be able to:				onduct in complex	odern T	e .e	nviron Istain	Ethics	ndividual	ommunication	roject	ife Long	-SO-1	PSO-2 PSO-3
		Eng	4	<u> </u>	g g	€	ნ 8	<u> ந ல</u>	E	Ĕ	ŏ	<u>Ā</u>	<u> </u>	_	8 8
CO-1:	analyze calibration technique <mark>s, chara</mark> cteristics and signal types of sensors	-	1.5	2	3	-		-	-	-	-	-		3	<u> </u>
CO-2:	explain about principle and working of physical sensors	2	- 1	43	3	-	4	-		-	-	-	-	3	- -
CO-3:	understand the types of ther <mark>mal sen</mark> sors and its importance	2	17/2	4.3	2	-	-	-		-	-	-	-	_	3 -
CO-4:	be aware of magnetic and radiation sensors	2	- 1	5 1	3	-	-	-		-	-	-	-	-	3 -
CO-5:	recognize electrochemical sensors and nanosensors along with the applications of various sensors used home appliances and industries		-4	3	2	-		-		-	-	-	-	-	3 -

Unit-1 – Classification and Charaterization

9 Hour

Measurements-Basic method of measurement- Errors- Classification of errors- Error analysis- Statistical methods- Sensors/Transducers-Introduction- Principles of Sensors/Transducers- Classification of Sensors/Transducers- Static Characteristics of Sensors/Transducers- Accuracy-Precision-Resolution-Minimum detectable signal- Threshold-Sensitivity-Selectivity and specificity-non-linearity- Hysteresis-Output impedance-isolation and grounding- Dynamic Characteristics- Zero order and First order sensors- Second order sensors- Electrical characterization- Mechanical and thermal characterization- Optical characterization- Chemical/biological characterization

Unit-2 – Mechanical and Electromechanical Sensors

Hour

Resistive potentiometer- Strain gauge- Inductive sensors- Sensitivity and linearity of sensor- Ferromagnetic plunger type transducers- Electromagnetic transducer- Magnetostrictive transducer- Capacitive sensors- Parallel plate capacitive sensor- Serrated plate capacitive sensor- Variable thickness dielectric capacitive sensor- Stretched diaphragm variable capacitance transducer- Electrostatic transducer- Piezoelectric elements- Piezoelectric materials- Deformation modes and multimorphs- Lead zirconate titanate (PZT) family- Force/stress sensors using quartz resonators

Unit-3 – Thermal Sensors

9 Hour

Gas thermometric sensors- Thermal expansion type thermometric sensors- Acoustic temperature sensor- Dielectric constant and refractive index of thermosensors- Helium low temperature thermometer-Nuclear thermometer- Magnetic thermometer- Resistance change type thermometric sensors- Metal resistance thermometric sensors- Thermosensors- Materials for thermo emf sensors- E (emf)-T(Temperature) relations- Thermosensors using semiconductor devices- Thermal radiation sensors- Detectors- Pyroelectric thermal sensors- Quartz crystal thermoelectric sensors- Heat flux sensors

Unit-4 – Magnetic Sensors and Radiation Sensors

9 Hour

Introduction to Magnetic sensors- Principles behind- Yoke coil sensors- Coaxial type sensors-Force and displacement sensors- Magnetoresistive sensors- Anisotropic magnetoresistive sensorg- Semiconductor magnetoresistors- Active semiconductor magnetic sensors- Hall effect sensor-sensor geometry and fabrication- Variable inductance sensors- Eddy current sensors- Radiation sensors-Introduction-basic characteristics- Types of photoresistors/photodetectors- Photoemissive cell and photomultiplier- Photoconductive cell-LDR- Photocurrent- Photoresistors and photo FETs and other devices- Fibre optic sensors-Temperature sensors-microbend sensors

Unit-5 - Electroanalytical Sensors and Sensor Technologies

9 Hour

Electroanalytical sensors-introduction- Electrochemical cell- Sensor electrodes-Molecular selective electrodes- ChemFET- Recent trends in sensor technologies- Film sensors- Thick and thin film sensors-Semiconductor IC technology- Micro electro mechanical system (MEMS)- Fabrication of MEMS using lithography (process steps) - micromachining- Some application examples- Nanosensors- Onboard automobile sensors-flow rate sensors-pressure sensors- Temperature sensors-oxygen sensors- Torque and position sensors- Home appliance sensors-Aerospace sensors-Fluid velocity sensors- Sensing direction of air flow-Monitoring-strain, force, thrust and acceleration-Medical diagnostic sensors-Sensors for environmental monitoring – Integration of different sensors in a MEMS device

Learning Resources
Resources

- 1. Ernest O Doebelin, "Measurement Systems Applications and Design", 4th ed., Tata 3. D. Patranabis, Sensors and Transducers, 2nd ed., Prentice Hall of India, 2010 McGraw-Hill, 2009
- 2. John P. Bentley, "Principles of Measurement Systems", 4th ed., Pearson Education, 2000
- 4. D.V.S Murthy, Transducers and Instrumentation, 2nd ed., Prentice Hall of India, 2001.

Learning Assessme	ent			TAKES IN			
•	Bloom's Level of Thinking	CLA-1 Avera	Continuous Learnin native rge of unit test 0%)	CL	Learning A-2 0%)	Final Exa	native amination eightage)
	9 9	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	The 1997 AND	20%	-	20%	-
Level 2	Understand	20%	10 70 70 70 70 70	20%	-	20%	-
Level 3	Apply	30%	10 mm	30%		30%	-
Level 4	Analyze	30%		30%		30%	-
Level 5	Evaluate		The state of the s	Annual Control		-	-
Level 6	Create		- 4/1//	-	-4		-
	Total	10	0 %	100	0 %	10	0 %

Course Designers		//
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Maximilian Fleischer, Siemens, Germany,	1. Dr. A. Subrahmanyam, IIT Madras, manu@iitm.ac.in	1. Dr. S. <mark>Yuva</mark> raj, SRMIST
maximilian.fleischer@siemens.com	/ DEAKN- FAD TRIES	
2. Dr. Shyam Sunder Tiwari, Sensor's technology Private	2. Dr. M. S. Ramachandra Rao, IIT Madras, msrrao@iitm.ac.in	2. D <mark>r. A. Karthi</mark> geyan, SRMIST
Limited, India, sst@sensorstechnology.com	CI II II	

Course	21NTE30/IT	Course	CDEEN NANOTECHNOLOGY	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	Z 11N 1 E 304 1	Name	GREEN NANOTECHNOLOGY	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	W	4			Progr	<mark>am</mark> Օւ	itcome	s (PO)					rogram	
CLR-1:	familiarize with the field of traditional manu <mark>facturing to</mark> green manufacturing	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcomes	
CLR-2:	CLR-2: understand the various techniques for sustainable green manufacturing				SI		. ".			Work		Se .				1
CLR-3: able to identify green nanotechnology concepts in Industrial process			S	evelopment of	stigations roblems	Usage	Ъ	. 1		Μ		Finan	ning			
CLR-4:	ering Knowle	alysis	lopi	investig ex probl		r and	∞ >	h.	Team	ion	∞ŏ	a				
CLR-5:	LR-5: understand the list of metrics in the industry					Tool	engineer a	nment nability	. 1	<u>छ</u>	Sommunication	Mgt.	g Le	,		
					nduct ir omplex	dern	ery ety	iron	S	Individual	l E	roject	Long	-1-)-2	
Course C	Outcomes (CO): At the end of this course, learners will be able to:	Eng	Problem	Des	Con	Moc	The	Env Sus	Ethi	ln j	S	Proj	Life	PSO.	PSO-2	
CO-1:	incorporate the green Nanote <mark>chnolog</mark> y in industrial processing	3		2	-	-	/	-	-	-	-	-	-	-	- -	
CO-2:	CO-2: demonstrate the various principles of green manufacturing				3	-	4	-	-1	-	-	-	-	2	- 2	
CO-3:	CO-3: create various metrics for Industrial manufacturing				43	_	_	-	-	-	-	-	-	-		
CO-4:	CO-4: produce life cycle assessments and machine tools			2	3	-	-	-		-	-	-	-	2		
CO-5:	apply the green manufacturing in the semiconductor industry	-	- 3		3	2		-		_	_	_	-	-	2 -	

Unit-1 - Green Manufacturing

9 Hour

Green manufacturing and Sustainability goals for the future - Environment impact on waste generation, Toxic chemical releases - Energy consumption and carbon emission strategies for green manufacturing — Biological sources used in Nanotechnology: Plants & Microorganisms — Mechanisms of biosynthesis of nanoparticles — Effect of parameters such as pH, temperature, concentration, exposure time, type of enzyme — Phytochemical based Nanoparticles — Plant derived nanoparticles — Mechanism of Phytochemical synthesis

Unit-2 - Techniques for Sustainable Green Manufacturing

9 Hour

Social, business & policy environment, Need for change - Internal stake holders, External stake holders - Components of next transition, Linear to circular transition - Product production to service provision, Integrated information, Rich communication - Policy environment, Changing policy trends, Fostering co-operation - Principles of green manufacturing, Technology: wedgets -1st principle of green manufacturing, 2nd principle of green manufacturing - Mapping of principles, Solutions

Unit-3 - Metrics for Industrial Green Manufacturing

9 Hour

Metrics for green manufacturing, Current metrics - Financial metrics, Metrics for ecology - Metrics for society, Multiple metrics - Impact assessment, Risk assessment - Material flow analysis, Energy flow analysis - Metric development methodologies, Ecological metric choice model - Decision tree model for equipment's Supply, Metrics development for component systems - Green energy supply, Green energy technologies - Solar photovoltaics, wind energy, Application potentials of green energy - Integration of green energy systems to conventional energy systems

Unit-4 - Life Cycle of Green Production

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Closed loop production systems, Life cycle production systems - Economic and ecological benefits, Reduction of investment & increase of resources, Machine tools, Energy consumption - Life cycle assessment machine tools, Methods & results - Process parameter optimization, Constant feed per tooth - Constant spindle speed, Conventional vs high speed machining - Dry machining and minimum quantity lubrication, Health & environmental hazards - Remanufacturing: product recovery & industrial practice, Challenges & opportunities - Reuse, Approaches for sustainable factory design - Zero carbon design - available technologies towards zero carbon footprint

Unit-5 - Green Manufacturing in Semiconductor Processes

9 Hour

Semiconductor manufacturing, Semiconductor fabrication - Micro fabrication process, Lithography - Oxidation & annealing, Cleaning - Facility systems, resource use, Abatement - Green manufacturing in industry, Concepts & challenges - Use phase issues, Analysis phase of semiconductor manufacturing - Upstream materials, Chemicals, silicon, water - Infrastructure & equipment, Electricity - Semiconductor manufacturing, Transportation & use phase

Learning
Resources

- Green Manufacturing- Fundamentals and Applications, David A Dornfeld, Springer science publishing, 2013,
- Green Nanotechnology: Solutions for Sustainability and Energy in the Built Environment, Geoffrey B. Smith, Claes-Goran S. Granqvist, CRC Press, 2010
- 3. An Introduction to Green Nanotechnology, Mahmoud Nasrollahzadeh, Mohammad S. Sajadi, Monireh Atarod, Elsevier Science Publications, 2019.

Learning Assessm	ent			- 7						
Bloom's Level of Thin <mark>kin</mark> g		CLA-1 Avera	Continuous Learnin native ge of unit test 0%)	CL	Learning A-2 0%)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	2004 8220 200	20%		20%	-			
Level 2	Understand	20%	Carlot Marian	20%		20%	-			
Level 3	Apply	30%	A Section of the Sect	30%		30%	-			
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Level 6	Create		No. 10 E. 130	"一根是2000年代"		0 -	-			
	T <mark>otal ====================================</mark>	100	0%	100	0 %	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Manoj Maurya, Jayalakhsmi Waving Mills Pvt Ltd, Salem@jailakshmi.com	1. Dr. T. Ramesh Babu, Anna University, trb@annauniv.edu	1. Dr. C.Siva, SRMIST
2. Mr.Hitesh Rathore, SHT Distributors – Salem, TN,	2. Dr. M. Rajmohan. Anna University, rajmohan@annauniv.edu	2. Dr. M. Navaneethan, SRMIST
hitheshrathore@gmail.com		

Course	24NITE 20ET Course	NANOMAGNETISM AND SPINTRONICS	Course _	PROFESSIONAL ELECTIVE	L	T	Р	С	,
Code	Name	NANOMAGNETISM AND SPINTRONICS	Category □	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil	
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	17	4			Progr	am Oı	itcome	s (PO)					ograr	
CLR-1:	understand the basic cond	cepts related vari <mark>ous type of m</mark> agnetism and magnetic properties of materials	1	2	3	4	5	6	7	8	9	10	11	12		oecifio tcomo	
CLR-2:	provide in-depth knowledg	ge about low <mark>dimensional</mark> magnetic materials	dge		of	SL					ork		9				
CLR-3:	understand the magnetiza	tion behav <mark>ior of mag</mark> netic nanostructures and thin films	wlec	S	elopment	estigations roblems	Usage	ъ	. 1		am W		nan	Бū			
CLR-4:	give an overview of differe	ent Exper <mark>imental A</mark> pproaches to characterize magnetic nanostructures	Αno	alysi	ldol	estig		er and	× ×	h.	Teal	ation	% ⊢	arni			
CLR-5:	acquaintance with spin tra	nsport <mark>mechani</mark> sm in magnetic materials	ring	An	deve	t inv	Tool	enginee	ment ability		<u>∞</u>	nica	Mgt.	g Le			
	-		nginee	Sem	ign/e	duct ii	lern	eng ety	ironi	S	Individual	mmunic	roject l	Lo _l	7	7-5	SO-3
Course O	ourse Outcomes (CO): At the end of this course, learners will be able to:				Des	Con	Moc	The	Env Sus	Ethics	Indi	Sol	Proj	Life	PSC	PSC	PSC
CO-1:	realize the importance of "	ma <mark>gnetism"</mark> in contributing to past and for the advancement of new technology	/ 3	- 3	1		-	-7	-		-	-	-	-	3	-	-
CO-2:	appreciate the significance	e o <mark>f in-dept</mark> h understanding of magnetic properties in low dimension	3	- i	25	3	-	1	-		-	-	-	-	3	-	-
CO-3:	obtain the knowledge a nanostructures	bout fabrication of magnetic thin films and properties of the magnetic	3) ik	Ä.,	3	-	-	ř -	-:	-	-	-	-	-	2	-
CO-4:	know various sensitive characterization techniques for investigating magnetic nanostructures		3	3	-	- 3	-	-	-	-:	-	-	-	-	-	2	-
CO-5:	analyze the mechanism of magnetic memory device	f s <mark>pin trans</mark> port in magnetic nanostructures and its relevance in advancing the performance	3	-		3	-		-	- 0	-	-	-	-	-	-	2

Unit-1 - Types of Magnetism 9 Hour

Basics of magnetism, Units in magnetism, Different types of magnetism: Dia, Para, Ferro, Ferri, Antiferro – Application of different materials possessing different magnetic property - Origin of various type of magnetization behaviour, Magnetization curves and hysteresis loops, Saturation magnetization, Coercive field, Magnetic susceptibility, Formation of magnetic domains, Domain walls, Domain walls, Domain walls, Domain walls, Pomain walls, Poma

Unit-2 - Magnetic ordering and Anisotropy

9 Hour

Concept of Magnetic ordering, Magnetic ordering in low dimensions, Physical origin of Magnetic anisotropy, Shape anisotropy and Magnetocrystalline anisotropy, Dipolar anisotropy, Interface magnetic anisotropy, Mechanisms of magnetization reversal, Coherent rotation, Fanning, curling Domain wall movement, Introduction to Gilbert damping, In-plane magnetic anisotropy, Magnetic domains in in-plane magnetized materials, Perpendicular magnetic anisotropy, Magnetic domains in out-of-plane magnetized materials, Formation of magnetic vortex, Formation of antivortex and Skyrmions

Unit-3 - Magenetic Properties in Low Dimension

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Magnetism in thin films, Magnetism in multilayers, Fabrication of nanomagnets using various techniques, Top down and bottom up approach, Single domain versus multi domain behaviour, Chemical synthesis of magnetic nano-particles, Self-assembly of magnetic nanoparticles, Magnetic nanowires, Physical vapour deposition of magnetic thin films and multilayers, DC and RF Sputter deposition, E-beam evaporation technique, Magnetization reversal in magnetic thin films, Domain walls and magnetization reversal nanostructures, Magnetic properties of NiFe, CoFeB (soft) and FePt, CoPt (hard) materials

Unit-4 - Magnetometers and Characterization Tools

9 Hour

Introduction to various magnetometers, Working principle of magnetometers, Vibrating Sample Magnetometer, Superconducting Quantum Interference Device, Magnetic imaging techniques, Magneto-optical Kerr effect, Longitudinal, Transverse and Polar Kerr effect, Faraday effect, Magnetic force microscopy, Scanning electron microscopy with polarization analysis, Interpretation of magnetic contrast from thin films and nanostructures, Magnetic contrast from nanostructures, Spin-polarized scanning tunnelling microscope (SP-STM), Interpretation of SP-STM results, Magnetic recording and its principles, Nanomagnetic disks, Read and write head

Unit-5 - Spin Transport in Magnetic Nanostructures and Applications

9 Hour

Introduction to spin transport, spin angular momentum, Spin Current, Spin valve devices, Giant magneto resistance (GMR), Spin dependent scattering, Valet-Fert model for GMR, Magnetic tunnel junction, Tunnel magneto resistance (TMR), Application of GMR and TMR, Spin transfer torque, Spin-orbit coupling induced phenomena, Spin-orbit torque, Spin Hall effect, Spin dynamics, Advanced spintronics based devices, Domain wall-based memory, Race track memory

- Principles of Nanomagnetism, by Alberto P. Guimaraes, XII, Springer Berlin Heidelberg New York, 2009
- 4. Nanomagnetism and Spintronics Hardcover, Teruya Shinjo, Elsevier, 2013
- 2. Advanced Magnetic Nanostructures, by David Sellmyer, Ralph Skomski, Springer Heidelberg, 2010
- 5. Magnetism and Magnetic Materials J M D Coey, Cambridge University Press 2012
- 3. Spin dynamics and damping in ferromagnetic thin films and nanostructures, by Anjan Barman and Jaivardhan Sinha, Springer, Switzerland, 2018
- 6. B.D. Cullity, Introduction to Magnetic Materials, Addison- Wesley (1972)

earning Assessm			7	Continuous Learnin	g Assessment (CLA)		Cum	mative
	Bloo <mark>m's</mark> Level of <mark>Thinkin</mark> g	3	Forma CLA-1 Averag (50)	e of unit test	Life-Long CL (10		Final Ex	ramination eightage)
			Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember		20%		20%	-	20%	-
Level 2	Understand		20%	100	20%		20%	-
Level 3	Apply		30%		30%		30%	-
Level 4	Analyze		30%	The second second	30%		30%	-
Level 5	Evaluate	-	-	· 1////	-	-4	-	-
Level 6	Create		-	- 1.9	-		-	-
	Total	-	100	%	100) %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Dr. Hemant Dixit, GlobalFoundaries, USA, aplahemant@gmail.com	Dr. Arabinda Haldar, IIT Hyderabad, arabinda@iith.ac.in	1. Dr. Jaivardhan Sinha, SRMIST
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research India, India, Krishna.muvvala@saintgobain.com	2. Dr. M. S. Ramachandra Rao, IIT Madras, msrrao@iitm.ac.in	2. Dr. Kamala Bharathi, SRMIST

Course	21NTE306T Course	2D LAVERED NANOMATERIALS	Course _	_	DDOEESSIONAL ELECTIVE	L	Т	Р	С
Code	Name	2D LAYERED NANOMATERIALS	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre	e-requisite	Co- requisite	Nii	Progressive	Nil
(Courses	" Courses	IVII	Courses	IVII
C	ourse Offering Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	H.	4			Progr	am Oı	ıtcome	s (PO))					rogra	
CLR-1:	understand the 2D layere	Nanomaterials <mark>and its prope</mark> rties and importance	1 -	2	3	4	5	6	7	8	9	10	11	12		pecifi ıtcom	
CLR-2:	familiarize the structure a	nd properties <mark>of graphen</mark> e	(I)		7/	of	,	ciety			~						
CLR-3:	acquire knowledge about	different sy <mark>nthesis met</mark> hods for producing layered materials	Knowledge		nt of	ions	Φ	socie	, 1		Work		Finance				
CLR-4:	reinforce and enhance the understanding of the principles of various characterization tools in study 2D materials				gn/development ions	estigations oblems	Usage	and	t &	N	Team	tion	∞ర	arning			
CLR-5:	-5: gain knowledge on various 2D layered materials and the application of layered nanomaterials				deve	t inv	Tool	engineer	Environment 8 Sustain <mark>ability</mark>		<u>∞</u>	Sommunication	Mgt.	g Le			
	•		ngineering	oblem-	ign/di tions	duc	lern		ironi	g	ndividual	nur	roject l	Long	0-1	-5	-3
Course O	ourse Outcomes (CO): At the end of this course, learners will be able to:				Des	Con	Mod	The	Env	Ethics	İpu	Con	Proj	Life	PSC	PS0-2	PSO-3
CO-1:	distinguish various 2D lay	ere <mark>d nanom</mark> aterials and their properties	2	, D	6 59	3	-	1	-		-	-		-	3	-	-
CO-2:	apply the concept of stomic and electronic structure to understand the physical and chemical proportion				4	3	-	3) -		-	-	1	-	-	2	-
CO-3:	CO-3: utilize the different techniques for preparation of 2D layered nanomaterials		1	120	2	3	-	-	-		-	-		-	-	3	-
CO-4:	0-4: analyze the 2D layered nanomaterials using various characterisation techniques		مجاز	1	2	3	-	_	-		-	-	1	-	-	3	-
CO-5:	apply the distinct propertie	es <mark>of 2D lay</mark> ered materials in various fields	3			-	-	-	-		-	-	-	-	-	-	3

Unit-1 – 2D Materials and Its Examples

9 Hour

Introduction to 2D materials - Layered and Non-layered materials - bonds in layered materials - van der Walls force- Covalent bond-Types of Layered materials - Graphene, TMDs, Black phosphorous, h-Boron Nitride, MXenes and Layered metal oxides. Properties, Advantages and Applications of 2D Layered Nanomaterials.

Unit-2 - Graphene and its Properties

9 Hour

Introduction to graphene - Dimensionality forms of carbon allotropes- Graphene structure - Manipulation of quantum degree of freedom- Crystal plane of 2D graphene- Free standing model- Electronic structure of graphene- Band structure- Fermi levels in graphene- Carrier density- Role of defect and dopant- Electronic structure of graphene- Tensile strength- Physical properties of graphene- Functional properties of graphene- Penta-graphene and its properties.

Unit-3 - Preparation Methods for 2d Materials

9 Hour

Preparation techniques for 2D layered materials - Introduction to Scotch-tape method (micromechanical cleavage)- Preparation of graphene using Scotch-tape method-Pros and cons of micromechanical cleavage method - Introduction and principle of Chemical vapor deposition- Preparation of graphene by CVD- Introduction to Solution-exfoliation- Preparation of graphene using solution- exfoliation- Introduction to Solution-exfoliation- Preparation of 2D layered material by solution exfoliation- Decomposition of silicon carbide

Unit-4 - Chracterization Tools for 2d Materials

9 Hour

Characterization techniques - Principles of Raman spectroscopy- Limitations of Raman spectroscopy- Raman spectrum of graphene- Analysis of D band Raman spectra- Analysis of G band Raman spectra- Raman shift dependence on defect- Raman shift dependence on doping concentration. Introduction to X-ray photoemission spectroscopy- Limitation and application of XPS- Introduction to X-ray diffraction study- Limitation and application of XRD- Introduction and limitations to BET analysis- Adsorption properties – other characterizations for analyzing 2D materials

Unit-5 - Application of 2d Materials

9 Hour

Introduction to h-BN structure, synthesis and properties- Application of h-BN. Introduction to SiC structure, synthesis and properties- Application of SiC structure. Introduction to layered metal oxides - structure, synthesis and properties- Application of SiC structure. Introduction and types of transition metal Dichalcogenides- Introduction and application of MoS2, Introduction and application of VS2- Introduction of BCN and its applications

- 1. Houssa, Michel, Athanasios Dimoulas, and Alessandro Molle, "2D Materials for Nanoelectronics"- CRC Press, 2017.
- 2. Banks, Craig E., and Dale AC Brownson, eds. "2D Materials: Characterization, Production and Applications"- CRC Press, 2018.
- Ter-Zakaryan, A., and A. D. Zhukov. "Materials Horizons: From Nature to Nanomaterials." In Materials Horizons: From Nature to Nanomaterials, pp. 349-377. 2021. (Materials Horizons: From Nature to Nanomaterials2D Nanomaterials for Energy and Environmental Sustainability)
- 4. Tiwari, Ashutosh, and Mikael Syväjärvi, eds. "Advanced 2D Materials" John Wiley & Sons, 2016.
- Dragoman, Mircea, and Daniela Dragoman,"2D Nanoelectronics: Physics and Devices of Atomically Thin Materials"- Springer, 2017

earning Assessm	TOTAL		С	ontinuous Learning	g Assessment (CLA)							
	Bloom's Level of <mark>Thinking</mark>	Formative Life-Long Learning CLA-1 Average of unit test CLA-2 (50%) (10%)					Summative Final Examination (40% weightage)					
			Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	-	20%	32 Table 1	20%	- 0	20%	-				
Level 2	Understand		20%	3 m	20%		20%	-				
Level 3	Apply		30%		30%		30%	-				
Level 4	Analyze		30%	- Land - All - N	30%		30%	-				
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Level 6	Create		1 - William 1975		/			-				
	Tot <mark>al</mark>		100 %	The state of the s	100	%	10	0 %				

Course Designers	110	/ . /
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Hemant Dixit, Global Foundaries, USA, aplahemant@gmail.com	1. Prof. K. Sethupathi. IIT Madras, ksethu@iitm.ac.in	1. Dr. J. Archana, SRMIST
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research India, India,	2. Dr. S. Balakumar. University of Madras, Madras, balakumar@iunom.ac.in	2. Dr. S. Harish, SRMIST
Krishna.muvvala@saintgobain.com	B FARN-IEAD TRIBLE	

Course	21NTE207T Course	NANOCATAL VCTC		_	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name	NANOCATALISTS	Category '	L	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses		Nil	
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		- ا	Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		έ.,	4			Progr	<mark>am</mark> Οι	itcome	s (PO)					rogram	
CLR-1:	acquire the concepts of C	Chemistry of Nano <mark>catalysts</mark>		1 - (1)	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes	
CLR-2:	understand the Catalytic	Kinetics	Ç	aĥn		o ^t	SI		. ".			Work		8				1
CLR-3:	describe the reaction kine	etics of Adso <mark>rption and</mark> Desorption processes		₽	S	Jent	stigations roblems	Usage	ъ	. 1		Μ		Finan	ning			
CLR-4:	understand the principles	s behind th <mark>e Synthe</mark> sis of Nanocatalysts	5		alysis	n/development of ons	estig		r and	ج ج ک	h.	Team	fion	∞ర	ä			
CLR-5:					An	deve	> -	<u>S</u>	engineer a	nment nability	1	<u>8</u>	Sommunication	Mgt.	g Le			
						ign/	nduct in complex	dern	ery ety	iron	S	Individual	חשר	roject	Long	PS0-1	5.2	
Course C	urse Outcomes (CO): At the end of this course, learners will be able to:			20 1	Problem	Des	Con	₩.	The	Sus Sus	Et	Indi	Sol	Proj	Life	PSC	PSO-2	
CO-1:	express the mechanism of	of m <mark>aterials f</mark> or using as catalyst	-137 2	2 -		4-1	3	-	-7	-		-	-	-	-	3		
CO-2:			9	3	2	1	- 19	-	4	-	-	-	-	-	-	3		
CO-3:	2-3: evaluate the photocatalyst for environmental remediation			gi.	2	4	-34	-	_	3		-	-	-	-	-		
CO-4:	0-4: analyse the working of nobl <mark>e metals</mark> as Nanocatalysts			3	1	. 1	-	-	-	-		-	-	-	-	-	3 -	
CO-5:				2	3		7 -			-	_=	_	_	_	_	_	3 -	٦

Unit-1 - Chemistry of Nanocatalysts

9 Hour

Introduction to Catalysis - Classifications of Catalysis - Necessary properties of a catalyst - Heterogeneous Catalysis - Reaction on the Solid Surfaces - Active sites: Activation Energy - Adsorption Isotherms - Physisorption and Chemisorption - Brunauer Emmett Teller (BET) theory - Total Surface Area - Pore volume and Pore size distribution - Porosity characterization techniques - Hg Porosimetry Method - N2 Adsorption Desorption method - Reaction Mechanism - Kinetics of the Heterogeneous Catalytic Reactions - Activation energy (Arrhenius equation, Eyring equation) - Terminology in Catalysis: TO (Turnover), TON (Turnover number), TOF (Turnover frequency) - Sequences involved in a Catalysed Reaction - Asymmetric Synthesis using a Catalyst

Unit-2 - Catalytic Kinetics

9 Hour

Introduction to Adsorption and Desorption Processes - Adsorption Rate - Desorption Rate - Catalytic Activity (Bulk and Nanoscale) - Catalytic Activity Determination for Metal/Metal-Oxide Nanostructures - Langmuir Hinshelwood Mechanism for Nanocatalysts - Mass Transport - Diffusion controlled Process - Adsorption equilibrium on Uniform Surfaces: Langmuir Isotherms Single-site (non-Dissociative) Adsorption - Derivation of the Langmuir Isotherm - Adsorption equilibrium on non-Uniform Surfaces: Langmuir Isotherms - The Freundlich Isotherm - The Temkin Isotherm - Activated Adsorption - Catalytic Efficiency - Applications of Metal Nanoparticles in Organic Reactions - Environmental Remediation.

Unit-3 - Photocatalysis

y Hour

Kinetics and Photocatalytic Activity - Introduction to Photocatalyst - Basics of Electrochemistry - Photochemistry - Electronic Structure and Photocabsorption - Jablonskii Diagram - Structure of Photocatalysts - Solar Spectrum - Fundamental Understanding of Semiconductor Interfaces - Principles and Relevance to Photocetochemical Mechanism - Photocatalysis Mechanism - Properties of good Photocatalysts - Advantages of Photocatalysts - Types of Photocatalysts - Homogeneous and Heterogeneous Photocatalyst - Carbonaceous Photocatalysts - Plasmonic Photocatalysts - Applications of Photocatalysts - Characterization techniques used for photocatalysts

Unit-4 - Nanocatalysts and Examples

9 Hour

Introduction to Nanocatalysts - Noble Metal Nanocatalysts (Ru, Rh, Pd, Pt, etc.) - Polymer Stabilized Rh and Ru Nanoparticles - Oxide supports for Nanocatalysts: Carbon supports for Nanocatalysts - Gold Nanoparticle based Catalysts Gold vs Palladium Catalysts for the Aerobic Oxidation of Alcohols - Oxide based Catalysts - Metal free Catalysts (CNT, Graphene based Catalyst) - Transition Metal Dichalcogenides based Catalysts - Microporous Materials: Zeolites-Zeotypes - Overall steps in Zeolite Crystallization - Zeolite Synthesis via Dry Gel route - Zeolite Y determination of surface Acidity - Shape Selectivity - Synthesis of Mesoporous Silica MCM 41 - Mesoporous Carbon - Sulfated Zirconia - Ag/SiO2 Composite Nanocatalyst

Unit-5 - Applications of Nanocatalytic Materials

9 Hour

Applications of Nanocatalysts in Sustainable Chemistry - Toxic Gases conversion using Nanocatalysts: NOx - CO Oxidation using Nanocatalysts - Hydrogenation of Compounds with C=C bonds, Hydrogenation of Aromatic Compounds - Green House Gases: CO2 Conversion - Dissociative Mechanism: Oxygen Reduction Reaction using Nanocatalysts - Associative Mechanism: Oxygen Reduction Reaction using Nanocatalysts Hydrogen Production using Oxide and Dichalcogenides based Catalysts - Energy Processing: Processes involved in Crude Oil Refinery - Gasoline Production - Cracking - Fuel Cell - Biomass Gasification -Biodiesel - Photocatalysts for Self-cleaning - Purification of Water and Air - Environmental Remediation - Future Possibilities

- 1. M. Albert Vannice, Kinetics of Catalytic Reactions, Springer, 2008.
- 2. Nick Serpone and Ezio Pelizzetti, Photocatalysis: Fundamentals and Application, Wiley Interscience, 1st Edition, 1989. Nanocatalysis Applications and Technologies, Editor(s):
- 3. Calvino-Casilda, Antonio José López-Peinado, Rosa María Martín-Aranda, Elena Pérez 6. Nanocatalysis Synthesis and Applications, Editor(s): Vivek Polshettiwar, Tewodros Asefa, Mayoral, CRC Press, 2021 Kurt W.
- 4. Kolasinaski, Surface Science: Foundations of Catalysis and Nanoscience, John Wiley & Sons, England, 2nd Edition, 2005.
- 5. NanoporousMaterials: Synthesis and Applications, Edited by Qiang Xu, CRC Press, 1st Edition, 2013.
 - John Wiley & Sons, Inc., 2013.

Learning Assessm	nent	10	Sec. 12. 14. 14. 14.	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1		ii ii			
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	Blo <mark>om's</mark> Level of <mark>Thinkin</mark> g	CLA-1 Avera	native ge of unit test 1%)	- CL	Learning A-2 0%)	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%		20%		20%	-		
Level 2	Understand	20%		20%		20%	-		
Level 3	Apply	30%	A) - N//	30%	4)	30%	-		
Level 4	Analyze	30%	- / /	30%		30%	-		
Level 5	Evaluate		- 111	-	7 -7 /	-	-		
Level 6	Create	7) -	- /43/5	-	7_7- <u> </u>	-	-		
	Total	100	0 %	100	0 %	100) %		

Course Designers	AREARA-IDan com	
Experts from Industry	experts from Higher Technical Institutions	Internal Experts
1. Dr. P. Sudhakara, CLRI – CSIR, Jalandhar,	1. Dr. S.A. Shivashankar, Centre for Nano Science and Engineering (CeNSE), Indian	1. Dr. Elangovan Elamurugu, SRMIST
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Dr. Sudhakar Selvakumar, CSIR-Central Electrochemical	Dr. Sudakar Chandran, Department of Physics, Indian Institute of Technology Madra	as, 2. Dr. Gopalakrishnan Chandrasekaran,
Research Institute, ssudhakar79@gmail.com	Chennai. csudakar@iitm.ac.in	SRMIST

Course	21NTE308T	Course	MEMO AND NEMO	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	ZINIEJUOI	Name	WEWS AND NEWS	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil	
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil	
			The state of the s			

Course Le	arning Rationale (CLR):	The purpose of learning this course is to:	17	A			Progr	am Oı	utcome	s (PO)					ogran	
CLR-1:	learn what are MEMS and	where they are useful	1 2 3 4 5 6 7 8 9 10 11 12				12	12 Specifi Outcom									
CLR-2:	understand the basics of fa	brication of e <mark>lectromec</mark> hanical systems at micro and nanoscale and modeling	dge		o	SL	4	. "			Work		8				
CLR-3:			w lec	ဟ	nent	estigations roblems	Usage	ъ			am W		Finance	В			
CLR-4:	explore magnetic materials	s Msuitab <mark>le for ma</mark> gnetic MEMS	Α'n	alysis	velopment of	/estig probl	ol Us	er and	× ×		Теа	tion	∞	arni			
CLR-5:	gain knowledge of thermal	, micro <mark>-opto-M</mark> EMS materials	ering	A	a	.≦ ×	P	engineer stv	ronment tainability		<u>8</u>	Communication	Mgt.	og Le			
			9	roblem	ign/d	onduct ir	Jern	The eng society	Environ S <mark>ustain</mark>	SS	Individual	l mu	roject	Long	7	-SO-2)-3
Course O	utcomes (CO):	At the end of this course, learners will be able to:	Engi	Pro	Des	Sor	Мод	The	Env Sus	Ethics	Indi	Cor	Proj	Life	PS0-1	PS(PSO-3
CO-1:	utilize mechanics principle	s t <mark>o analyz</mark> e the mechanical performance of microsystems	3		3	-	-		-		-	-	-	-	3	-	-
CO-2:	utilize optics, electrical ar MOEMS	nd mechanical principles to analyze optoelectromechanical performance of	3	135				5	-	-	-	-	-	-	2	1	-
CO-3:	use the radio frequency an	n <mark>d thermal</mark> principles to analyze the performance of RF and thermal MEMS	3	3	- 3	4-	-	-	-		-	-	-	-	3	-	-
CO-4:	use magnetic and fluid prin	c <mark>iples to a</mark> nalyze the performance of magnetic MEMS and microfluidic devices	3		- E	32	-	-	-		-	-	-	-	-	2	-
CO-5:	analyze the tools and proc	e <mark>sses use</mark> d in micromachining of MEMS	_3	3	- 34	B _	-		-		-	-	-	-	-	3	-

Unit-1 - Mechanical Proerties of Micro/Nano Systems

9 Hour

Definition of Micro and nano-electromechanical systems (MEMS and NEMS), MEMS in daily life, Scaling Laws, Conventional electromechanical systems, Mathematical Modeling, Important steps for analysis and design of engineering steps, Microsensors and microactuators, Principle of sensing and actuation, capacitive sensors, pressure sensors, Inertia sensor, Flow sensor, Thermal sensor, Thermal actuators, piezoresistive sensors, piezoelectric sensing and actuation, magnetic actuation, NEMS-Scaling Effect: Intrinsic losses: Phonon/phonon interaction, Electrical resistivity, depletion, the deactivation of dopants, Quantum confinement effect, Electron/phonon interactions, two-level, and surface effects

Unit-2 - Fabrication tools for Mems/Nems

Hour

Nano machining of NEMS based upon electron beam lithography, Nanoelectromechanical systems fabrication, Nanoimprint lithography, Polymeric nano fibre templates, Focused ion beam doping and wet chemical etching, Stencil lithography and sacrificial etching, large scale integration P and N-type doping in semiconductors, surface machining at macro and microscales. Wafer bonding and LIGA, MEMS Assembling and Packaging, Anodic bonding, fusion bonding, Lithography, electroforming, and molding. Basic Modeling elements in mechanical and electrical systems, Ampler element, mass/inertia element, capacitor, resistor, and inductor, Inertance, fluid resistance, fluid capacitor, Thermal systems modeling, Thermal capacitance, thermal resistance, Translational and rotational pure mechanical systems with spring, Damper and mass

Unit-3 - Principles of Sensing and Actuation in Mems and Nems

9 Hour

Principles of sensing and actuation, Role of microsensors and microactuator with examples, components of mechanical MEMS, Beam, cantilever, microplates, Diaphragm structures theory, corrugated, diaphragms, components in sensors, Capacitive effects, piezoelement, piezomechanics, Measurement methods Strain measurement, pressure measurement, Flow measurement using an integrated paddle-cantilever structure, MEMS Gyroscopes, Nano-gyroscope device: CNT vibration-based, Shear mode MEMS, principle, Compensation in gyroscope, gripping piezo actuator, design and working principle, Inchworm technology, principle, Thermal sensors and actuators, Thermal energy basics and heat transfer processes, thermistors, thermocouple, Thermal actuators, Thermodevices, micromachine thermocouple probe, thermal flow sensors - Working of radiosonde and other applications

Unit-4 - Magnetic Mems and Nems 9 Hour

Magnetic materials: properties, Magnetoresistive materials, magnetostrictive materials, hard magnetic materials, design considerations in magnetic materials, Magnetic sensing and design, Presence and direction detection of large object – an example, Magnetoresistive sensor, Principle of magnetoresistive sensor, hall effect, magnetortransitor, MEMS magnetic semsors and actuators, Construction of a MEMS magnetic sensor, the principle of operation, sensitivity of the sensor, Review of RF-based communication system-I, Tuners, resonators, switches, phase shifters, RF MEMS application area, advantages, Review of RF-based communication system-II, Varactors, Tuners, Filters, Resonators, phase shifter, switches

Unit-5 - Micro Optics Mems and Applications

9 Hour

Principles of MOEMS technology, Applications, Hybrid systems, application, advantages, MOEMS components, Light modulators, beam splitters, Microlens, micromirror, the digital micromirror device, MOEMS devices, Optical switch, waveguide and tuning, shear stress measurement, Lab-on-a-chip, Important considerations on microscale fluid, Properties of fluids, density, viscosity, nature of the flow, surface tension, Fluid actuation methods, Dielectrophoresis, electrowetting, Electrothermal flow, Thermocapillary effect, Electroosmosis flow, Optoelectrowetting, Micropumps: design consideration, Microneedle, Construction of a micropump, modeling, working principle

- Mahalik N P, "MEMS", Tata McGraw-Hill Education, 2008.
 Laurent Duraffourg and Julien Arcamone, "Nanoelectromechanical systems", John Wiley & Sons, Inc., 2015. Sergey Edward Lyshevski, "Micro-Electromechanical and Nano-Electromechanical Systems, Fundamental of Nano-and Micro-Engineering". CRC Press. 2005
- 3. Chang Liu, 'Foundations of MEMS', Second Edition, Pearson, 2012.

Learning Assessme	ent		A STATE OF THE STA	14 M. C.							
			Continuous Learning	g Assessment (CLA)	7	Cuma	matius.				
	Blo <mark>om's</mark> Level of <mark>Thinkin</mark> g	CLA-1 Avera	native ge of unit test 9%)	CL	Learning A-2 9%)	Summative Final Examination (40% weightage)					
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	20%	To a 122 42 87	20%		20%	-				
Level 2	Understand	20%		20%		20%	-				
Level 3	Apply	30%	1	30%		30%	-				
Level 4	Analyze	30%		30%	-4	30%	-				
Level 5	Evaluate	A .	- 1	-		-	-				
Level 6	Create		- 1	-	7 - N		-				
	Total	100	0 %	100) %	100	0 %				

Course Designers	Control of the contro	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Hemant Dixit, GlobalFoundaries, USA,	1. Prof. S Balakumar, balakumar@unom.ac.in	1. D <mark>r. S. Yuvar</mark> aj, SRMIST
aplahemant@gmail.com	Liliili	- //3/
2. Dr. Krishna SurendraMuvvala, Saint Gobain Research India,	2. Prof. M. Ghanashyam Krishna, UOHYD, mgksp@uohyd.ernet.in	2. Dr. Mangalampalli Kiran, SRMIST
India, Krishna.muvvala@saintgobain.com		

Course	21NTE300T Course	SOLID STATE DEVICES	Course _	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Name Name	SOLID STATE DEVICES	Category	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course Le	earning Rationale (CLR): The purpose of lead	ning this course is to:	11	A			Progr	am Oı	ıtcome	s (PO)					ogran	
CLR-1:	get knowledge in the design and working p <mark>rinci</mark> p	l <mark>e of</mark> solid-state devices	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcome	
CLR-2:	understand the physics of p-n junction	V 0.	dge		of	SL					Work		ee Ge				
CLR-3:			Knowlec	ဟ	nent	latio ems	Usage	ъ					Finance	ng			
CLR-4:	describe the operation of basic semiconductor d	odes		alysis	lopr	vestigations v problems	ol Us	er and	y t S	N.	Team	tion	∞ర	arni			
CLR-5:	understand the theory of various types of transis	tors	ering	۱A	sign/development of utions	t inv	Č	engineer sty	ironment tainability	. \	<u>8</u>	nica	Mgt.	ıg Le			
Course	utcomes (CO): At the end of this of	ourse, learners will be able to:	Engine	roblem	Design/	onduct in complex	Modern -	The eng society	Environi S <mark>ustaina</mark>	Ethics	Individual	Sommunication	roject	ife Long	PS0-1	PS0-2	PSO-3
CO-1:		ials and p-n junction for the development of solid-state			-	ਰੱ ਹ		- 8	- ш <u>о</u>		<u>=</u> -	-	- -	-	2	-	<u>a-</u>
CO-2:	use knowledge of physics to understand the wor	king of semiconductor devices	/	2	146		-	7			-	-	-	-	-	2	-
CO-3:	develop analytical approach <mark>es to un</mark> derstand se	miconductor devices	1.47	174	3	-	-	-	<u> </u>		-	-	-	-	-	2	-
CO-4:	develop in depth understanding on the principle	of working of different solid-state devices	1		177	2	-	-	-		-	-	-	-	3	-	-
CO-5:	distinguish the design principles of various solid-	state devices	_3		- 4	-	-	-	-		-	-	-	-	-	2	-

Unit-1 - Design and Principles of Solid-State Devices

9 Hour

Concept of p-n junction-Physics of the p-n junction formation-Energy band diagram of a p-n junction-Estimation of the electric field, electric potential, and built-in potential-Depletion approximation and estimation of space charge width-Depletion layer capacitance and its estimation Qualitative description of charge flow in a p-n junction-Ideal current-voltage characteristics of a p-n junction-Derivation of Shockley equation (ideal-diode equation)-Generation-recombination process and its effect-Reverse bias breakdown mechanisms in a pn junction-Zener and Avalanche breakdown-Transient behavior of a p-n junction-Concept of Noise in semiconductor devices-Terminal functions of a p-n junction diode. The concept of tunnel diode-p-n junction as rectifier, Zener diode, Varistor, and Varactor

Unit-2 - Physics of P-N Hetero Tjunctions

Hour

Understand what a metal-semiconductor contact is.-Qualitative characteristics of energy band formation- Nonideal effects on the barrier height-Qualitative explanation of image-force-induced lowering of the potential barrier-Current transport processes in metal- semiconductor contacts-Comparison of the Schottky barrier diode and the p-n junction diode-Metal-semiconductor Ohmic contacts-Concept of ideal nonrectifying and tunneling barriers--Photoelectric measurements-Figure of merit of ohmic contacts and its determination, the concept of specific contact resistance-Isotype and anisotype semiconductor heterojunctions - energy band diagrams-Current density equations and physical interpretation-Introduction to two-dimensional electron gas-Concept of quantum well and superlattice structures

Unit-3 - Transistors Types

9 Hour

Study fundamentals of BJT operation-Operation modes of a BJT-Understand the structure and working of p-n-p and n-p-n transistors-Band diagram and static characteristics-Factors involved in transistor amplification-BJT fabrication--Evaluation of the terminal currents-Non ideal effects in BJT-Deviations from the basic theory and indicate situations in which each effect is important-The physical mechanisms of the current gain limiting factors-The voltage breakdown mechanisms in a bipolar transistor-The current-limiting factors from the current components in the transistor Heterojunction BJT-Schottky and Photo transistors

Unit-4 - Fiels Effect Transistors 9 Hour

Principle and types of field-effect transistors-Principle of operation of JFET -GaAs epitaxial layers for MESFET – Principle of working-Concept of high-electron mobility transistors - III-V semiconductor materials-Basic working and fabrication of MOSFET-Knowledge on modes of operation and short channel MOSFET-Short channel effects in MOSFET-Advanced MOSFET structures -Complementary MOS structure and its formation-CMOS process integration-Concept of modulation doping in HEMT-Basic device structure of AlGaAs/GaAs HEMT and I-V characteristics-Output characteristics and channel related phenomenon-Dynamic effects in MOS capacitors – The Charge-coupled device-Basic CCD structure and its applications

Unit-5 - Applications in Optical Devices

9 Hour

Understand optical generation of carriers in a p-n junction- Solar radiation and ideal conversion efficiency of a solar cell-Physics of solar cell-Device configuration and technology roadmap, solar cell materials-Familiarize with the solar cell parameters and efficiency calculation-Design principle of photodetector- How light-emitting diodes work?-Basic device structure and the concept of radiative recombination-Materials of choice and technology roadmap-Specifications used in denoting the practical LED bulbs-Physics of laser action-Gain knowledge of stimulated emission and population inversion-Fabrication of p-n junction laser-Emission spectra-Familiarize with the structure and need of heterojunction lasers-Materials for semiconductor lasers and quantum cascade lasers

Learning
Learning Resources
Resources

- S M Sze, Kwok k. Ng, "Physics of semiconductor devices" John Wiley & Sons, Inc., 2007
- Ben G. Streetman, Sanjay Kumar Banerjee, "Solid State Electronic Devices", Pearson Education Ltd. 2016
- 3. Donald A. Neamen, "Semiconductor Physics and Devices: Basic Principles" McGraw Hill, Fourth Edition, 2011.
- 4. Solid-State Electronic Devices, Christo Papadopoulos, Springer link, 2014

Learning Assessm	ent			- 100 Specifical					
	5 / 6		Continuous Learning	g Assessment (CLA)		Cumr	notivo		
	Bloo <mark>m's</mark> Level o <mark>f Thinkin</mark> g	Forma CLA-1 Average (50%	e of unit test	Life-Long I CLA (109	-2	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%		20%	-	20%	-		
Level 2	Understand	20%	1 1 1 mm - 400 N	20%	- >	20%	-		
Level 3	Apply	30%		30%		30%	-		
Level 4	Analyze	30%		30%		30%	-		
Level 5	Evaluate		T - 1127/	-	- H		-		
Level 6	Create		- 1.9	-		-	-		
	Total	100	%	100	%	100	0 %		

Course Designers		/ / / / / / / / / / / / / / / / / / / /
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.org	Prof. M.S. Ramachandra Rao, IITM Chennai, msrrao@iitm.ac.in	1. Dr. M. Kovendhan, SRMIST
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	2. Prof. T. Som, Institute of Physics, tsom@iopb.res.in	2. Dr. E. Senthil Kumar, SRMIST

Course	21NTF310T Course	NANOTECHNOLOGY IN COSMETICS	Course	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Name Name	NANOTECHNOLOGY IN COSMETICS	Category	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	am Ou	ıtcome	s (PO)					gram
CLR-1:	express the basis of cosmeceuticals	1	2	3	4	5	6	7	8	9	10	11	12		ecific comes
CLR-2:	demonstrate the classification and various types of cosmetics	dge		of	SL					Work		8			
CLR-3:	analyze about ingredients and effect of inclusion of nanoparticles in cosmetics	Knowlec	ဟ	nent	estigations roblems	Usage	ъ	· 7	L			inance	рu		
CLR-4:	get acquainted with current trends in the field of nano based cosmetics		alysis	evelopment	vestig probl		r and	ج ج ک	h.	Team	tion	∞ π	arni		
CLR-5:	get acquainted with future aspects of cosmeceuticals	ering	Α	deve	.⊆ ×	Tool	engineer aty	ronment tainability	. 1	<u>∞</u>	Communication	Mgt.	g Le		
		9	roblem	sign/de	onduct ir complex	Modern -	ne eng ciety	Environi S <mark>ustaina</mark>	S	ndividual	nur	roject	Long	7	7 7
Course O	utcomes (CO): At the end of this course, learners will be able to:	Engi	Prof	Des	Con	Мос	The	Sus	Ethics	Indi	Col	Proj	Life	PS0-1	PSO-2 PSO-3
CO-1:	apply basic concepts of nanotechnology in cosmetics Apply knowledge in making organosilicon formulation	3		150	1	·	7	-	. *	-	-	-	-	3	
CO-2:	distinguish effects of using nanoparticles over conventional methods in cosmetics	1 -	11:	146	1	2				-	-		-	3	
CO-3:	analyze about current trends in the field of cosmetics	1.63	1.15	7.	2	-	-	-		-	-	-	-	-	2 -
CO-4:	apply basic cosmetic concepts in making nanoformulation	. 44		3	44	_	-	-		-	-	-	-	-	2 -
CO-5:	apply knowledge in making organosilicone formulation	ar e		2	٠.	-		-	-	-	-	-	-	-	- 2

Unit-1 - Introduction to Cosmetics 9 Hour

Meaning of cosmetics-Classification of cosmetics-Purpose of cosmetics-Cosmeceuticals-Pharmaceuticals in cosmetics-Quality Characteristics-Quality Assurance-Development process of cosmetics-Cosmetics for Skin-Cosmetics for hair-Cosmetics for nails-Cosmetics colour materials-Cosmetics and fragrances-Oral care cosmetics-Body Cosmetics-Physical chemistry of cosmetics-Stability of cosmetics

Unit-2 - Materials in Cosmetics 9 Hour

Oily materials: introduction, oils and fats, wax-Hydrocarbons-Higher fatty acids-Higher alcohols, esters, silicones-Surface active agents: introduction-Anionic Surfactant-Cationic Surfactants-Amphoteric Surfactant-Non-ionic surfactants-Humectants: introduction-Choice of humectants-unusual humectants-Special uses of humectants-Antioxidants: introduction-General oxidative theory, measurement of oxidation-Assessment of oxidant efficiency-Choice of antioxidant

Unit-3 - Polymeric Systems in Cosmetics and its Properties

9 Hour

Film formers-Polymers as film formers-Thickeners-Types of thickners-Polymers in hair colouring-Types of polymers in hair colour-Conditioning Polymers-Surfactants in conditioners-cleansing agents-Ethoxylated Alcohols-Silicones-Emulsion Types of polymeric systems-Natural Polymers-Stimuli responsive polymeric systems-pH-responsive-Thermal responsive-Photo responsive

Unit-4 - Liposomes and Nano Formulations

9 Hour

Multiple emulsions as novel delivery systems-Nano materials in cosmetics-Nano crystals in cosmetics-Silicones and beyond-Organ modified silicones-New esters mimicking property for organ modified silicones-Silicones in shampoo-Minimalizing undesirable side effects-Substantive silicones-Effect of substantive silicones-Organo-modified delivery systems-Types of Organo-modified delivery systems-Silicones personal care delivery system-Liposomes in cosmetics-Niosomes in cosmetics-Micro emulsion in cosmetics-Nano emulsion in cosmetics-Cyclodextrin complexes in cosmetics

Unit-5 - Aspects of Cosmeceuticals 9 Hour

Nano delivery systems Synthesis of dual Nano delivery systems containing vitamin e for cosmetics-Synthesis of dual Nano delivery systems containing vitamin e for pharmaceuticals-Characterization of dual Nano delivery systems containing vitamin e-Various characterization techniques Preparation of keratin coatings for orthopaedic implant titanium rods-Characterization of keratin coatings-Nanotherapeutics as a treatment for inflammation-Cosmetic repair and restoration-Moisturization of skin-Fortification of the skin barrier-Contact lenses types-Beauty from contact lenses beyond vision correction

Learning	
Resources	

- New Cosmetic Science, Mitsui T., Elsevier, 1998
 CosmeticNanotechnology: Polymers and Colloids in Cosmetics, Sarah E.M., Kathleen O.H., Robert Y.L., American Chemical Society, 2006
- 3. Delivery System Handbook for Personal Care and Cosmetic Products, Meyer R.R., William Andrew ASP, 2005

4. Nanotechnology for the Preparation of Cosmetics Using Plant-Based Extracts, Siti Hamidah Mohd Setapar, Akil Ahmad, Mohammad Jawaid, Elsevier Science, 2022

earning Assessm	nent		Continuous Loomin	g Assessment (CLA)						
Bloom's Level of Thi <mark>nkin</mark> g		CLA-1 Avera	Formative CLA-1 Average of unit test (50%)		earning -2 6)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	Carlot of the control	20%		20%	-			
Level 2	Understand	20%	A Section of the Sect	20%		20%	-			
Level 3	Apply	30%	188 / C - 450 W.	30%		30%	-			
Level 4	Analyze	30%	Miles 1997 1997	30%		30%	-			
Level 5	Evaluate //	227 777 317		中央医院院内。		-	-			
Level 6	Create	and the second second	30 Bar 1 1 1	1 1 1 1 1 1 1 1 1 1	3 -	-	-			
	Total Total	100)%	100 9	%	100	0 %			

Course Designers	20 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Mr.Solomon Jonnes, Bengaluru, solomon@terracarb.com	1. Dr. Amit Kumar Mishra, IIT Jodhpur, amit@iitj.ac.in	1. Dr. Mani Rah <mark>ulan, SR</mark> MIST
2. Dr. Nagesh Kini, Thermax, une, Maharastra, nagesh.kini@gmail.com	2. Dr. Sampath Kumar T.S, IIT Madras, tssk@iitm.ac.in	2. Dr. C. Siva, SRMIST

Course Code	21NTE311T	Course Name	NA	NOMEDICINE	_	ours atego	-	Е			PROF	ESSIC	NAL E	LECT	IVE		3	T 0	P 0	3
Pre-requis Courses		Nil	Co- requisite Courses	Nil	•		gres							Nil						
	ffering Departm	ent Pl	nysics and Nanotechnolog	Data Book / Codes / Star	ndards								Nil							
Course Lea	rning Rationale	(CLR): The p	urpose of lea <mark>rning this c</mark>	ourse is to:	(T)	7	-		-	Progr	am Oı	ıtcome	s (PO)					rograi	
		abelling and imag		71.2	-	1	2	3	4	5	6	7	8	9	10	11	12		pecifi itcom	
	know about mole			0		ge		j o	S					美		gg			100111	<u></u>
CLR-3:	learn about drug	discovery		-A-16		wled	"	ent	investigations lex problems	ge		١, ١		Team Work		& Finance	g			l
CLR-4:	understand cand	er diagnosis		T AND S	77,	Kno	Analysis	lopm	estig	Usa	r and	∞ >	N.	Tear	.io	ĕ ≪	arnir			l
CLR-5:	learn about card	iovascular diagn <mark>o</mark>	sis and therapy			Engineering Knowledge	lem Ana	Design/development of solutions	Conduct inve of complex p	Modern Tool Usage	The engineer society	Environment Sustainability	ဟ	Individual &	Communication	Project Mgt.	ife Long Learning	-	7	ကု
Course Out	comes (CO):	At the	e end of this course, lea	rners will be able to:	i de la	igi	Problem	Designation	Conduct of comple	Mode	The eng society	Susta	Ethics	ndiv	Som	Proje	le.	PSO-1	PSO-2	PSO-3
CO-1:	explain in vivo in	naging		20 miles (1987)	43	3	-71	T.	· .	-	/	-		-	-	-	-	-	2	-
CO-2:	apply nanomater	ials for diag <mark>nos</mark> is	(A)		E	3	-	40	-19	-	4	-	-	-	-	-	-	2	-	-
CO-3:	corelate nanotec	hnology an <mark>d drug</mark>	<mark>l d</mark> iscovery			3	igh.	÷	4	-) -		-	-	-	-	-	2	
CO-4:	apply nanotechn	ology for di <mark>agn</mark> os	<mark>in</mark> g cancer		111	3 -	127	G ₂ t	1-	-	-	-		-	-	-	-	-		
CO-5:	relate nanopartio	les to thera <mark>py</mark>		CAPTER LAND	1 2	3		100		-	À	-		-	-	-	-	-	2	
Nanoparticle	noparticles for in es for In Vivo Stu logy, Nanoproteo	dy of Cells, L <mark>ive</mark> -	Cell Single Molecule Ass	ays, Quantum Dots for Stem Cell Lab	eling an	nd Apo	optosi	is, Mol	ecular	Motors	s-Nand	omotor	Made	of Nuc	cleic Ad	cids, S	tructura	al DNA		Hou RN
Unit-2 - Mol	ecular Diagnost	ics								1	V								9	Hou
			<mark>Nanobi</mark> ochip, Quantum D	ots for Molecular Diagnostics, In Vivo I	naging	Using	g Nan	opartic	les, Na	nobar	codes	T <mark>ech</mark> no	o <mark>logy</mark> , i	Nanob	iosens	ors.				
Nanofluidic I				odies, Nanotechnology based Vaccine	Deliver	y, Na	noma	terials	for cell	thera	oy, ge <mark>r</mark>	ne thera	ару							Hou Hou
				nosis, Anticancer Effect of Nanopartic	es, Nan	noeled	ctrode	s in N	europh	ysiolog	gy, Na	nowires	s for M	lonitori	ng Bra	in Acti	vity, Ne	eurode		
		therapy applicat In by nanochip, C		Atherosclerotic Plaques, Cardiovascula	r Syste	m reg	genera	ation, I	lydrog	els for	Муоса	ardial T	īssue i	Engine	ering,	Nanon	nateriai	ls as N		Hou icida
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Manufacturing and Applications 1st Edition, Elsevier, 2021

2006

			Continuous Learnin	g Assessment (CLA)		Summative				
	Bloom's Level of Thinking	Formative CLA-1 Average of unit test (50%)		C	g Learning LA-2 <mark>0%)</mark>	Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	ALTERNA	20%		20%	-			
Level 2	Understand	20%		20%		20%	-			
Level 3	Apply	30%	3	30%		30%	-			
Level 4	Analyze	30%	-	30%	A -	30%	-			
Level 5	Evaluate		-		7	-	-			
Level 6	Create		*-A	-	7 - 1	-	-			
	Total	100) %	10	00 %	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, HCL Health care division, Chennai	1. Dr. Vignesh Muthuvijayan, IIT M	1. Dr. G. Devan <mark>and Venk</mark> atasubbu, SRMIST
2. Dr. Asifkhan Shanavas, INST Mohali	2. Dr. T. Prakash, UOM	2. Dr. K. Janani <mark>Sivasank</mark> ar, SRMIST



Course	04NTE240T	Course	MICROELECTRONICS AND VLSI	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	ZINIESIZI	Name	MICROELECTRONICS AND VLSI	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	NI	ressive urses	Nil
Course Offering	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	-4			Progr	<mark>am O</mark> u	tcome	es (PO)				_	rogram
CLR-1:	acquire knowledge on importance of microelectronics	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	understand the physical effects of semiconductor-semiconductor junction, its electrostatics, device and circuit level ELEoperation			1	of		ety	ability		×					
CLR-3:	acquire knowledge on digital language of Boolean algebra, basics of logic gates for advanced memory applications	Knowledge	S	ign/development of	investigations problems	Usage	d society	Sustainability	N.	m Work		inance	Б		
CLR-4:	learn process flow of CMOS IC fabrication, circuit formation and its operation	Ā	Problem Analysis	lop	estig		er and	∞ర		Team	tion	∞ T	ami		, '
CLR-5:	understand intricacies of designing micro/nanoscale rules, flow of fabrication and IC testing principles	ngineering	Ä	deve		T00	engineer	Environment		<u>ত</u>	ommunication	Mgt.	g Le		
		e	Slen	ign/d		ern		<u>io</u>	S	/idu	שנ	Project	Long	7)-2)-3
Course O	utcomes (CO): At the end of this course, learners will be able to:	Eng	Prop	Desi	Som	Modern	The	Env	Ethics	Individual	Coll	Proj	Life	PSO	PSO PSO
CO-1:	interpret difference between macro and micro electronics	3	- L	40 70	-19	-	4	-	-	-	-	-	-	3	- -
CO-2:	apply basic semiconductor physics which is important to understand the working of semiconductor semiconductor junctions, device and circuit level operation	r- 3	i ik	4	7	-	-	<u> </u>	-:	-	-	-	-	3	
CO-3:	analyze various number sys <mark>tems of</mark> Boolean algebra, operation of logic gates and memory circuits	2	1 -		- 3	-	-	-	-:	-	-	-	-	-	
CO-4:	elucidate process flow of CMOS-based logic devices, circuit formation and its operation	_3	-4		3	-	_	-	-	-	-	-	-	-	3 -
CO-5:	analyze power consumption and need for optimization in on-chip devices, its effect on switching speed	-		-	2	7-	_	-	-	-	-	-	-	-	3 -

Unit-1 - Macro and Mcroelectronics

9 Hour

Introduction to classification of materials- Types of semiconductors- Concept of energy band gap- Doping in semiconductors – types of doping- advantages of doping- Formation of the p-n junction- Electrostatics of junction operation- Diode as circuit element- Basics of bipolar and unipolar junction transistors- Current-voltage characteristics and operation of transistors -Ebers -Moll model for transistor design- Small-signal model- Small-signal model for bipolar junction transistor (BJT)- Small-signal model for a junction field-effect transistor (JFET)- Amplifiers- Transistor connections in various modes- Feedback concept- Ideal F/B amplifiers- Types of feedback amplifiers

Unit-2 - Electronic Operations

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Number systems - Binary and octal numbering- Hexadecimal numbering- Conversions between number systems- Boolean algebra- Logic gates- Truth tables for AND, OR, NOT gates- Truth tables for NAND, NOR gates- Circuits with logic gates- combinational circuits and sequential circuits- Flip-flops- SR and JK flip-flops- Triggering of flip-flops -Edge triggered Flip Flops- Basics of counters- Asynchronous and synchronous counters-Ring and ripple counter- modulo N counter- Overview of memory devices- Logic gates for memory applications- Read-only memory- Random-access memory

Unit-3 - Integrated Circuit Technology and Fabrication

9 Hour

Introduction to IC Technologies – IC fabrication - Introduction to MOSFET-TYPES OF MOSFET -ENHANCEMENT AND DEPLETION MODE -Complementary Metal Oxide Semiconductor (CMOS)- VLSI for CMOS-Positive channel MOS (PMOS) and negative channel MOS (NMOS)- BicMOS and applications- CMOS inverter- CMOS logic circuits- Combinatorial CMOS Logic- pMOS and nMOS in logic operation- D-latch-CMOS for D-latch- Transistor logic- Pass transistor circuits

Unit-4 - VLSI Technology 9 Hour

Introduction to VLSI- Needs of VLSI- VLSI design styles- Layout rules- Overview of VLSI design methodologies- Needs of designing- Steps in designing- Cascading of the process- Introduction to MOSFET- VLSI for MOSFET- DC operation of MOSFET- AC operation of MOSFET- Modelling of MOSFET- Small-signal model- High-frequency MOSFET models- Testing of transistor- Need for testing- Testing principles- Design for testability- Error analysis- Safety in testing

Unit-5 - IC Devices Testing 9 Hour

Usage of power in IC - Overview of power consumption, low and high power in VLSI chips- On-chip capacitors- Charging and discharging of capacitor- Currents and voltages in CMOS short circuits- Leakage current, static current- Gate-level- architecture- transistor and gate sizing- Power analysis- Data correlation analysis- Random logic signals, signal entropy- Switching activity analysis- Parallel architecture- Digital CMOS circuits- CMOS amplifiers- CMOS amplifier topologies- Common-Source topologies- Parallel architecture with voltage reduction.

Learning Resources
Resources

- 1. Behzad Razavi, Fundamentals of Microelectronics/Edition 3, Wiley, 2021
- 2. S. M. Sze, Semiconductor Devices: Physics and Technology, Wiley 2008.
- 3. Modern VLSI design: IP based design/Prentice Hall; 4th edition (December 26, 2008)
- 4. Millman and Grabel, "Microelectronics", 2nd Ed. Tata McGraw-Hill, 2003
- 5. Weste N.H., "Principles of CMOS VLSI Design", Pearson Education, India, 2002
- 6. Fundamentals of CMOS VLS I Design, Kiran Kumar and V.G Nagesh. H.R, 2011, Sanguine Technical Publishers, Bangalore:

Learning Assessm	ent		771.2			
	9 /	Continuous Learn	ing Assessment (CLA)	Learning	Cumm	notivo
	Bloom <mark>'s</mark> Level of <mark>Thinking</mark>	Formative CLA-1 Average of unit test (50%)	Summative Final Examination (40% weightage)			
	2 5	Theory Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	20%	- ()	20%	-
Level 2	Understand	20%	-20%		20%	-
Level 3	Apply	30% -	30%	.57	30%	-
Level 4	Analyze	30%	30%		30%	-
Level 5	Evaluate		14 Table 54		-	-
Level 6	Create	- 12 Day 10 - 10			-	-
	Total Total	100 %	100	0 %	100	%

Course Designers			
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts	
1. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.org	1. Prof. K. Sethupathi, IITM Chennai, ksethu@iitm.ac.in	√ 1. Dr. A. Geetha, SRMIST	
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	Prof. S. Balakumar, University of Madras, balakumar@iunom.acs.in	2. D <mark>r. P. Mal</mark> ar, SRMIST	

Course	21NTE212T Course	NANOTECHNOLOGY FOR ENERGY SYSTEMS	Course	П	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name Name	NANOTECHNOLOGY FOR ENERGY SYSTEMS	Category	Е	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	<mark>am O</mark> ı	ıtcome	s (PO)					rogram
CLR-1:	learn the importance of renewable energies for the safe survival of human kind on the earth	1	2	3	4	5	6	7	8	9	10	11	12		pecific Itcomes
CLR-2:	understand the basics of green energy production, storage and transport	a)		17	of		ciety			¥					
CLR-3:	understand how nanotechnology can improve the green energy production from various sources	edge		nt of	ions	Φ	socie	. 1		Work		ance	1		1
CLR-4:	explore the methods of hydrogen p <mark>roduction</mark> and storage	Knowle	Sis	bme	stigations lems	Jsag	and		h.	eam	_	Finan	arning		
CLR-5:	acquire knowledge on the fabrication, characterization of nanomaterials useful for energy production, transportation and storage	ering K	n Analysis	n/development of	prob	Aodern Tool Usage	engineer	ment & ability	١	<u>⊸</u> ≪	communication	Mgt. &	Ľ		
Course C	utcomes (CO): At the end of this course, learners will be able to:	Engine	Problem,	Design, solution	Conduct	Moderr	The en	Environment 8 Sustainability	Ethics	Individual	Comm	Project	Life Long	PSO-1	PSO-2 PSO-3
CO-1:	identify the urgency of energy solutions and the expectations of Nanotechnology in providing long term solutions to these problems	3		N _y ,	77-	1	4	-	- 1	-	-	-	-	3	- -
CO-2:	describe the concepts of Ph <mark>otovoltai</mark> cs	1.78	190	2	1	-	-) -		-	-	-	-	-	3 -
CO-3:	apply Nanotechnology and nanomaterials in thermoelectrics	3	100	125	1-	-	-	- 1		-	-	-	-	-	2 -
CO-4:	apply the principle and design of fuel cells for energy production			2	<i>i</i> - 1	-		-	-:	-	-	-	-	-	2 -
CO-5:	knowledge on hydrogen prod <mark>uction a</mark> nd storage materials	2			_	_	-	-	_	_	_	-	-	-	3 -

Unit-1 - Fossil and Renewable Enrgy Resources

9 Hour

Energy Challenge in the 21st Century-Fuel share of world total primary energy supply-Nanotechnology in energy research-The importance of nanotechnology in improving the nanoscale energy devices-Conventional fossil fuels Unconventional fossil fuels-Discussion about greenhouse gases, clean energy sources and advantages- Renewable energy sources-Nanotechnology in fuel production- fuel cells, Thermoelectric conversion

Unit-2 - Photovoltaic Principles and Devices

9 Hour

Terawatt challenges in photovoltaics-How can photovoltaics meet a significant fraction of energy demand?- Limits in conversion efficiency- S-Q limit - Theoretical limits of photovoltaics efficiency and possible improvements by different approaches- Different loss mechanisms in photovoltaics - Loss controlling concepts under development - Hybrid concepts-Combining organic and inorganic cells, concept of heterojunction-type photoactive layer, hole-electron pair-Semiconductors optical properties-Basics of semiconductors, bandgap-charge carrier transport in semiconductors-Optical properties of semiconducting thin films, Optical absorption-Narrow and wide band gap materials, bulk, thin film and dye sensitized solar cells - Future of photovoltaics

Unit-3 - Thermoelectric Energy Generation and Size Effects

9 Hour

Bulk thermoelectric materials-Basics of thermoelectricity, Seebeck effect, Peltier effect, Figure of merit, WiedemannFranz relationship-Bulk thermoelectric materials- size effects, Selection criteria for bulk thermoelectric materials-Important three guidelines-Effect of size of the quantum dots, nanowires on the conversion efficiency, classical and quantum size effects-Thermoelectric properties on nanoscale: modelling-Importance of characteristic length scale, Bi nanostructures-Importance of Bi nanowire and its diameter in thermoelectricity

Unit-4 - Fuel Cells and Nanocatalysts

9 Hour

Types of fuel cells, development of low-temperature fuel cells-Cathode and anode reaction-Oxygen reduction reaction, cathodic reactions, reactions at anode surface-Practical fuel cell catalysts and Electrolytes-Nanostructured materials in low-temperature cell, Non-precious catalysts, electrolytes-High-temperature polymer electrolyte membranes, membrane-electrode assembly-High temperature fuel cells, organic fuel cells - Applications of Fuel cells - Introduction to nanotechnology in energy storage applications

Unit-5 - Nanotechnolgy for Hydrogen Production and Storage

9 Hour

Introduction to hydrogen fuel - Methods of hydrogen production, Importance of hydrogen energy-Nanomaterial based photoelectron chemical cell, Water splitting for producing hydrogen-Semiconductors with specific morphology such as nanotubes and discs for production of hydrogen storage; technological barriers-Methods of improving efficiency of cells, potential storage materials hydrogen sorption-Hydrogen storage by Physiosorption and chemisorption methods-Properties of materials: physical storage, thermodynamic and kinetics-Bond strengths for Physisorption and chemisorption - chemical hydrides nanocomposites-Hydrogen storage by chemisorption, basic structures of metal and complex hydrides, chemical hydrides - Future scope of hydrogen fuels

Learning Resources
Docourose
Resources

- Javier Garcia-Martinez, Nanotechnology for the Energy Challenge, WILEY-VCH Verlag GmbH & Co., 2010
- 2. Anatoli Korkin, David J, Nanoscale Applications for Information and Energy Systems, Springer, 2013
- 3. Darren P. Broom, Hydrogen Storage materials: The characterization of their properties, Springer, 2011
- 4. Dharmendra Tripathi, R. K. Sharma, Energy Systems and Nanotechnology, Springer, 2021

earning Assessm	nent		Continuous Loomin	g Assessment (CLA)					
	Bloom's Level of Thi <mark>nking</mark>	CLA-1 Avera	Formative CLA-1 Average of unit test (50%)		earning -2 6)	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%	Carlot of the control	20%		20%	-		
Level 2	Understand	20%	A Section of the Sect	20%		20%	-		
Level 3	Apply	30%	188 / C - 450 W	30%		30%	-		
Level 4	Analyze	30%	Miles 1997 1997	30%		30%	-		
Level 5	Evaluate //	227 777 317		中央医院院内。		-	-		
Level 6	Create	and the second second	30 Bar 1 1 1	1 1 1 1 1 1 1 1 1 1	3 -	-	-		
	Total Total	100)%	100 9	%	100	0 %		

Course Designers		114		2
Experts from Industry	Experts from Higher Tecl	hnical Institutions		<mark>nterna</mark> l Experts
1. Dr. Hemant Dixit, GlobalFoundaries, USA,	aplahemant@gmail.com 1. Dr. Ramesh Ch	andra Mallik, IISc Bangalore, rcmallik@	Diisc.ac.in	1. Dr. P. Malar, SRMIST
2. Dr. Krishna Surendra Muvvala, Saint Gob	<mark>ain Re</mark> search India, India, 2. Dr. Bhaskar Ch	andra Mohanty, Thapar University, bha	askar@thapar.edu	2. Dr. J. Archana, SRM IST
Krishna.muvvala@saintgobain.com		(2) h		

Course	21NTE314T	Course	DHYSICS OF ELECTRONIC MATERIALS	Course	_	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	21111123141	Name	PHYSICS OF ELECTRONIC MATERIALS	Category	E	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	111	4			Prog	am Ou	ıtcome	s (PO)					rogram	
CLR-1:	understand the physics o	f electronic materi <mark>als</mark>	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes	
CLR-2:	familiarize different physi	cal properties <mark>of electroni</mark> c materials	ge		of	SI					Work		8				
CLR-3:	know-how the various pro	ocesses in e <mark>lectronic m</mark> aterials	lowledge	w	Jent	vestigations c problems	Usage	ъ			Μ		Finance	Вu			
CLR-4:	understand the physics b	ehind the working of electronic materials-based devices	조	alysis	ldol	estig	l Us	r and	∞ ∞ >	l.	Team	ion	∞ర	arni			
CLR-5:	gain a fundamental unde	rstandin <mark>g of the e</mark> merging electronic materials	ering	An	/development	t in K	Tool	engineer ety	nment		<u>∞</u>	ommunication	Mgt.	g Le			
	•		9	roblem	gn/	nduct in	dern	enç etv	ron in in	SS	/idu	l III	roject	Long	7	5.2	<u>.</u>
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Engi	Pro	Desi	of Sol	Mod	The	Envi	Ethics	Individual	Con	Proj	Life	PSO-1	PSO-2	2
CO-1:	apply knowledge of physi	cs in understanding the properties of semiconductors	3		17.	2	-	/	-	-	-	-	-	-	-	3 -	
CO-2:	elucidate dielectric behav	ior <mark>of mater</mark> ials and their practical uses	3		10.00	2	-	4	-		-	-	-	-	3		
CO-3:	distinguish between differ	ren <mark>t magnet</mark> ic materials	2	0.174	3	15	-	-	ļ -		-	-	-	-	2		
CO-4:	evaluate different optical	pr <mark>ocesses</mark> in semiconductors and identify their applications	3	- 1	125	3	-	-	-		-	-	-	-	-	3 -	
CO-5:	develop skills to identify r	nat <mark>erials fo</mark> r thermoelectric applications	2	2	-		_		-		_	-	-	-	_	2 -	

Unit-1 - Physical Properties of Electronic Materials

9 Hour

Introduction to Semiconductors - Defining characteristics and classification of semiconductors, Fundamentals of band theory of semiconductors, Intrinsic semiconductors, Energy band diagram and carrier movement, Conductivity of a semiconductor, Electron and hole concentrations Extrinsic semiconductors, Concepts of p-type, n-type and compensation doping, Energy band diagram and electron and hole concentrations, Estimation of the position of the Fermi energy and the resistivity, The temperature dependence of carrier concentration The temperature dependence of drift mobility, Degenerate and nondegenerate semiconductors, Direct and indirect recombination, Minority carrier life time, Carrier injection and diffusion, Optical absorption in semiconductors, Direct and indirect band gap semiconductors and the E-k diagram

Unit-2 - Dielectric Characteristics of Electronic Materials

9 Hour

Concept of relative permittivity, Electric dipole moment and polarizability, Polarization vector and charge density, Electric susceptibility and relative permittivity, Lorentz field in dielectrics, Clausius-Mossotti equation, Electronic polarization in covalent solids, Ionic, dipolar, interfacial and total polarization, Concept of dielectric loss, Dielectric studies and the Cole-Cole plot, Dielectric strength and insulation breakdown, Dielectric breakdown mechanisms, Capacitor dielectric materials, Typical capacitor constructions, Piezoelectricity, Piezoelectric spark generator and quartz crystal, Ferroelectricity and pyroelectricity, Practical Applications

Unit-3 - Magnetic Properties of Electronic Materials

9 Hour

Definition of magnetic dipole moment, Orbital and spin magnetic moment of an electron, Magnetization vector, Definition of magnetic susceptibility and magnetic permeability, Magnetic materials classification - Diapara-, ferro-, antiferro-, and Ferrimagnetism; Origin of ferromagnetism and exchange interaction, Saturation magnetization and curie temperature, Magnetic domains and domain walls, Magnetostriction and domain wall motion, Magnetic domains in polycrystalline materials Understanding the M versus H hysteresis curve, Demagnetization, Soft and hard magnetic materials: Examples and uses, Superconductivity, Type I and Type II superconductors, Critical current density and superconducting solenoids, Josephson effect, Introduction to anisotropic and giant magnetoresistance(GMR), applications of GMR

Unit-4 - Optoelectronic Properties and Devices

9 Hour

Optical properties of materials, Refractive index, Real and imaginary components of refractive index, Refractive index-wavelength behavior, Snell's law and total internal reflection, Case study: fiber optics and LEDs, Interaction of photons with materials, Absorption, transmittance and reflection, Antireflection coatings on solar cells, Fabrication methods of anti-reflective coatings based on refractive index, Dielectric mirrors, Band to band absorption, Direct and indirect transitions, Light scattering in materials, attenuation in optical fibers, Luminescence, phosphors, and white LEDs, Spontaneous and stimulated emission, Laser materials and laser action, Concept of photoluminescence and electroluminescence, Examples for devices working on the principles of PL and EL, Electro-optic effects and applications, Magneto-optic effects and applications

Unit-5 - Thermal Properties and Prospects of Electronic Materials

9 Hour

Thermal properties of materials, Atomistic theory of heat capacity, Quantum mechanical considerations, Einstein and Debye model, Electronic contribution to the heat capacity, Heat capacity and specific heat, Thermal expansion and thermal conductivity, Thermal conductivity in metals, alloys, and dielectrics, Thermoelectricity in metals, Seebeck effect and the figure-of-merit, Thermoelectricity in semiconductors, Overview of thermoelectric devices, Two-dimensional electronic materials, The Era of graphene and related materials, Electronic properties at 2D limit, Optical properties- layer dependence, 2D materials-based metal, semiconductor and dielectrics, Applications and future perspectives

- S O Kasap, "Principles of Electronic Materials and Devices" McGraw Hill, Fourth Edition, 2017
- Wei Gao, Zhengwei Li, Nigel Sammes, "An Introduction to Electronic Materials for Engineers World Scientific Publishing Co. Pte. Ltd, Second Edition, 2011
- 3. David Jiles, "Introduction to the Electronic Properties of Materials: Nelson Thornes Ltd. Second Edition. 2001
- 4. David K. Ferry, Jonathan P. Bird "Electronic Materials and Devices" Academic Press, First Edition, 2011.
- 5. Yuriy M Poplavko, "Electronic Materials: Principles and Applied Science" Elsevier, First Edition, 2019
- 6. Rolf E. Hummel, "Electronic Properties of Materials: An Introduction for Engineers" Springer, 1993

Learning Assessm	ent		A 100 100 100 100		7		
			Continuous Learning	g Assessment (CLA)	77	Cum	mative
	Blo <mark>om's</mark> Level of <mark>Thinkin</mark> g	CLA-1 Avera	native ge of unit test 0%)	Life-Long CLA (10	4-2	Final Ex	nauve amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%		20%		20%	-
Level 2	Understand	20%	1	20%		20%	-
Level 3	Apply	30%	10 - 10 M.	30%	4)	30%	-
Level 4	Analyze	30%	- 1.7	30%		30%	-
Level 5	Evaluate		- 1111	-	-V -V	-	-
Level 6	Create	1)	430	-	/_/1- /	-	-
	Total	100	0 %	100)%	10	0 %

Course Designers	/INFARA-IEAD TRUE	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Dr. K. Ashok, Vikram Sarabhai Space Centre, ashok@vssc.gov.in	Prof. K. Sethupathi, IITM Chennai, ksethu@iitm.ac.in	1. Dr. S. Chandramohan, SRMIST
Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	Prof. S. Balakumar, University of Madras, balakumar@iunom.ac.in	2. Dr. V. Kathirvel, SRMIST

Course	24NITE24ET Course	NANOTECHNOLOGY IN FOOD PRODUCTION	Course	PROFESSIONAL ELECTIVE	L	T	Р	С	
Code	Name Name	NANOTECHNOLOGI IN FOOD FRODUCTION	Category	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses		Nil	
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		• •	Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	Program Outcomes (PO)									Progra					
CLR-1:	know the various types of	interactions at m <mark>olecular scal</mark> e	1	2	3	4	5	6	7	8	9	10	11	12		ecifi tcom	
CLR-2:	understand the effect of n	anoparticles <mark>on agricultu</mark> ral methodology and food technology	egp		of	SL					Work		9				
CLR-3:	gain knowledge on the typ	nes of diagn <mark>ostic tools</mark> using nanotechnology	owlec	S	nent	stigations	Usage	ъ	, 1				Finance	bu			
CLR-4:	acquire knowledge about	the new <mark>er technol</mark> ogies in the food production	줃	alysis	velopment	estig		r and	y k	h.	Team	ţį	∞ర	arni			
CLR-5:	get familiarized with the ne	ew con <mark>cepts of N</mark> ano Science in the packaging industries and food production	ering	٩	deve	t inv	- P	engineer ty	onment ainability	. 1	<u>∞</u>	ommunication	Mgt.	g Le			
			e	plem	fion/	duct	ern	et e	ron	SS	/jqn	l III	ect	Long	7	75	-9
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Eng	Pro	Design	Con	Ø Po	The	Envi S <mark>us</mark> f	Ethics	Individual	Con	Project	Life	PS0-1	PS0-2	PSO-3
CO-1:	apply the concept of intera	acti <mark>ons withi</mark> n the supramolecular structures at molecular scale	2		3		-	/	-		-	-	-	-	-	3	-
CO-2:	utilize the assay technique	es <mark>in agricu</mark> ltural and food diagnostics	2	-	3	7-19	-	4	-		-	-	-	-	-	3	-
CO-3:	apply the concepts of nan	ot <mark>echnolog</mark> y in food products	3	17/2	3	43	-	-) -	-	-	-	-	-	-	3	-
CO-4:	engineer food ingredients	w <mark>hich are</mark> capable to improve the bioavailability	3	140	2		-	-	- 1	-3	-	-	-	-	-	3	-
CO-5:	assess the toxic effects of the nanomaterials used in the food processing and technology				3	7 -	-		-		-	-	-	-	-	3	-

Unit-1 - Interactions at Molecular Level

9 Hour

Intermolecular interactions and supermolecular structures – Introduction - hydrophobic and hydrophilic interactions dispersion interaction, electrostatic interactions Atoms and small molecules, Polymers, particles, and surfaces. Introduction to Steric interactions. Steric interactions involving soluble polymers Aggregation, Depletion, aggregation of particles by non- adsorbing polymers, Bridging aggregation of particles by adsorbing polymers. Stabilization of dispersed particles by adsorbing polymers. Polymer brushes to prevent particle aggregation and particle deposition at surfaces. Self-Assembly, Organized self-assembled structures, Langmuir layers, Lipid bilayers, Solid-supported lipid bilayers Micelles, Vesicles

Unit-2 - Nanoparticles on Agriculture and Diagonistics

9 Hour

Nanotechnology in Agriculture and Food diagnostics. Nanodiagnostic approaches in detecting microbial agents, Biosensors, Enzyme biosensors and diagnostics. DNA-based biosensors and diagnostics. Radiofrequency identification, Integrated nanosensor networks: Detection and Response., Electrochemical biosensors – Gold Nanoparticles, Magnetic Nanoparticles in diagnostics, Fluorescent Nanoparticles in diagnostics, Silica Nanoparticles in diagnostics. Safety of nanotechnology in food and the impact in consumer health. Transduction Principles. Microfluidic Assays, Lateral flow (immuno) assays, Antibody microarrays Surface plasmon resonance spectroscopy

Unit-3 - Nanotechnology in Food Products

9 Hour

Food products and its production – Introduction. Processes impacting food at nanoscale. Need for new food processing methods. Efficient fractionation of crops Efficient product structuring, Optimizing Nutritional value. Nanotechnology in Food Production. Applications of nanotechnology in foods, Sensing, packaging Encapsulation, Nano Engineering food ingredients to improve bioavailability Nanocrystalline food ingredients. Nano-engineered protein fibrils as ingredient building blocks. Preparation of food matrices. Risks of Nanotechnology. Concerns about using nanotechnology in food production. Rational argumentation versus Human feelings, Nano-emulsions. Nanotechnology for food preservatives

Unit-4 - Nantotechnology in Crop Management

9 Hour

Nanotechnology in Crop management - Introduction. Crop improvement - reasons to package food products. Physical properties of packaging materials, Strength, Barrier properties light absorption, structuring of interior surfaces, antimicrobial functionality. Visual indicators, Quality assessment, preservation of safety. Product properties, Information and communication technology Sensors, Radiofrequency identification technology. Health Risks, Environmental Risks, Consumer and societal acceptance, nanotechnology for pesticide and insecticides

Unit-5 - Study of Nanotoxicology

9 Hour

Toxicology of Nanomaterials in food - Introduction. Characterization of engineered nanomaterials. Unique issues for characterization of engineered nanomaterials for food applications Safety assessment of oral-exposure engineered nanomaterials for food application Experimental design considerations for toxicology studies. Life cycle of nanotechnology food products Environmental behavior of nanoparticles - Toxicology of nanoparticles, Molecules in foods involved in triggering allergies. Impact of nanoscale structures on allergenic potential of foods Toxicokinetics Adme (absorption), Adme (distribution) Adme (metabolism) Adme (excretion) Toxicodynamics. In vivo toxicity, In vitro toxicity, Study Reliability

- Nicholas A. Kotov, "Nanoparticle Assemblies and Superstructures", CRC, September, 2019 (ISBN 9780367392284)
- Lynn J. Frewer, Willem Norde, Arnout Fischer, and FransKampers," Nanotechnology in the Agri-Food Sector", Wiley VCH, 2011 (ISBN:9783527330607
- 3. David S Goodsell, "Bionanotechnology", John Wiley & Sons, 2004 (ISBN 0-471-41719-X)
- Jennifer Kuzma and Peter VerHage, "Nanotechnology in agriculture and food production", Woodrow Wilson International, 2006 Espresso) and Page 300-307 (VASP)

earning Assessm	nent			THE PARTY OF THE P							
			Continuous Learning Assessment (CLA)								
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	Formative CLA-1 Average of (50%)		CL	Learning A-2 0%)	Summative Final Examination (40% weightage)					
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	20%	200	20%		20%	-				
Level 2	Understand	20%	707 2	20%	3	20%	-				
Level 3	Apply	30%	1 mg - 466 - N	30%		30%	-				
Level 4	Analyze	30%		30%		30%	-				
Level 5	Evaluate			/ L			-				
Level 6	Create	III.	- 1977	-	- 4		-				
	Total	100 %	1.7	100	0 %	10	0 %				

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr.Rajendra Moorthy Rajendran, Kemin Industries, Chennai, India	1. Dr. V Geethalakshmi, TNAU, Coimbatore, directorscms@tnau.ac.in	1. Dr. C. Gopalakrishnan, SRMIST
rajendramoorthy.r@kemin.com		
2. Mr. Saravanan Lokasundaram, Agro Crops, Chennai, India, sara@agrocrops.com	2. Dr. A Lakshmanan, TNAU, Coimbatore, microlaxman@yahoo.com	2. Dr. E. Senthilkumar, SRMIST

Course	24NTE246T Course	ADVANCED DRUC DELIVERY SYSTEMS	Course _	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Name Name	ADVANCED DROG DELIVERT 3131EWS	Category	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

THE RESERVE

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	am Ou	ıtcome	s (PO)					ogram
CLR-1:	understand the concept of drug delivery	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcomes
CLR-2:	acquire knowledge on controlled drug d <mark>eliver</mark>	ge		of	SI	7	. "			Work		ЭG			
CLR-3:	learn the concept of targeted drug delivery	Knowledge	w	Jent	estigations roblems	Usage	ъ			Μ		Finance	ning		
CLR-4:	know about the methods of drug delivery		alysis	udoli	estig		r and	∞ ×	h.	Team	tion	& Fi	ä		
CLR-5:	learn about various nanocarriers	ering	An	sign/development of utions		Tool	engineer ety	nment nability		<u>8</u>	mmunication	Mgt.	g Le		
		9	roblem	lgn/	nduct in complex	dern	et el	iron	S	ndividual	nuu	əct	Long	7)-2)-3
Course C	outcomes (CO): At the end of this course, learners will be able to:	Engi	Po	Des	Seg	₩.	The	Env Sus	Ethics	<u>n</u>	S	Proje	Life	PSO.	PSO PSO
CO-1:	explain various drug delivery <mark>systems</mark>	3		1.5	- 1	-	/	-		-	-	-	-	2	
CO-2:	analyse a controlled drug rel <mark>ease pro</mark> file	3		40.50	- 1	-	1	-		-	-	-	-	3	
CO-3:	formulate different drug delivery systems	3	172	1	1.5	-	_) -	-	-	-	-	-	-	- 2
CO-4:	apply the concept of drug ta <mark>rgeting</mark>	3	- 47	2	-	-	-	-		-	-	-	-	-	- -
CO-5:	apply the concept of drug delivery systems for Cancer Imaging and Therapy	3		1	Ι	_		-		-	-	-	-	-	2

Unit-1 - Introduction to Drug Delivery Systems

9 Hour

Drug delivery systems- Traditional drug delivery- Advantages and disadvantages of various traditional drug delivery systems- Modes of drug delivery- Routes of administration- Novel drug delivery system-Pharmacokinetics- ADME studies- Kinetics of drug delivery- Zero order kinetics- First order kinetics- Controlled drug delivery

Unit-2 - Targeted Drug Delivery

9 Hour

Targeted drug delivery system- Site specific drug release- Types of drug targeting- Active targeting- Passive targeting- Barriers for drug targeting- Strategies for site specific drug delivery- Receptors- Ligands-Antibodies based drug delivery- Metabolism based drug delivery- PEGylation of nanoparticles

Unit-3 - Nanoparticles for Drug Delivery

9 Hour

Metal nanoparticles for drug delivery- Multifunctional nanoparticles- Virus based drug delivery system- Polymeric nanoparticles- Dentrimers- Magnetic nanoparticles for drug delivery- Nanoscaffolds- CNT in drug delivery- Liposomes- Gene delivery

Unit-4 - Nanotechnology in Cancer Therapy

9 Hour

Cancer therapy- Drug delivery to cancer- Targeted drug delivery to cancer- Enhanced permeability and retention- Cancer markers- Folate receptor- Angiogenesis- Leaky vasculature- Targeting tumor vasculature for imaging-Pharmacodynamics- Photothermal therapy- Fluorescent Silica Nanoparticles for Tumor targeting

Unit-5 - Nanomaterials and Devices in Drug Delivery

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Photothermally-modulated drug delivery using nanoshell- Hydrogels- Nanoporous systems for drug delivery- transdermal drug delivery- low-frequency sonophoresis- implants for controlled drug delivery- Responsive release system- Fabrication and Applications of Microneedles- Micropumps- microvalves- Implantable microchips- Quantum Dot Probes- Nanorobots- Drug delivery to Central Nervous systems- Drug delivery across Blood brain barrier

Learning Resources	1. 2.	Drug Delivery: Engineering Principles for Drug Therapy, M. Salzman, Oxford University Press, 2001. Drug Delivery and Targeting, A.M. Hillery, CRC Press, 2002.	Drug Delivery: Principles and Applications, B. Wang, Wiley Intersceince, 2005 NanoparticleTechnologyforDrugDelivery, RamB.Gupta, UdayB.KompellaTaylor & Francis, 2006

Learning Assessment								
		Continuous Learning Assessment (CLA)				Cummativa		
	Bloom's Level of Thinking	Formative CLA-1 Average of unit test (50%)		Life-Long Learning CLA-2 (10%)		Summative Final Examination (40% weightage)		
		Theory	Practice	Theory	Practice Practice	Theory	Practice	
Level 1	Remember	20%	-	20%		20%	-	
Level 2	Understand	20%		20%	7 2 - 1	20%	-	
Level 3	Apply	30%	A POST OF THE PERSON NAMED IN	30%	1 / Je 1	30%	-	
Level 4	Analyze	30%	10 TO 10	30%	1 m	30%	-	
Level 5	Evaluate	\	A 5 A 3 A 5 A 5 A 5 A 5 A 5 A 5 A 5 A 5			-	-	
Level 6	Create			100		<u> </u>	-	
	Tota <mark>l</mark>	100 %		10	00 %	100 %		

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. ChandruTrivitron Healthcare Pvt. Ltd. Chennai, chandru.k@trivitron.com	1. Dr. Asifkhan Shanavas, INST Mohali, asifkhan@inst.ac.in	1. Dr. G <mark>. Devana</mark> nd Venkatasubbu, SRMIST
2. Dr. Achuth Padmanaban, Baylor Co <mark>llege of</mark> Medicine, USA,	2. Dr.Mukesh Doble, IIT M, mukeshd@iitm·ac	2. Dr. K. <mark>Janani S</mark> ivasankar, SRMIST
achuthz@gmail.com		

		Course		ourse	SOCIETAL IMPLICATIONS OF MANOTECHNOLOGY	Course	_	PROFESSIONAL ELECTIVE	L	T	Ρ	С	
out tune	L	Code	21NTE317T N	Name	SOCIETAL IMPLICATIONS OF NANOTECHNOLOGY	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses		Nil	
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		• •	Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		4			Progr	am Oı	ıtcome	s (PO)					rogram	
CLR-1:	provide an insight into th	e fundamentals o <mark>f social-econ</mark> omic implications of nanotechnology	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes	
CLR-2:	provide an insight into th	e fundamental <mark>s of ethical</mark> implications of nanotechnology	dge		of	SI	7	. "			Work		8				
CLR-3:			owlec		Jent	stigations	Usage	ъ			\ 		inan	ning			
CLR-4:	LR-4: understand the implications of nanotechnology in quality of life		줃	alysis	ldol	estig		r and	∞ ∞ >		Team	ion	≪ ⊡	ਕ			
CLR-5:	LR-5: explore the matters related to risk assessment associated with nanotechnology		ering	A	n/development of	> -	Tool	engineer aty	ment		<u>∞</u>	mmunication	Mgt.	g Le			
			liee liee	plem	/ugi	nduct in	dern	et en	Lai Lo	SS	ndividual	l E	əct	Long	7	2-5	
Course C	ourse Outcomes (CO): At the end of this course, learners will be able to:		Eng	Prot	Desi	Sol	Mod	The	Envi	E	Indi	Con	Proj	Life	PSO.	PSO-2	3
CO-1:	address the socioeconor	nic i <mark>mplicatio</mark> ns of nanotechnology	3	1	1.5	1-	-	-7	-	3	-	-	-	-	3		
CO-2:	20-2: apply the knowledge of ethical implications pertaining to nanotechnology		3	- 1	40.50	-11	-	1	-	2	-	-	-	-	-		
CO-3:	CO-3: address the legal risks related with the nanotechnology		2	وتواران		13	-	-	- 1	2	-	-	-	-	-	2 -	
CO-4:	0-4: improve the quality of life		3	4.47	5	-	-	-	-	3	-	-	-	-	-		
CO-5:	0-5: handle the issues related to risk assessment associated with nanotechnology		3			7-	_		_	2	_	_	_	_	_	2 -	

Unit-1 - Social-Economic Implications of Nanotechnology

9 Hour

Economic Impacts and Commercialization of Nanotechnology. Socio-economic impact of nanoscale science: initial results: nanobank, Managing the nanotechnology revolution, Malcolm Baldrige national quality criteria. Emergence of Nanoeconomy Key drivers, challenges and opportunities, Moore's law, Transcending Moore's law with molecular electronics, Molecular electronics – a next paradigm, Transcending Moore's law with nanotechnology, Transition from Microelectronics to nanoelectronics, Semiconductor scaling as a model for nanotechnology commercialization. Sustaining the impact of nanotechnology on sustainability

Unit-2 - Ethical Considerations Pertaining to Nanotechnology

9 Hour

Ethics, Law and Governance – Introduction. Ethics and law. Ethical issues in nanoscience and nanotechnology: reflections and suggestions. Concerns of Nano scientists and engineers in ethics and law. Ethics and nano: a survey. Recent developments in nanotechnology law in a new frontier. An exploration of patent matters associated with nanotechnology. U.S. Patent Statute. The ethics of ethics. Environmental Impacts of nanomaterials. Problems of governance of nanotechnology. Negotiations over quality of life in the nanotechnology initiative. Governance. Societal implications of emerging science. and technologies: a research agenda for science and technology studies (STS). Institutional impacts of government science initiatives Challenges for government and universities. Nanotechnology for national security. Nanotechnology in Defense

Unit-3 - Legal Risks Associated with Nanotechnology

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Nanoparticle toxicity and risk, Navigating nanotechnology through society, Public and private goods. Nanoparticle Toxicity and risk, Nanotechnology, surveillance, and society Methodological issues. Innovations for social research, Nanotechnology: societal implications: individual perspectives, Nanotechnology: nanotechnology and social trends; Five nanotech social scenarios Technological revolutions and the limits of ethics in an age of commercialization. Implications of Experiential data recorder. Vision, innovation, and policy. Institutionalizing Multi-Disciplinary Engagement. Post-hoc Versus Therapeutic Ethics, Nano revolution implications for the artist

Unit-4 - Coverging Interdisciplinary Technologies

9 Hour

Converging Technologies - Introduction Integrative Technology. Nanotechnology's implications for the quality of life. Social implications, Management of innovation for convergent technologies the "integration/penetration model" Social impacts of nano biotechnology issues. Nanobiotechnology: The Science Dimension. The Integration/Penetration Model: The Interface Range New Forms of Knowledge: Computer Simulations and Modeling. Regulatory structures and society. Social impacts of nanobiotechnology issues. The use of analogies for interdisciplinary research in the convergence of nanotechnology. Interdisciplinary research in the convergence of information technology Converging technologies: innovation, legal risks, and society. Converging technologies and their societal implications.

Unit-5 - Risk Assessment and Management

9 Houi

Public Perceptions and Education. Public perceptions-societal implications of nanoscience. An agenda for public interaction research. Communicating nanotechnological risks Risk Assessment, Risk communication. Problems in Risk communication. A proposal to advance understanding of nanotechnology's social impacts. Nanotechnology in the media: a preliminary analysis public engagement with nanoscale science and engineering, Nanophobia, Public Engagement with nanotechnology. Nanotechnology: moving beyond risk Communication streams and nanotechnology: the (Re) interpretation of a new technology nanotechnology, Societal implications- individual perspectives. The case of Cold Fusion, The case of Recombinant DNA

Learning Resources

- C.R. Mihail, and S.B. William, Nanotechnology: societal implications, Springer publication, 2011 (978-1-4020-5432-7)
- 2. Ronald Sandler, Nanotechnology the Social & Ethical Issues, Woodrow Wilson,
- 3. William S. Bainbridge, Societal Implications of Nanoscience and Nanotechnology, 2010 (079237178X, 9780792371786)
- 4. Fritz Allhoff, Patrick Lin, James H. Moor, John Weckert, "Nanoethics: The Ethical and Social Implications of Nanotechnology", John Wiley & Sons, 2007

Learning Assessme	ent		A STATE OF THE STA	The Control of the Co			
			Continuous Learning	g Assessment (CLA)	7	Cuma	matius.
	Blo <mark>om's</mark> Level of <mark>Thinkin</mark> g	(30%)			Learning A-2 9%)	Final Exa	native amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	To a 122 42 87	20%		20%	-
Level 2	Understand	20%		20%		20%	-
Level 3	Apply	30%	1	30%		30%	-
Level 4	Analyze	30%		30%	4	30%	-
Level 5	Evaluate	A .	- 1	-		-	-
Level 6	Create		- 1	-	7 -V		-
	Total	100	0 %	100) %	100	0 %

Course Designers		~ <i>//</i> /
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr.Ajay Kumar, Avansa Technology and services, India	1. Dr. Hirendra N Ghosh, Institute of Nanoscience and Technology, Punjab,	1. Dr. C. Gopalakrishnan, SRMIST
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2. Dr. Tanvi Sharma , Nanoshel LLC, Chandigarh, India,	2. Dr. Asish Pal, Institute of Nanoscience and Technology,	2. Dr. P. Sivakumar, SRMIST
tanvisharma@nanoshel.com	Punjab.apal@inst.ac.in	1

Course	21NTE401T Course	NANOTECHNOLOGY IN TISSUE ENGINEERING	Course _	_	PROFESSIONAL ELECTIVE	L	Т	Р	С	1
Code	Name	NANOTECHNOLOGY IN TISSUE ENGINEERING	Category	E	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

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Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	am Ou	itcome	s (PO)					rogram
CLR-1:	understand the general scientific concepts of tissue engineering	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	know the various types of tissues	ge		of	SI	,	. "			Work		g			
CLR-3:	acquire knowledge about biomaterials for tissue engineering and regenerative medicine	Knowledge	S	Jent	ation	Usage	ъ			\ N		Finance	ning		
CLR-4:	get acquainted with stem cells	ᅙ	alysis	udoli	investigations ex problems	l Us	r and	× ×		Team	ig	⋖	ਕੂ		
CLR-5:	understand the process of cell th <mark>erapy</mark>	ering	٩	sign/development of utions	t inv		engineer ety	nment nability		<u>8</u>	ommunication	Mgt.	g Le		
		Enginee	<u>a</u>	ign/	nduct in complex	dern	eng	iron	S	ndividual	nwu	Project I	Long	PS0-1)-2)-3
Course C	rse Outcomes (CO): At the end of this course, learners will be able to:				Se	Mo	The	Sus	Ethics	<u>i</u>	Š	Pro	Life	PS(PSO.
CO-1:	apply basic knowledge of tiss <mark>ue anat</mark> omy for tissue mimicking	3	-	1.5	-	-	-7	-		-	-	-	-	-	2 -
CO-2:	0-2: analyze the different tissue type		1	40.00	-19	-	4	-	-1	-	-	-	-	-	2 -
CO-3:	2-3: apply different biomaterials in tissue engineering for biomedical applications		100	4.7	13	-	_	- 1	- 6	-	-	-	-	3	
CO-4:	4: apply stem cells in tissue engineering			100	-	-	-	-		-	-	-	-	3	
CO-5:					X -	_		-		-	-	-	-	-	2 -

Unit-1 - Introduction to Tissue Engineering

9 Hour

Basic definition; current scope of development; use in therapeutics, cells as therapeutic agents, cell numbers and growth rates, measurement of cell characteristics morphology, number viability, motility and functions.

Measurement of tissue characteristics, appearance, cellular component, ECM component, mechanical measurements and physical properties

Unit-2 - Types of Tissues and Interactions

9 Hour

Tissue types and Tissue components, Tissue repair, Engineering wound healing and sequence of events. Basic wound healing Applications of growth factors: VEGF/angiogenesis, Basic properties, Cell-Matrix& Cell-Cell Interactions, telomeres and Self-renewal, Control of cell migration in tissue engineering.

Unit-3 - Biomaterials for Tissue Engineering

9 Hour

Properties of biomaterials, Surface, bulk, mechanical and biological properties. Scaffolds & tissue engineering, Types of biomaterials, biological and synthetic materials, Biopolymers, Applications of biomaterials, Modifications of Biomaterials, Role of Nanotechnology

Unit-4 - Stem Cells in Tissue Engineering Technology

9 Hour

Introduction, hematopoietic differentiation pathway Potency and plasticity of stem cells, sources, embryonic stem cells, hematopoietic and mesenchymal stem cells, Stem Cell markers, FACS analysis, Differentiation, Stem cell systems- Liver, neuronal stem cells, Types & sources of stem cell with characteristics: embryonic, adult, haematopoietic, fetal, cord blood, placenta, bone marrow, primordial germ cells, cancer stem cells induced pleuripotent stem cells.

Unit-5 - Stem Cell Therapy

9 Hour

Stem cell therapy, Molecular therapy, In vitro organogenesis, Neurodegenrative diseases, spinal cord injury, heart disease, diabetes, burns and skin ulcers, muscular dystrophy, orthopedicapplications, Stem cells and Gene therapy Physiological models, issue engineered therapies, product characterization, components, safety, efficacy. Preservation – freezing and drying. Patent protection and regulation of of tissue-engineered products, ethical issues.

	1.	Bernhard O.Palsson, Sangeeta N.Bhatia,"Tissue Engineering" Pearson Publishers	3.	Bernard N. Kennedy (editor). New York: Nova Science Publishers, 2008. Stem cell transplantation,
Learning		2009.		tissue engineering, and cancer applications
Resources	2.	Meyer, U.; Meyer, Th.; Handschel, J.; Wiesmann, H.P. Fundamentals of Tissue	4.	Sabu Thomas, Yves Grohens, Neethu Ninan, Nanotechnology Applications for Tissue Engineering
		Engineering and Regenerative Medicine.2009		1st Edition, Elsevier, 2015

Learning Assessm	ent				4, 1		
	DI I	Form	Continuous Learning		g Learning	l .	native
	Bloom's Level of Thinking	CLA-1 Averag		CL	.A-2 0%)		amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%		20%	2	20%	-
Level 2	Understand	20%		20%	-	20%	-
Level 3	Apply	30%	20 C C C C C C C C C C C C C C C C C C C	30%		30%	-
Level 4	Analyze	30%	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	30%		30%	-
Level 5	Evaluate			A		-	-
Level 6	Create		A THE REAL PROPERTY.	1919			-
·	Tot <mark>al</mark>	100)%	10	0 %	10	0 %

Course Designers		1 . Dr. 180	
Experts from Industry	Experts from Higher Technical Institutions	The state of the s	Internal Experts
1. Mr. K. Chandru, HCL Health care division, Chennai	1. Dr. Mukesh Doble, IIT M		1. Dr. G. Devanand Venkatasubbu, SRMIST
2. Dr. Asifkhan Shanavas, INST Moha <mark>li</mark>	2. Dr. T. Prakash, UOM	ALC: 175 33	2. Dr. N. Selvamur <mark>ugan., S</mark> RMIST

Course	21NTE402T Course	MICRO AND NANOFLUIDICS	Course	г	PROFESSIONAL ELECTIVE	L	T	Р	С	
Code	Name Name	WIICRO AND NANOFLUIDICS	Category □	_	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	Learning Rationale (CLR): The purpose of learning this course is to:		٦,	4			Progr	am Ou	itcome	s (PO)					rogram
CLR-1:	acquire knowledge on various physical principles related to liquid flows	1		2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	understand theory of fluid flow in micro and nano-size devices	a do	9		of	SI		, "s			Work		9			
CLR-3:	describe the concept of heat and mass transfer phenomena in channel	l a	₽	S	nent	estigations roblems	Usage	ъ	. 1				Finan	ning		
CLR-4:	unifies thermal sciences with colloi <mark>dal scien</mark> ces, biological sciences	Knowk	- 1 6	alysis	velopment of	estig/ probl		r and	ج ج ک	h.	Team	Įį.	∞ర	ä		
CLR-5:	gain knowledge on electrochemi <mark>cal mech</mark> anisms of micro and nanofluids	Pering	2	∢	ın/deve ons	nduct invi	'n Tool	engineer ety	nment inability		dual &	mmunication	t Mgt.	Long Le	_	3 2
Course C	Outcomes (CO): At the end of this course, learners will be able to:	Findi		Problem	Desig solutic	Condo of con	Modern	The en society	Enviro Sustal	Ethics	Individual	Comn	Project	Life Lo	PSO-1	PSO-2 PSO-3
CO-1:	apply the principles of liquid fl <mark>ow</mark>	3	- ;	3			-		-		-	-	-	-	-	2 -
CO-2:	analyze flow of fluid in micro and nano-size devices	3		2	4 50		-	4	-		-	-	-	-	2	
CO-3:	apply the knowledge of micro and nanofluidic devices, their fabrication, charecterization	.3	X1-19	2	1	-34	-	-	-	-	-	-	-	-	-	
CO-4:	utilize the opportunities in the emerging field of micro and nanofluids	2		3	351	-	-	-	-		-	-	-	-	-	2 -
CO-5:	apply the conceptsof electro <mark>chemica</mark> l mechanisms of micro and nanofluids	3		2	-	ť -	_		-	-	-	-	-	-	-	- 2

Unit-1 - Introduction to Microscale Liquid Flow

9 Hour

Liquid flow at low dimensions-- Micro and Nanofluidics -Micro and Nanofluidis devices- Design of micro and Nanofluidis-Preparatory concepts-Preparatory concepts-Constitutive Laws, Determination of transport properties- viscosity, diffusion coefficients, Determination of transport properties-thermal conductivity- Continuum approximation and its limitations, Kinematics- Surface forces, Body forces, Navier-Stokes equation, Navier-Stokes Equations in Cartesian Coordinates- Energy transport, Energy transport-conduction heat transfer, Two-dimensional, Steady flow- Incompressible flow

Unit-2 - Flow Analysis in Micro and Nano Size Devices

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Microscale viscous flow-Essentials, Structure of flow in a pipe or channel, Poiseuille flow in a pipe, Poiseuille flow in a pipe-derivation of maximum velocity, The velocity in slip flow of gases and liquids, Flow in a thin film under gravity-film flow rate, Fully developed suction flows, Velocity profile-suction flows, Developing suction flows, Darcy's flow, Surface tension driven flow and its quantitative approach, Stokes flow past a sphere and its drag calculation, Sedimentation of a solid particle, simple model for blood flow

Unit-3 - Heat and Mass Transger Phenomena in Channel

9 Hour

Heat transfer phenomena in channels and tubes, Mass transfer phenomena in channels and tubes, One-dimensional temperature distributions in channel flow, Temperature distributions in channel flow, Quantitative approach), Thermal and mass transfer entrance regions, Mass transfer entrance regions, The temperature distribution in fully developed tube flow, Nusselt number, The Graetz problem for a channel and its quantitative approach, Mass transfer in thin films, A thin liquid film falling under gravity, Classical Taylor-Aris dispersion and its quantitative approach, The stochastic nature of diffusion, Brownian motion, Unsteady mass transport in uncharged membranes, Temperature and concentration boundary layers

Unit-4 - Electrochemical Mechanisms of Micro and Nanofluids

9 Hour

Introduction to elements of electrochemistry and the electrical double layer, The structure of water and ionic species, Chemical bons in biology and chemistry, Hydration of ions, Chemical potential and its quantitative approach, The Gibbs function, Chemical Equilibrium, Electrochemical potential, Acids bases and electrolytes, Site-binding models of the silica surface, Polymer surfaces, Qualitative description of the electrical double layer and electrical double layer-triple layer model. The electrical double layer on a cylinder and on a sphere, Electrical conductivity in an electrolyte solution, Electrophoretic effect

Unit-5 - Opportunities in Emrging Micro and Nanofluids

9 Hour

Elements of cell biology and applications, Nucleic acids and polysaccharides, Proteins: Protein function and structure, Some common proteins, Few polypeptide chains are useful, Protein binding, Cells-The cell membrane, Membrane transport, Ion channels, Applications-DNA transport, DNA current, Development of an artificial kidney: Background, The nanopore membrane for filtration, Hindered transport, Biochemical sensing: Biosensor, Receptor-based classification of biosensors, Transducer-based classification of biosensors, Evaluation of biosensor performance, Nanopores and nanopore membranes for biochemical sensing

Learning Resources

- 1. TerrenceConlisk"EssentialofMicroandnanofluidics: withapplicationstobiologicalandchemical sciences" Cambridge University Press, 2018.
- 2. Joshua Edel "Nanofluidics" RCS publishing, 2016.
- 3. Henrik Bruus "Theoretical Microfluidics" Oxford Master Series in Physics, 2007.
- 4. Patric Tabeling "Introduction to Microfluids" Oxford U. Press, 2005.
- 5. ChristofM.Niemeyer&ChadA.Mirkin, "Nanobiotechnology: Concepts, Applicationand Perspectives", Wiley VCH, 2004.
- 6. SaritK.Das, StephenU.S. Choi, WhenhuaYu&T. Pradeep, "NanofluidsScienceand Technology" Wiley Interscience, 2007

Learning Assessme	nt			THE REAL PROPERTY.					
		3.00	Continuous Learning	Cumr	notivo				
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	Format CLA-1 Average (50%)	of unit test	CL	Learning A-2 0%)	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%	100	-20%	4	20%	-		
Level 2	Understand	20%		20%	3 -	20%	-		
Level 3	Apply	30%	Section 1	30%		30%	-		
Level 4	Analyze	30%		30%		30%	-		
Level 5	Evaluate					-	-		
Level 6	Create		4 - 4/7/	-	- N - N - N - N - N - N - N - N - N - N	-	-		
	Tota <mark>l</mark>	100 %	6	100	0 %	100	0 %		

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Mr. Sameer Sharda, New Age Instruments & Materials Pvt. Ltd, Gurgaon, sameer@newagein.com	Dr. Basavaraj Madivala Gurappa, IIT Madras, Chennai, basa@iitm.ac.in	1. Dr. Junaid Masud Laskar, SRMIST
Mr. Mohammed Shafi, Holmarc Opto-Mechatronics Pvt. Ltd, Cochin, optics@holmarc.com	2. Dr. Dillip K. Satapathy, IITM, Chennai, dks@iitm.ac.in	2. Dr. V. Eswaraiah, SRMIST

Course	21NTF403T Course	NANODODOTICS	Course _	DDOEESSIONAL ELECTIVE	L	Т	Р	С
Code	Name	NANOROBOTICS	Category	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

THE RESERVE

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	Program Outcomes (PO)					ogram									
CLR-1:	provide an insight into the	fundamentals o <mark>f nanorobotic</mark> s manipulation and assembly	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcomes	
CLR-2:	gain scientific understand	ling regarding <mark>the role of</mark> nanorobotics in the modern engineering applications	dge		of	SI		. ".			Work		e				
CLR-3:	understand the concept of	f nanomani <mark>pulation of</mark> nanostructures	wlec	w	velopment of	stigations	Usage	Ъ	. 1		am W		Finan	ЭG			
CLR-4:	learn the techniques of a	utomated <mark>manipula</mark> tion of nanoobjects	Αno	alysis	lopi	/estig probl		r and	∞ >	h.	Теаг	io	& Fi	arning			
CLR-5:	gain knowledge on theore	etical an <mark>d experi</mark> mental aspects of Nanorobotics	ring	A	/deve	.≦ ×	Tool	engineer aty	ment	. 1	<u>∞</u>	mmunication	Mgt.	g Le			
			inee	plem	ign/	duct ir	lern	enc ety	ron	S	/idu	nur	roject	Long	7	7 7	
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Eng	Prot	Des	of or	Мос	The	Sus	E E	Individual	Sol	Proj	Life	PSO-1	PSO-2	
CO-1:	apply the scientific conce	pts <mark>underlyi</mark> ng engineering and technological applications in nanorobotics	2	- 5	3	-	-	7	-		-	-	-	-	-	2 -	
CO-2:	acquire the knowledge of	na <mark>noroboti</mark> cs manipulation	2	- 1	4 74.5	3	-	4	-	-	-	-	-	-	-	2 -	
CO-3:	apply the knowledge of fa	nst <mark>imaging</mark> system for advance nanotechnology applications	- X	170	2	2	-		-		-	-	-	-	-	2 -	
CO-4:	get familiarize with the ne	w <mark>concept</mark> s of real-time nanomanipulation and apply those concepts using CAD	1 = -	140	. 3	2	-	-	-		-	-	-	-	-	2 -	
CO-5:	utilize the concept of nan	ob <mark>ots for m</mark> edical applications	4	4	3	2	_		-		-	-	-	-	-	- 2	1

Unit-1 - Introduction to Nanorobotics

9 Hour

Types of interaction forces – nanomanipulation using interaction forces – Actuation - Electro kinetic based actuation - Carbon nanotubes - Electro kinetic manipulation of carbon nanotubes - Graphene sheets – Nanoparticles - Biological entities - Biological nanomaterials - Laser based actuation-fundamentals - Laser based actuation-applications - Optical tweezers - Applications of optical tweezers - Manipulation of biological entities - Manipulation of chemical entities - Piezoelectricity - Piezoelectric enabled actuator

Unit-2 - Role of Nanorobotics in Modern Engineering

Hour

I Dielectric materials - Dielectric polarization - Electro rotation - Theory and modelling of electro rotation - Properties of fluid medium - Dynamic effects of fluid medium - Dielectrophoretic - Nanoparticles by dielectrophoretic - CNT-definition - Manipulation of CNT - Scanning probes - Nanomanipulation by scanning probe - Atomic scale stick-definition - Reducing atomic scale stick - Slip motion - Nanomanipulation by slip motion - Feedback control - Slip motion by feedback control - nanomanipulation

Unit-3 - Nanorobotic Manipulation and Assembly

9 Hour

Sensors-classifications - Art of compressive sensing - Fast imaging system - Compressive sensing based fast imaging system - SPM basics - AFM based imaging - Atomic manipulation in AFM - AFM based nanorobotic system - Augmented reality - AFM based nanorobotic system enhanced by augmented reality - Hardware setup for Sensing - Software setup for Sensing - Hardware setup for Sensing - Hardwar

Unit-4 - Real Time Nanomanipulation Using Cad

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computer-aided design (CAD) - CAD models of nanostructures - Automated manipulation of micro-nano objects - Automated manipulation of nanostructures - Automated manipulation of Nanowires - Automated manipulation of nanotubes - Automated manipulation of nanotubes - Automated manipulation of nanoparticles - Augmented reality system Limitation of augmented reality system Real time fault detection - Methods of real time fault correction - Time random drift - Time random drift compensation with local scan on-line fault detection - Interpretation of on-line fault correction Implementation of the data to test the hypothesis - Experimental results of the data to test the hypothesis

Unit-5 - Applications of Nanorobotics

9 Hour

Nanorobotic- introduction - Nanorobotic Applications - Endoscopy imaging - Wireless capsules endoscopy imaging - Energy harvesting - Energy harvesting by nanorobotic - Gastro-intestinal tract- introduction - Capsules robot in gastro-intestinal tract - Nanorobots - Introduction - Nanorobots - Design and application of nanorobotics in oncology - Drug delivery system - Cooperative control design for nanorobots in drug delivery - Medical applications of nanorobots - Medical applications of nanorobots: current - proposals and designs - Therapy using nanorobots - Cancer targeted therapy using nanorobots

Learning
Resources
11C3Ou1CC3

- 1. Ning Xi, Guangyoung Li, "Introduction to Nanorobotic Manipulation & Assembly" Artech House Press, 2012
- 2. Yi Guo, "Selected Topics in Micro/Nano-robotic for Biomedical Applications", Springer, 2013
- Klaus D. Sattler, "Hand Book of Nanophysics: Nano medicine & Nanorobotics", CRC Press, 2019
 Constantinos Mavroidis, Antoine Ferreira, "Nanorobotics Current Approaches and Techniques" Springer Link, 2013

earning Assessm	nent		Continuous Loomin	g Assessment (CLA)				
Bloom's Level of Thi <mark>nking</mark>		CLA-1 Avera	Formative CLA-1 Average of unit test (50%)		earning -2 6)	Summative Final Examination (40% weightage)		
		Theory	Practice	Theory	Practice	Theory	Practice	
Level 1	Remember	20%	Carlot of the control	20%		20%	-	
Level 2	Understand	20%	A Section of the Sect	20%		20%	-	
Level 3	Apply	30%	188 / C - 450 W.	30%		30%	-	
Level 4	Analyze	30%	Mar 1997 1997	30%		30%	-	
Level 5	Evaluate //	22 7 77 3 1		中央医院院内。		-	-	
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	Total Total	100)%	100 9	%	100	0 %	

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Interna <mark>l Expert</mark> s
1. Dr. Narayanasvamy Vijayan, National Physical Laboratory,	1. Prof. V. Subramaniam, IITM, Chennai, maninanvs@iitm.ac.in	1. D <mark>r. S. Mur</mark> ali, SRMIST
nvijayan@nplindia.org	1110	■ N
2. Dr. A. Pandikumar, Scientist, CSIR-CERL,	2. Prof. D. Arivuoli, Anna University, arivuoli@annauniv.edu	2. Dr. V. Kathirvel, SRMIST
pandikumar@cecri.res.in		

Course	21NTE404T Course	PHOTOVOI TAIC TECHNOI OGY	Course _	PROFESSIONAL ELECTIVE	L	T	Р	С	,
Code	Name	PHOTOVOLTAIC TECHNOLOGY	Category	PROFESSIONAL ELECTIVE	3	0	0	3	i

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	V./	7	4			Progr	<mark>am O</mark> u	itcome	s (PO)					rogram	
CLR-1:	understand the basics of so	olar energy and <mark>solar cells</mark>		1	2	3	4	5	6	7	8	9	10	11	12		pecific Itcomes	
CLR-2:	know about the materials p	roperties rel <mark>evant to ph</mark> otovoltaics		dge		o	SI					Work		8				
CLR-3:				owlec	W	Jent	stigations	Usage	Ъ	. 1		Μ		Finan	ning			
CLR-4:	Green the control of		i de Vigo	주	alysis	n/development of	estig		r and	ج ج ک	h.	Team	Įį.	∞ర	ä			
CLR-5:	get acquainted with new co	ncept <mark>s and de</mark> velopments in photovoltaics	AL,	ering	٩	deve	t inve lex pr	<u>6</u>	engineer a	nment nability	1	<u>8</u>	Communication	Mgt.	g Le			
			173	<u>e</u>	roblem	ign/	iduct in omplex	dern	eng ety	tain	SS	Individual	<u> </u>	roject	Long	7)-2	
Course C	e Outcomes (CO): At the end of this course, learners will be able to:		The said	Eng	Prof	Des	Con	Moo	The	Sus	Et	Indi	Sol	Proj	Life	PSO.	PSO-2	200
CO-1:	differentiate between differ	en <mark>t types o</mark> f photovoltaic technologies	-13	2	- 2	4-1	-	-	7	-		-	-	-	-	-	-	-]
CO-2:	interpret important properti	e <mark>s of sem</mark> iconductors relevant to photovoltaics	8.0	3	- 1	25	2	-	Ē	-	-	-	-	-	-	3	-	-
CO-3:	O-3: identify different photovoltaic device design concepts for different applications			3	No.	_3	43	-	_	-		-	-	-	-	-	- 2	2
CO-4:	CO-4: discuss advancement of different generations of solar cells			3	127	Gg f	2	-	-	-		-	-	-	-	-	3	-
CO-5:	D-5: discuss the advanced concepts and explorations in photovoltaics		F 11 2	3	4		3	_		-		_	_	-	-	-	-	-

Unit-1 - Introduction to Photovoltaics

9 Hour

Renewable energy technologies, Challenges, History of solar cells, Commercialization/economic factors, Basics of solar cell device and mechanism, Sun as a source of energy, The solar spectrum, Measuring sun light, Atmospheric effects, Terrestrial and space spectra; Air mass (AM0, AM1.5), Classification of photovoltaic technologies, Generations of solar cells, 1st generation photovoltaics, Silicon technology, 2nd generation photovoltaics, 3rd generation photovoltaics

Unit-2 - Photo Conversion, Seperation and Recombination

y Hour

Optical absorption, Carrier generation, Band gap, Direct vs. indirect bandgaps, Minority carrier transport -Carrier recombination-lifetime and defects, Band to band and Shockley-Read-hall recombination, High injection effects Surface and interface recombination, Implications on device performance, PN homojunctions, PN junction under dark and light, Photocurrent, Spectral response, non-idealities, Real p-n diodes, Temperature effects

Unit-3 - Characteristic Parameters and Device Studies

9 Hour

Solar Cell performance indicators, Device testing, Efficiency calculations, Parameters for ideal cells, Non-idealities, Series resistance, shunt resistance, Optical loss mechanisms and implications, Basics of solar cell device design, Minimization of losses, Lateral design and Vertical design, Optical versus electrical tradeoffs, Device optimization, Band gap and other material properties. Spectral utilization, Light management

Unit-4 - Various Types of Solar Cells

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Si photovoltaics, Fabrication, Single crystal Si solar cells, Polycrystalline/microcrystalline Si solar cells, Amorphous Si solar cells, Heterojunctions, p-i-n and n-i-p structures, thin film II-VI solar cells, Chalcopyrites, CdTe/CdS thin film solar cells, Superstrate structure, CulnGaSe2/CdS thin film cell technologies, Earth abundant alternatives, Dye-Sensitized solar cells, QDSSCs, ETA solar cells, Organic photovoltaics, Hybrid solar cells. Perovskite solar cells

Unit-5 - Next Generation Photovoltaic Cells

9 Hour

III-V photovoltaics, multi-junction solar cells, Spectral splitting, GalnP/GaAs/Ge triple junction solar cell, Bandgap profile optimization, Solar spectrum matching, Tunnel junctions, Current matching limitations, Concentrator photovoltaics (CPV)-, Concentrator optics, CPV cells, Terrestrial CPV systems, Space photovoltaics, Radiation effects in semiconductors and solar cells, new concepts, Quantum dots, wires, Intermediate band solar cells, Multiple exciton generation

Learning Resources
Resources

- 1. Solanki C.S., "Solar photovoltaics fundamentals, technologies and applications", 3rd edition, PHI LearningPvt Ltd, New Delhi, India
- 2. Fonash S.J., "Solar Cell Device Physics", Academic, 2010
- 3. Moller H.J., "Semiconductors for Solar Cells", Artech House, 1993.

4. Green M.A., "Third Generation Photovoltaics: Advanced Solar Energy Conversion", Springer, 2006Fundamentals of Solid-State Engineering, Manijeh Razeghi, Kluwer Academic Publishers, 2002

earning Assessm	Bloom's Level of Thin <mark>king</mark>	CLA-1 Avera	Continuous Learnin native ge of unit test 9%)	g Assessment (CLA) Life-Long CLA (10	4-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	2,734,784,747, 4, 5	20%		20%	-			
Level 2	Understand	20%	Carlot and the same	20%		20%	-			
Level 3	Apply	30%	A Section of the Sect	30%	. 1	30%	-			
Level 4	Analyze	30%	William Commence of the	30%		30%	-			
Level 5	Evaluate	S 100 100 100 100 100 100 100 100 100 10	NAME OF THE PARTY	7 10 10 10 10 10	- C	-	-			
Level 6	Create	44 77 34	171 172 35	一個电影器表现。		0 -	-			
	T <mark>otal — — — — — — — — — — — — — — — — — — —</mark>	100	0%	100) %	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.or	g 1. Dr. Sudhakar Chandran, IIT Madras, csudhakar@iitm.ac.in	1. Dr. S Venkata <mark>pra</mark> sad Bhat, SRMIST
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	2. Dr. M. S. Ramachandra Rao, IT Madras, msrrao@iitm.ac.in	2. Dr. P. Malar. SRMIST

Course	21NTE405T Course	ADVANCED COMPLITATIONAL TECHNIQUES	Course	PROFESSIONAL ELECTIVE	L	T	Р	С	1
Code	Name Name	ADVANCED COMPUTATIONAL TECHNIQUES	Category	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses		Nil	
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		• •	Nil	

Course L	earning Rationale (CLR): The purpose of learning this course is to:	$\Box I^{\gamma}$	1			Progr	am Oı	itcome	s (PO)				Pı	rogram	
CLR-1:	know the physical effects at the nanometer and sub-nanometer scales: how computational methods help to understand the properties and at nanoscale	can 1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes	
CLR-2:	acquire knowledge on molecular and optical computing	dge		of	SL		\ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \	7		Work		ce				
CLR-3:	know the basis of Biomedical Comp <mark>uting and</mark> its application		ဟ	evelopment	stigations	Usage	ъ			am W		Finan	д			
CLR-4:			alysis	lopi	estig	ol Us	r and	۲ × م >		Teal	ţį	∞	aming			
CLR-5:	acquire knowledge on parallel information processing mechanism and architecture	ering	₹	/deve	l.≧ ×		engineer ety	ment ability		<u>∞</u>	Communication	Mgt.	g Le			
		ě	roblem	B.5	omple	Modern To	et et	ron is	SS	ndividual	l III	roject l	Long	7	2 5	
Course C	Outcomes (CO): At the end of this course, learners will be able to:	Engi	Pro	Desi	Con	Mod	The	Envi Sust	Ethics	Indi	Con	Proj	Life	PSO-1	PSO-2	SS
CO-1:	apply the knowledge of the p <mark>roperties</mark> of nanomaterial in Quantum computing	3	1.5	3	- 1	-	1	-	-	-	-	-	1	3	-	-
CO-2:			3	3	-)	-	7	, -		-	-	-	-	-	3	-
CO-3:	-3: apply the knowledge of Biomedical Computing		1 14	£7.	3	-	_	<u> </u>		-	-	-	-	2	-	-
CO-4:	-4: execute the basic of Qubit problems and gain depth knowledge about Quantum Computing		3	3	3.5	-	-	-		-	-	-	-	-	3	-
CO-5:	5: apply knowledge of computing architecture in efficient optimization of the materials problems			- 3	45.	_		-		-	-	-	-	-	- :	2

Unit-1 - Computational Methods for Nanoscale Understanding

9 Hour

History of computing – Quantum Computing - Quantum Computing – Materails for Quantum Computing - Nano Information Processing - Prospects and Challenges - Digital Signals - Digital Gates - Introduction of Nanoelectronics - Application of Nanoelectronics - Application of Nanoelectronics - Application of Silicon Nanoelectronics - Application of Silicon Nanoelectronics - Application of Nanoelectronics - Application of Nanoelectronics - Nanoelectronics - Application of Nanoelectronics - Nanoelectro

Unit-2 - Molecular and Optical Computing

9 Hour

Molecular Computing - Applications of Molecular Computing - Modeling molecules - Modeling clusters of atoms - Overview of various first-principles methods - Discussion on Limitation and Application - Density Functional Theory (DFT) - HK and KS equations - Kohn Sham equation- Discussion on LDA and GGA - Structural, Electronic of nanomaterials from DFT calculations (Examples only) - Magnetic properties (examples only) - Concept of Optical Computing - Application of Optical Computing - Current use of optics for Computing in Industry - Optics for Computing: Future Applications - Optical Computing Paradigms - Optical Computing Paradigms: Examples - Working concept of Photonic Switches - Application of Photonic Switches.

Unit-3 - Biochemical Computing and Examples

9 Hour

Introduction to Biochemical Computing - Examples of Biochemical Computing - Application of DFT in biological system - Bsics of Molecular Dynamics Simulation (MD) - Block Diagram of MD- Constant Tempature MD - Application of MD in biological system - Genetic Algorithm - Application of GA to Biological Systems - Biological Neurons - Biological Neurons in information processing - Function of neuron cell on silicon for Signal processing - Modeling of neuron cells by VLSI circuits - Problems on Modeling of neuron cells by VLSI circuits - Neural networks and distributed data processing - Working concept of DNA Computer - Application of a DNA Computer - Information Processing with Chemical reactions: Working Concept - Information Processing with Chemical reactions: Example.

Unit-4 - Concepts and Applications of Quantum Computing

9 Hour

Bit and Qubit - Coherence and Entanglement - Concept of Coherence - Concept of Entanglement with Examples - Theory of Quantum Parallelisms - Application of Quantum Parallelisms - Classical Gates – Reversible Operations - Sqrt (NOT) Operation - Concept of Quantum Algorithm - Application of Quantum Algorithms - Challenges to large Quantum Computers - Fabrication, Testing Architectural Challenges - Working Concept of Quantum dot cellular automata - Application with Example of Quantum dot cellular automata - Introduction and Working principle of Computing with QCA - Application of Computing with QCA - QCA Clocking - QCA Design Rules - Electronic Struture Calculations on Quantum Computers - Magnetic calculations

Unit-5 - Parallel Information Processing and Architecture

9 Hour

Parallel computing - Shared and Distributed Memory Clusters - Parallel algorithm - MPI based algorithm as example - Working Concept of Mono and Multiprocessor Systems - Applications: Mono and Multiprocessor Systems - Some considerations to Parallel Processing - Usefulness of Parallel processing in various device applications - Influence of Delay Time - Performance efficiency on Delay time - Power Dissipation - Power Dissipation in different system - Architecture for Processing in Nanosystems - Classic Systolic Arrays - Processor with large memory - Application of Processor with large memory - Processor array with SIMD - PIP Architectures- Optimize choice of processors to solution- Comparisim between Parallel and Quantum Computer in terms of performance

Learning Resources

- Vishal Sahni et.al, Nanocomputing: The Future of Computing, Tata McGraw-Hill Education, 2008.
- Feliciano Giustino, Materials Modelling using Density Functional Theory: Properties and Predictions, Oxford: Oxford University Press, 2014.
- 3. J.M. Thijssen, Computational Physics, Cambridge University Press, 2007.
- 4. AndrewR.Leach, Molecularmodelling: principlesandapplication, PearsonEducation, 2001

Learning Assessme	ent			- That sale			
	Bloo <mark>m's</mark> Level of <mark>Thinkin</mark> g	CLA-1 Avera	Continuous Learning mative age of unit test 0%)	g Assessment (CLA) Life-Long CLA (10	4-2	Final Ex	mative amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%		20%		20%	-
Level 2	Understand	20%	The same of the same	20%	3 - >	20%	=
Level 3	Apply	30%		30%		30%	=
Level 4	Analyze	30%	The state of the s	30%		30%	=
Level 5	Evaluate		- 1/3//	-	-4	-	=
Level 6	Create	PAGE 1	- 1.17	-		-	-
	Total	10	00 %	100	1%	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Hemant Dixit, GlobalFoundaries, aplahemant@gmail.com	1. Dr. Ranjit Kumar Nanda, IITM Chennai, nandab@iitm.ac.in	1. Dr. C. Preferencial Kala, SRMIST
2. Dr. Murali Kota, Global Foundaries, USA, kvrmmurali@gmail.com	m 2. Dr.Biswarup Pathak, IIT Indore, biswarup@iiti.ac.in	2. Dr. Saurabh Ghosh, SRMIST

Course	21NTE406T	Course	NANOTECHNOLOGY LEGAL ASPECTS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	1
Code	Z1N1E4001	Name	NANOTECHNOLOGY LEGAL ASPECTS	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Nil	Co- requisite Courses	Nil P	rogressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	111	4			Progr	<mark>am</mark> Ou	tcome	s (PO)				Р	rogram	
CLR-1:		able moving acro <mark>ss the fields</mark> of science, ethics, and law and be able to fill a al, social, and p <mark>olicy implic</mark> ations of nanotechnology from a global governance		2	3	4	5	6	7	7 8 9		10	11	12	_	pecific utcomes	
CLR-2:	familiarize with the concep	ot of patent, copyright laws trade mark, trade secret and IP infringement	dge	I	of	S		١. ٠			Work		Se				
CLR-3:			Knowlec		Jent	stigations	sage	70		1	×		Financ	б			
CLR-4:			Kno	alysis	ndol	estigatior problems	\cap	r and	& <u>></u>		Team	ion	& Fi	aming			
CLR-5:			neering	em An	gn/development of ions	induct inves	Modern Tool	engineer ety	vironment stainability	χ	ndividual &	Sommunication	ect Mgt.	Long Le	1-1	-5	-3
Course C	urse Outcomes (CO): At the end of this course, learners will be able to:		Engi	Probl	Designation	Conc of co	Mode	The en	Envii Sust	Ethics	ndiv	Com	Proje	Life I	PSO	PSO-2	PSO
CO-1:	acquire the knowledge the	regulatory policies of social and legal aspects	3	10	18 50	- 1	-	2	3	2	-	-	-	-	-	-	3
CO-2:	understand the concepts of natents, converget laws and apply the knowledge of trademark, trade secret		et 2	i in	4	-52	-	2	3	3	-	-	-	-	-	-	3
CO-3: acquire the knowledge on environmental degradation and current regulations		2	4.75	100		-	3	2	2	-	-	-	-	-	-	3	
CO-4: get familiarize with the current trends in legal and ethical impacts of nanotechnology		2		-	Z -	-	3	2	2	-	-	-	-	-	-	3	
CO-5:	fuel with the government policies and rules related to taxation, trade, security, privacy, export import of		of 2	1.5	14	-	-	3	3	3	-	-	-	-	-	-	3

Unit-1 - Policies of Social and Legal Aspects

9 Hour

Big Questions about defining little Nanoparticles- simple applications of Nanotechnology of day-to-day life- Labels: how Big is nano, how small is not nano,- capturing the discovery: the limits of lists and numbers as regulatory criteria- sample legal definitions- the lessons learned from the legend of Asbestos- components of international regulation exposure of legend Asbestos- Rethinking traditional policies- Integrating nanotechnology into international laws- abundance of laws- WHO constitution – codifying precautionary principles- synthesizing NT advances into harmonized legislative texts- Nanotechnology revolutionizing risk communications – due diligence is your best friend- the Question is knowledge and consent, not the magnitude of risks- revolutionary promises of nanoparticles, nanomedicine- nanoworld cancer day, benefits to patients: new bones, new teeth, and new organs- Stakeholders, one and all- Hamilton's legacy – Governmental obligations

Unit-2 - Intellectual Property and Copyright

9 Hour

Technical knowledge of patents- Patentability requirements - structure of patents - classification of patent applications- design patent, monopoly powers- Reexamination of patents - licensing strategies and arrangements- Willful Patent treaties infringement issues, claim scope- Patent treaties- Copyright laws - fixation, Originality, creativity- Government policies and rules- Integrated circuit topographies- Technology transfer - Civil laws- Criminal laws in nanotechnology- Trade secrets- Ownership of IP

Unit-3 - Environmental Degradation and Regulations

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Environmental degradation and its consequences- Current environmental regulations- Classification of pollutants- Sources/origins of pollutants- Pollution – air- Pollution – water- Industrial waste water treatment-Control and quality check - Dispersion methods – aerobic and non-aeroobic- Monitoring and its regulatory boards- House-hold- Solid wastes – Solid waste – industrial/commercial type- Hospital waste and recycling methods- Hazardous chemical waste- Toxicity, health issues- Safety and health issues- Risk assessment and analyses- Tracking, responsibility and rules

Unit-4 - Social Impacts of Nanotechnology

9 Hour

Social impacts of nanotechnology- Economic impacts of nanotechnology- Implications of nanotechnology- Effect on the quality of life- Short term and long-term implications- Legal, societal implications in Nanotechnology- Ethical issues in nanotechnology- Social and environmental issues in nanotechnology- Artificial intellects- Ethics, for artificial intellects- Nanotechnology and life extension- Nanotechnology for national security- Nanotechnology for space exploration- Nanotechnology for medical applications- Moral issues of nanotechnology applications- Public perception of nano-technological risks- Education of public about nanotechnology- Training to the public about nanomaterials

Unit-5 - Trade and Business in Nanotechnology

9 Hour

Trade and business in nanotechnology- Trade restrictions and barriers- Taxation system – national and international regulatory bodies- Taxation of goods: - too small to be seen- Laws for genetic research- Rights of new life form- Governmentsurveillance and monitoring- Privacy violations- Security and monitoring Eavesdropping – case studies- R&D in nanotechnology- R&D regulation- Current industrial design laws-Change in industrial design laws- Export – import regulations- Crimes involved in nanoparticles- Corporate criminal liability, intentions- prevention and detention

Learning	
Resources	

- 1. Patrick M. Boucher, "Nanotechnology: Legal aspects" CRC press, 2008
- 2. Fritz Allhoff, Patrick Lin, James Moor, John Weckert, "Nanoethics: The ethical and social implications of nanotechnology" Wiley publication, 2007
- 3. Louis Theodore, Robert G. Kunz, "Nanotechnology: Environmental implications and solutions" Wiley Publication, 2005
- 4. Ilise Feitshans, Global Health Impacts of Nanotechnololaw, Taylor and Francis group, 2018Espresso) and Page 300-307 (VASP)

Learning Assessme	ent			TAKES IN			
•	Bloom's Level of Thinking	CLA-1 Avera	Continuous Learnin native rge of unit test 0%)	CL	Learning A-2 0%)	Final Exa	native amination eightage)
	9 9	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20%	The 1997 AND	20%	-	20%	-
Level 2	Understand	20%	10 70 70 70 70 70	20%	-	20%	-
Level 3	Apply	30%	10 mm	30%		30%	-
Level 4	Analyze	30%		30%		30%	-
Level 5	Evaluate		The state of the s	Annual Control		-	-
Level 6	Create		- 4/1//	-	-4		-
	Total	10	0 %	100	0 %	10	0 %

Course Designers		<i></i>
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Narayanasvamy Vijayan, National Physical Laboratory,	1. Prof. V. Subramaniam, IITM, Chennai, manianvs@iitm.ac.in	1. Dr. Ala <mark>giris</mark> wamy A A, SRMIST
nvijayan@nplindia.org	ZITEARN - FEAR TRUE	
2. Dr. Krishna Surendra Muvvala, Saint Gobain Research India,	2. Prof. D. Arivuoli, Anna University, arivuoli@annauniv.edu	2. Dr <mark>. P. Malar,</mark> SRMIST
India, Krishna.muvvala@saintgobain.com	LILII LIV	

Course	24NITE407T Course	MICDO AND NANO EMILI CIONO	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Name Name	MICRO AND NANO EMULSIONS	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		1			Progr	<mark>am</mark> Οι	ıtcome	s (PO)					ogram	1
CLR-1:	acquire knowledge on mid	ro and nano em <mark>ulsion and its</mark> stability	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcomes	
CLR-2:	understand the various pr	operties of em <mark>ulsion</mark>	acc	0	of	SI		. "			Work		8				
CLR-3:				2	n/development of	stigations	Usage	ъ	, 1		\ N		Finance	βL			
CLR-4:	understand the formulatio	n of Nan <mark>o emulsio</mark> n	Knowle		dol	estig		r and	م ^ک ح	h.	Team	ig	∞ర	arning			
CLR-5:	learn the applications of e	mulsio <mark>n for vari</mark> ous fields	ering	An	deve	l.≧ ×	Tool	engineer a	nment nability	. 1	<u>∞</u>	Sommunication	Mgt.	g Le			
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Course C	Outcomes (CO):	At the end of this course, learners will be able to:	E C	Prof	Des	g G g	Moc	The en	Envi	Ethics	lpdi	Col	Proj	Life	PSO-1	PSO-2 PSO-3	
CO-1:	explore basic principles in	ch <mark>emistry o</mark> f microemulsions	3	- 1	1		-	-7	-		-	-	-	-	3		
CO-2:	explain properties of emul	lsio <mark>n by con</mark> cept of phase diagram	3	- L	40.50		-	4	-		-	-	-	-	3		
CO-3:	analyze the stabilization n	ne <mark>chanism</mark> in emulsions	.3	MIL TO		13	_	_) -	-	-	-	-	-	-	2 -	
CO-4:	apply the formulation of m	ic <mark>ro and n</mark> ano emulsions	11/2	54	2		-	-	- 1		-	-	-	-	-	2 -	
CO-5:	elucidate importance of ea	mu <mark>lsions in</mark> various technological applications		٠.		2	_	-	-		-	-	-	-	-	- 2	1

Unit-1 - Introduction to Micro and Nano Emulsions

9 Hour

Emulsion definition and characteristics- Definition of micro emulsion- Definition of nano emulsion- Theory of emulsion and methods- Theory of Micro emulsions- Theory nano emulsions- Preparation of microemulsion of nano emulsions- Ostwald ripening- Flocculation- Coalescence of drops- Applications of emulsions- Different application of micro and Nano emulsions

Unit-2 - Microemulsions and its Properties

y Hour

phase diagram approach to microemulsion- Partial generic phase diagram- Microemulsion formation- Ordering and disordering- Temperature Dependence of microemulsion ordering- Vapor Composition from Microemulsions- Ekwall on the association structures- Water-surfactant combination- Physicochemistry of W/O microemulsion formation- Stability of emulsions- Droplet clustering- Energetics of Droplet Clustering-Phenomenon in microemulsion- Percolating phenomenon in microemulsion- Scaling Laws- Effect of external entity-Microemulsions with mixed nonionic surfactants- Organ chalcogenides, Aromatic Heterocyclic Compounds- Properties of microemulsions with mixed nonionic surfactants

Unit-3 - Mechanism of Emulsification

9 Hour

Mechanism of Emulsification- Surface forces- Van der walls interactions- Electrical interactions- Phase inversion phenomena- Phase behaviorsof emulsions- Standard inverse boundary- Dynamic inversion- Dynamic behavior of emulsion- Spontaneous emulsification- Recent development with emphasis on self-emulsification- Self-emulsification process- Organic Reactions in Emulsions- Microemulsions- Symmetric thin liquid film with Fluid interfaces- Formation emulsified microemulsion- Microemulsion properties- Characterization of emulsified microemulsion

Unit-4 - Nanoparticle Formation in Microemulsions

9 Hour

Nanoparticle formation in microemulsion- Concept of formation in microemulsion- Chemical Reaction- Nucleation- Exchange mechanism in emulsions- Autocatalysis- Mechanism of microemulsion- Critical Nucleus Size- Chemical Reaction Rate- Nanoparticles uptake from W/O emulsion- W/O emulsion process- Nanoparticle Uptake in Reactive Surfactant Systems- Nanoparticle Uptake in Nonreactive Surfactant Systems- TiO2 nanoparticle in micro-emulsion and photophysical properties- Optical Absorption and Emission of TiO2 Nanoparticles in Microemulsion- Electron Transfer Dynamics in CatecholSensitized TiO2 Nanoparticles- Properties of interfacial electron transfer dynamics- Interfacial electron transfer dynamics

Unit-5 - Characterization and Applications of Microemulsions

9 Hour

Characterization and Application of Microemulsion- Introduction in basics and principles of NMR- NMR technique for measurement emulsion- Relaxation measurements on emulsions via CPMG experiments- Diffusion measurements on emulsions via PGSE and PGSTE experiments- Introduction and basics of ultrasound- Ultrasound characterization for emulsion- Ultrasound characteri

Learning Resources	
Resources	

- 1. Fanun, Monzer. Microemulsions: properties and applications, CRC press, 2008.
- Sjoblom, Johan. Emulsions and emulsion stability: Surfactant science series/61. CRC Press, 2005.
- 3. Berg J. C., An Introduction to Interfaces and Colloids: The Bridge to Nanoscience, World Scientific, 2010

Learning Assessm	ent	- AND 2				Name of the second	
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	Total	100)%	100	%	100) %

Course Designers	The state of the s	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Krishna Surendra, SAINT GOBAIN, Krishna.muvvala@saintgobain.com	1. Dr. Vinu, IITM, vinu@iitm.ac.in	1. Dr. Junaid Masu <mark>dLaskar,</mark> SRMIST
2. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.org	2. Dr. S. Ramaprabhu,IITM, ramp@iitm.ac.in	2. Dr. V. Eswaraia <mark>h, SRMI</mark> ST

Course	21NTE408T Course	CUDDAMOLECULAD CYCTEMS	Course _		L	Т	Р	С	Ì
Code	Name	SUF NAIWOLECULAN STSTEWS	Category	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	11	4			Progr	am Oı	ıtcome	s (PO)					ogran	
CLR-1:	acquire the concepts of su	ıpramolecular ch <mark>emistry</mark>	1	2	3	4	5	6	7	8	9	10	11	12	Specific Outcomes		
CLR-2:	CLR-2: utilize designing new materials of metal-organic frame works				of	SI		. "			Work		8				
CLR-3:	CLR-3: describe the concept of nanostructured objects			alysis	velopment	stigations	Usage	ъ	, 1		Μπ		Finance	ng			
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Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Eng	Pro	Design	o So	Mod	The	Envi S <mark>us</mark> f	Ethics	Individual	Com	Project	Life	PS0-1	PS0-2	PSO-3
CO-1:	analyze the main types of	su <mark>pramolec</mark> ular assemblies and molecular recognition	3	- 5		2	-	-7	-		-	-	-	-	2	-	-
CO-2:	evaluate the host-guest cl	ne <mark>mistry in</mark> supramolecules	2	3	40.70	- 1	-	4	-	-1	-	-	-	-	-	-	-
CO-3: analyze the nature of bindings involved in biological systems		2	172	3	13	-	-) -		-	-	-	-	-	2	-	
CO-4: analyze and understand the intermolecular forces to rationalize the formation of complex nanomaterials		3	140	2	2	-	-	- 1		-	-	-	-	-	-	2	
CO-5:			خيا	- 2	3		1		_	_	-	_	-	_	2	_	_

Unit-1 - Basic Concepts of Supramolecular Systems

9 Hour

Basic concepts and principles of supramolecular chemistry - Classification of supramolecular compounds - Host-guest compounds - Molecular recognition, Hydrogen Bonds: Definition, Structure and Stability-strength, Secondary Electrostatic Interactions in hydrogen bonding arrays -Non-covalent interactions: Ion pairing - Ion-Dipole Interactions- Dipole interactions - Dipole-Induced Dipole and Ion-Induced Dipole interactions - van der Waals or Dispersion Interactions, Cation- interaction- Anion-pi interactions, pi - pi interactions - Closed shell interactions, Aromatic-Aromatic Interactions: Benzene Crystals, Edge-to-face vs. pi-pi Stacking Interactions, N-H- pi interactions, Sulfur-aromatic interactions, Benzene-Hexafluorobenzene pi-stacking

Unit-2 - Coordination Chemistry

9 Hour

Introduction to coordination chemistry - Hosts for cation binding - Cation receptors - Crown ethers - Cryptands - Spherands - Calixarens - Selectivity of cation complex - Macrocyclic effects - Template effects - Host for anion binding - Concepts in anion host design - Anion receptors - Biological Receptors - Conversion of Cation Hosts to Anion Hosts - Neutral Receptors - Metal-Containing Receptors - Cholapods

Unit-3 - Biological Inspiration for Supramolecular Chemistry

9 Hour

Biological inspiration for supramolecular chemistry - Alkali metal cations in biochemistry - Co-ordination Polymers — Clathrates — Cavitands - Binding by cavitands — Cyclodextrins — Cucurbituril - Porphyrins and tetrapyrrole macrocyles - Transport processes - Dynamic Combinatorial chemistry - Supramolecular features of plant photosynthesis - Uptake and transport of oxygen by haemoglobin - Enzymes and coenzymes - Neurotransmitters and hormones - Enzymes. Metallobiosites - Heme analogues - Semiochemistry in natural world. Biochemical self-assembly

Unit-4 - Chirality, Metal Organic Frameworks-Characterization

9 Hour

Supramolecular Chirality - Chirality in Self-Assembled Systems - Chirality of Host-Guest Compounds - Chirality of Interlocked Systems - Metal Organic Frameworks (MOFs) - Covalent Organic Frameworks - Polymorphism — Solvates - Co-Crystals - Principles of supramolecular Extraction - Extraction technique, the extraction equilibrium - Examples of supramolecular extraction - Binding Constant - Binding constant determination by UV/Vis spectroscopy - Instrumentation of mass spectrometry, Limitations of mass spectrometry - Scanning probe microscopes: - scanning electron microscopy - Transmission electron microscopy - Confocal laser scanning microscopy

Unit-5 - Application of Supramolecules

9 Hour

3. Donald A. Tomalia, Jørn B. Christensen, Ulrik Boas, "Dendrimers, Dendrons, and Dendritic

Special Class Materials - Birth of a new macromolecular chemistry concept - Rational Design - Molecular Paneling - Artifical Self Replicating Systems - Supramolecular reactivity and catalysis - The past, present and future of dendrimers and dendrons - Supramolecular assembly of dendrons and dendrimers - Synthesis of dendritic polymers - Characterization of dendritic architectural structures - Nanomedical and advanced materials - Diagnostics and advanced imaging - Characterization of dendritic architectural structures - Nanoscience applications - Molecular and Supramolecular devices - Molecular Electronic Devices – Switches -Molecular Machines

Lagraina	1.	Jonathan W. Steed a
Learning		Sons; 2011
Resources	2	I M Lohn Sunramolo

- and Jerry L. Atwood<mark>, "Supramolecul</mark>ar Chemistry"J. Wiley and
- Polymers: Discovery, Applications and the Future", MPG books group, UK, 2012 2. J. M. Lehn, Supramolecular Chemistry, VCH, Wiley and Sons, 1st Ed. Weinheim, 1995

		7 AND 2	Continuous Learnin	g Assessment (CLA)		Cum	mativa	
	Bloom's Level of Thin <mark>king</mark>	CLA-1 Avera	native ge of unit test 1%)	Life-Long CLA (10	1-2	Summative Final Examination (40% weightage)		
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Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. P. Sudhakara, CLRI – CSIR, Jalandhar, sudhakarp@clri.res.in	1. Dr. Kothandaraman Ramanujam, IITM Chennai, rkraman@iitm.ac.in	1. Dr. N. Angeline Little Flower. SRMIST
2. Dr. Sudhakar Selvakumar, CSIR-Central Electrochemical Research Institute,	2. Dr.Arthanreeswaran, NIT, Trichy,arthanareeg@nitt.edu	2. Dr. C. Siva, SRMIST
ssudhakar79@gmail.com	1100	

Course Code	21NTE409T	Course Name	CANCER	R NANOTECHNOLOGY		Cours Catego	-	Е			PROF	ESSIO	NAL E	LECT	IVE		L 3	T 0	P 0	C 3
Pre-requis		Nil	Co- requisite Courses	Nil	****		ogres Cours							Nil						
	Offering Departme	ent	Physics and Nanotechnolo	Data Book / Cod	es / Standard		Jours	C 3					Nil							
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	arning Rationale	. ,	purpose of lea <mark>rning this</mark>	course is to:	AL 33		4			Progr	am Ou	tcome)					ograr pecific	
CLR-1:	understanding th	e basis of canc	er biology	<u> </u>		1	2	3	4	5	6	7	8	9	10	11	12		tcom	
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CLR-3:	getting knowledg	ge about ways to	o trea <mark>t cancer g</mark> rowth			Engineering Knowledge	S	Design/development of solutions	investigations ex problems	age	ъ			Individual & Team Work		nan	Вu			
CLR-4:	get acquainted w	vith nanomateria	al b <mark>ased cur</mark> rent therapies	available for cancer treatment	S. 127	Kno	Analysis	ldo	estig	Modern Tool Usage	r and	∞ >		Теа	.io	& F	Life Long Learning			
CLR-5:	get acquainted w	vith the current t	r <mark>end in ca</mark> ncer theranostic	es ·	STOPPACT !	ring	Ans	eve (inve ex p	2	The engineer society	nent Ibility		∞ —	icat	∕lgt.	J Le			
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Course Ou	tcomes (CO):	At t	<mark>he end</mark> of this course, le	arners will be able to:		Engi	Problem ,	Design/desolutions	Conduct involved of complex p	Mod	The en society	Environment Sustainability	Ethics	Indi	Communication	Project Mgt. & Finance	Life	PS0-1	PS0-2	PSO-3
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CO-4:	apply these nand	osystems fo <mark>r the</mark>	diagnosis and therapy		47.4	3	150	125		-	-	-		-	-	-	-	3	-	-
CO-5:	apply the concep	ots of nano t <mark>her</mark> c	o <mark>nos</mark> tic strategy	N. N. S.	N. B. J.	3			I -	-		-		-	-	-	-	-	-	1
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Resources	2. Cancer	Biology, Raymo	ond W. Ruddon, Oxford Ur	niversity press, 2007.																

			Continuous Learning	Assessment (CLA)		C		
	Bloom's Level of Thinking	CLA-1 Avera	native ge of unit test %)	CL	g Learning _A-2 <mark>0%)</mark>	Summative Final Examination (40% weightage)		
		Theory	Practice	Theory	Practice	Theory	Practice	
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Level 2	Understand	20%		20%		20%	-	
Level 3	Apply	30%	3	30%		30%	-	
Level 4	Analyze	30%	-	30%		30%	-	
Level 5	Evaluate		-			-	-	
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	Total	100) %	10	0 %	10	0 %	

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, HCL Health care division, Chennai	1. Dr. Mukesh Doble, IIT M	1. Dr. G. Devan <mark>and venka</mark> tasubbu, SRMIST
2. Dr. Asifkhan Shanavas, INST Mohali.	2. Dr. T. Prakash, UOM	2. Prof. N. Selvamurugan, SRMIST



Course	21NTE410T	Course	ATOMISTIC MODELING	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	21N1E4101	Name	ATOMISTIC MODELING	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Nil	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	TIME.	Program Outcomes (PO)											ogran			
CLR-1:	learn about basic modeling				3	4	5	6	7	8	9	10	11	12		ecific	
CLR-2:	understand the DFT for materials mode <mark>ling</mark>		dge		of	SL	-	. "			Work		g				
CLR-3:	understand the MD simulation		wlec	S	Jent	estigations roblems	Usage	ъ			Α		Finance	ng			
CLR-4:	gain knowledge about Monte Carlo Simulation	17.72	Knowle	nalysis	velopment	estig		r and	∞ ∞ >	h.	Team	ion	∞ర	arni			
CLR-5:	learn advance-modeling techniqu <mark>e</mark>	\$500 PA	ering	⋖	deve	t inve	Tool	engineer stv	rironment stainability	. 1	∞ర	ommunication	Mgt.	g Le			
			9	roblem	fign/	nduct	Aodern	enc etv	ron	SS	/idu	nuı	Project	Long	7	7.5	
Course O	Outcomes (CO): At the end of this course, learners will be able to:		Engi	Prot	Des	Con	Moc	The	Sus	Ethics	Individual	Col	Proj	Life	PS0-1	PS0-2	PSO-3
CO-1:	acquire the basics of design and materials modeling	V 31/2 - 1/2	3	- 3	- 72	-	-		-		-	-	-	-	-	-	-
CO-2:	gain knowledge on DFT and the approximations in the context of materials modeling	No. Wall	3	3	40	7-14	-	4	-		-	-	-	-	3	-	-
CO-3:	obtain the knowledge on Molecular Dynamics and its application to solve materials proble	m	3	172	4.4	3	-	_	-		-	-	-	-	- 1	-	-
CO-4:	improve their knowledge on materials modeling with Monte Carlo Simulation	47 4 1	3 -	100	1357	-	2	-	-		-	-	-	-	-	-	-
CO-5:	solve problems to understand the electronic, mechanical and optical properties of N	laterials using	3	-3	- 3	7.	-		-	-	-	-	-	-	-	2	-

Unit-1 - Basics for Modeling 9 Hour

Classical mechanics, Hamiltonians- Coordinate systems in the context of solving the physical problems- Potential energy-Definition and Concept — Calculation of elastic constants from potential function- Potentials for ionic systems- Potentials for ceramics Systems- Concept of Many-body potential -Many-body potentials for metals- Many-body potentials for covalently bonded systems - Comparative Study- Energy optimization - Significance of Lowest energy structure- Molecular statistics - Problems on Molecular Statistics

Unit-2 - Density Functional Theory

Born-Oppenheimer approximation- Limitations of BO approximation - Introduction to DFT- Hohenberg-Kohn Theorems- Kohn-Sham Equation- Interpretation of KS equations- Exchange-correlation functions and LDA/GGA- Accuracy of LDA/GGA- PW91 method, PBE method -Pseudopotentials - Types of Pseudopotentials - Brillouin zone- K-points, Concept of Basis Set- The need for self-consistency- Setting up structures, key parameters, Volume optimization Metals vs.insulators- Basis sets, energy cutoff, exchange-correlation function, K-points- Convergence and scaling with lattice parameters

Unit-3 - Molecular Dynamics Simulations

9 Hour

The basic MD algorithm- The MD steps- Taylor expansion- Verlet algorithms - choosing the time step- Predictor-corrector algorithm - Discussion with Examples- MD in different ensembles- MD in constant temperature- Molecular dynamics in constant pressure- Energies: molecular statics- Problems on Molecular Statistics- MD Simulation analysis- Limitations of MD- Application of MD as Case Study: 3D system-Application of MD as Case Study: 2D system

Unit-4 - Monte Carlo Simulations

9 Hour

Introduction of Monte Carlo simulation - Monte Carlo simulation analysis- Limitations of Monte Carlo simulations- Introducing ensembles in MC- Kinetic Monte Carlo- Key concepts: starting structure in KMC- Convergence criteria- Scaling with lattice parameters- Understanding the electronic structure- Electrical conductivity, Excited electron states- Application of MC method as Case Study

Unit-5 - Various Dft Codes for Advanced Modeling

9 Hour

Introduction to various DFT codes - Basic DFT outputs - Basic output of QM code - Energies, electronic structure - Using the energies: molecular statics, MD, MC - Using the energies: MC - Using the electronic structure: optical properties - Transitions between electronic states- Electrical conductivity - Mobility of electrons, scattering of electrons between states - Excited electron states due to thermal (or optical) excitations - Type of bonding - tunneling rates - Excited electron states due optical excitations - Understanding the electronic structure from different Methods, Comparative study- Wave functions, charge density, band structure, density of states- Confinement effect on Electronic Structure-3D, 2D, 1D Carbon based materials as example

Learning	
Resources	

- Jörg-Rüdiger Hill, Lalitha Subramanian and Amitesh Maiti, Molecular modeling techniques in materialsciences, Taylor & Francis/CRC Press: Boca Raton, 2006
- AndrewR.Leach, Molecular modelling: principles and application, Pearson Education, India, 2001
- 3. R. Martin, Electronic Structure: Basic Theory and Practical Methods, 2nd Edition, Cambridge University Press, 2020
 4. J.M. Thijssen, Computational Physics, Cambridge, UK: Cambridge University Press, 2007

earning Assessm	nent		Continuous Loomin	a Assessment (CLA)			
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	Total Total	100)%	100 9	%	100	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Dr. Hemant Dixit, GlobalFoundaries, aplahemant@gmail.com	1. Dr. Ranjit Kumar Nanda, IITM Chennai, nandab@iitm.ac.in	1. Dr. C. Prefer <mark>encial Ka</mark> la, SRMIST
2. Dr. Murali Kota, Global Foundaries, USA, kvrmmurali@gmail.com	n 2. Prof. G.P. Das, IIT M, KGP, msgpd@iacs.res.in	2. Dr. Saurabh Ghosh, SRMIST

Course	01NTE/11T	Course	NANOTECHNOLOGY IN TEXTILES	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	21N1E4111	Name	NANOTECHNOLOGY IN TEXTILES	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	111	4			Progr	am Oı	itcome	s (PO)					rogram
CLR-1:	acquire knowledge on nanotechnology for textile applications	1 2 3 4 5 6 7 8 9 10 11 12		12	Specific Outcomes										
CLR-2:	learn the smart materials and devices for textile industry	eege e e e e e e e e e e e e e e e e e													
CLR-3:	study the various nanostructures for improving the textile yarn and fabric	a di					ning								
CLR-4:	understand the nanomaterials processing for textile industry	Knowle	alysis	udoli	estig/ probl		r and	ج ج ک	h.	Team	ig	∞ర	ä		
CLR-5:	learn various nanodevices for improving the textile fabrics	ering	A	a	.⊆ ×	Tool	engineer sty	ment		al &	mmunication	Mgt.	ng Le		
		9	roblem	sign/d	nduct ir comple)	dern	e en	iron itain	S	ndividual	JIIIL	roject	Long	<u>-</u>	0-2
Course O	outcomes (CO): At the end of this course, learners will be able to:	Engi	Pro	Des	g G	οМ	The	En. Sus	Eth	pul	lo S	Pro	Life	PSO.	PSO.
CO-1:	demonstrate the applications of nanotechnology in textile industry	3	- 5	1	-	-	-7	-		-	-	-	-	-	- -
CO-2:	incorporate the responsive p <mark>olymers</mark> in textile fabric designs	3	-	3	-19	-	4	-	-	-	-	-	-	-	- -
CO-3:	incorporate nanocomposite-based sensors in textile fabrics	3	el rés	42-	2	-	-	i		-	-	-	-	-	
CO-4:	produce the nanocoatings in textile fabrics	3		3	2	_	-	- 1		-	-	-	-	-	- -
CO-5:	create the nanogenerators incorporated nanofabrics	- 15	_ 2	-	Υ-	3		-		-	-	-	-	-	

Unit-1 - Introduction to Smart Textiles

9 Hour

Introduction to smart nanotextiles, Nanotechnology & nanomaterials – Nanofibers, Advantages of nanofibers - Nanofibers fabrication, Electrospinning - Enhancing the mechanical properties, Large scale production of fibers - Formation of yarn & fabric, Moisture management & waterproof – Thermoregulation, Personal protection - Wearables and sensors, Medical care of nanofibers - Nanosols as coating agent, Applications of nanosols in textiles - Photocatalytic and light responsivity of nanosols, Antimicrobials and bioactive systems

Unit-2 - Smart Materials for Textile Industry

9 Hour

Responsive Polymers, Classification of stimuli-responsive polymers - Responsive polymers as sensors, Responsive polymers in drug delivery systems - Responsive polymers in cell application, Responsive polymers-based filters, Nanowires for textiles, Properties of nanowires in textiles - Balancing transparency and conductance, High specific surface area, Direct charge transport path - Oriented assembly of nanowires, Metal conducting nanowires - Conducting polymer nanowires, Oxide semiconducting nanowires - Sulphide semiconducting nanowires, Other semiconducting nanowires - Current and future perspective of nanowires

Unit-3 - Improvements to Textile Yarn and Fabric

9 Hour

Nanocomposites for textiles, Classifications - Structure & properties, Production methods of nanocomposites - Carbon structures, Nanocellulose - Conducting polymers, Nanoparticles, clays & wires - Laminated nanocomposites and fibers, Membranes, coatings, & Hydrogels - Sensing of nanocomposites Actuators of nanocomposites, Antibacterial activity of nanocomposites - Defense applications of nanocomposites Fire protection. Fire retardant materials - Self-cleaning, Energy harvesting of nanocomposites

Unit-4 - Nanotechnology Processes for Self-Cleaning

9 Hour

Photocatalytic self-cleaning, Super hydrophobic self-cleaning - Antibacterial coating, UV-Protection coating - Impregnation, Cross linking method - Flame retardant coatings, Carbon materials - Phase change materials in thermal regulation, Nanowires in thermal regulation - Carbon based conducting coating - Metal based conducting coating - Textiles for flexible solar cells - 3D printable flexible materials

Unit-5 - Nanogenerators in Textiles

9 Hour

Nanogenerators for textiles, working of nanogenartors - Classification of nanogenerators, Piezoelectric, nanogenerators (PENG) - Triboelectric nanogenerators (TENG), Theoretical origin of nanogenerators - Fiber based PENGs, Textile based PENGs - TENGs Classifications, Fibers based TENGs - Textiles based TENGs, 1D materials based TENGs - 2D fabrics for TENGs, 3D woven textile TENGs - Integrating energy harvesting devices, TENGs with solar cells - Magnetic Textile-Solid phase extraction.

Learning Resources
Resources

- Nazire D. Yilmaz, Smart Textiles, Wearable Nanotechnology, Ist Ed., Scrivener Publishing, 2019
- 2. P. J. Brown and K. Stevens, Nanofibers and nanotechnology in textiles, CRC Press, 2007
- Nanotechnology in Textiles: Theory and Application, Jiří Militký and Rajesh Mishra, Elsevier Publications, 2018
- 4. Nanosensors and Nanodevices for Smart Multifunctional Textiles, Andrea Ehrman, Tuan Nguyen, Phuong Nguyen Tri, Elsevier Publications, 2020

Learning Assessm	Bloom's Level of Thinking Continuous Learning Assessment (CLA) Formative CLA-1 Average of unit test (50%) Continuous Learning Assessment (CLA) Formative CLA-2 (50%) (10%)				Summative Final Examination (40% weightage)			
	/6/	Theory	Practice Theory	Practice	Theory	Practice		
Level 1	Remember	20%	20%		20%	-		
Level 2	Understand	20%	- 20%		20%	-		
Level 3	Apply	30%	- 30%		30%	-		
Level 4	Analyze	30%	30%		30%	-		
Level 5	Evaluate	S	NEW TOTAL TOTAL STATE OF	- C	-	-		
Level 6	Create	42.77	[22] [22] [23] [23] [23] [23] [23] [23]		0 -	-		
	T <mark>otal</mark>	10	0 %	00 %	100	0 %		

Course Designers			
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	mmadhu@annauniv.edu		
2. Mr. T.Raajasekar, Allwin Exports, fabric@allwinexport.com	2. Dr.T.S. Natarajan, IIT Tirupati, tsniit@iittp.ac.in	7 Y /	2. Dr. K. Mani Rahulan, SRMIST

Course	24NITE/442T	Course	NANOPHOTONICS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	21N1E4121	Name	NANOPHOTONICS	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Nil	Co- requisite Courses	Nil	Progressive Courses	Nil	
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standar	ds	Nil	

Course L	earning Rationale (CLR): The purpose of learning this course is to:	111	4			Progr	am O	ıtcome	s (PO)					gram	
CLR-1:	understand the fundamentals of light interaction with nanoscale materials	1	2	3	4	5	6	7	8	9	10	11	12		ecific come	
CLR-2: learn the basic concepts of quantum confined materials				of	SI	,	. 1			Work		9				
CLR-3:				Jent	ation	Usage	ъ	٠, ١		Μ		Finance	рu			
CLR-4:	enrich their knowledge on plasmonics and near field optics	Knowle	alysis	evelopment	vestigations c problems		r and	۲ × ×	h.	Team	ţį	∞ర	arni			
CLR-5:	familiarize themselves with nanophotonic fabrication	ering	٩	deve	1.⊑ ∂	Tool	engineer stv	rironment stainability	1	<u>रू</u>	ommunication	Mgt.	g Le			
		9	roblem	ign/d tions	onduct	dern	enc etv	iron t <mark>ain</mark>	S	ndividual	nur	Project	Long	7	7.5	က္
Course O	Outcomes (CO): At the end of this course, learners will be able to:	Engi	Pro	Des	g G	Moc	The	Env	Ethics	Indi	Sol	Proj	Life	PSO-1	PS0-2	PSO-3
CO-1:	apply the principles of Quantu <mark>m confi</mark> nement effects to understand Nanoscale interaction dynamics	3	- 2	1	-	-		-		-	-	-	-	2	-	-
CO-2:	utilize the photonic crystals i <mark>n variou</mark> s applications	3	2	40 745	3	-	4	-	-	-	-	-	-	3	-	-
CO-3:	explore the principles of pla <mark>smonics</mark> to study Near field scanning optical microscopy	3	2	4.	3	-	-	<i>-</i>	-	-	-	-	-	-	3	-
CO-4:	utilize the Near field scanning optical microscopy in data storage applications	2	3	125	2	-	-	-		-	-	-	-	-	2	-
CO-5:	apply the fundamental principles of Near field optical chemical vapor deposition technique for the fabrication of nanophotonic materials		2	1-34	3	-	Č	-		-	-	-	-	-	-	2

Unit-1 – Light Interaction with Nanoscale Materials

9 Hour

Photons and electrons - Similarities and differences - Free space propagation - Confinement of photons and electrons - Propagation through a classically forbidden zone - Photons Tunnelling Localization under a periodic potential - Photons Band gap and cooperative effects of photons - Band gap and cooperative effects of Electrons - Nanoscale optical interactions - Axial and lateral nanoscopic localization - Nanoscale confinement of photonic interactions - Nanoscale confinement of electronic interactions - Quantum confinement effects - Nanoscale interaction dynamics Nanoscale electronic energy transfer - Cooperative emissions.

Unit-2 - Quantum Confined Materials

9 Hour

Quantum confined materials - Inorganic quantum confined structures - Manifestation of quantum confinement - Quantum confined Stark effect - Dielectric confinement effect - Super lattices - Core-shell quantum dots - Quantum wells - Quantum confined structures as lasing media - Organic quantum confined structures - Photonic crystals - Important features of photonic crystals - Applications of Photonic crystals - Dielectric mirrors - Interference filters - Photonic crystal laser - Photonic crystal sensing Photonic crystal fibers (PCFs) - Introduction to metamaterials.

Unit-3 - Plasmonics Principles

9 Hour

Plasmonics - Internal reflection - Evanescent waves - Plasmons and surface plasmon resonance - Attenuated total reflection - Grating SPR coupling - Optical waveguide SPR coupling - SPR dependencies and materials - Plasmonics and nanoparticles - Near-Field Optics - Aperture less near field optics - Near field scanning optical microscopy - (NSOM or SNOM) - Principle Near field scanning optical microscopy - Design and Technique of SNOM - SNOM Applications - SNOM based visualization of waveguide structures - SNOM based energy transport - SNOM based optical data storage - SNOM based optical data recovery.

Unit-4 - Nanophotonic Fabrication

9 Hour

Nanophotonic Fabrication - Adiabatic nanofabrication - Non adiabatic nanofabrications - Conditions for non-adiabatic nanofabrications - Near field optical Chemical Vapour Deposition NFO CVD - Near field optical Chemical Vapour Deposition Philosopy—Design and Technique - Near field photolithography — Philosophy - Near field photolithography Design and Technique - Self-assembling method via optical near field interactions - Regulating the size of nanoparticles - Size dependent resonance - Controlling size of nanoparticles - Alignment of Size controlled nanoparticles - Controlling position of nanoparticles - Alignment of position controlled nanoparticles - Separation of nanoparticles - Alignment of Separated and controlled nanoparticles.

Unit-5 - Nano Biophotonics and Applications

9 Hour

Biophotonics – Nanobiophotonics - The cell and scale - The cell and constituents - Origin of contrast mechanisms - Optical contrast mechanisms - Classical contrast mechanisms - Bright field and dark field contrast - Phase contrast - Inter ferrometric contrast - Fluorescence contrast mechanism - Confocal Microscopy - Nonlinear microscopy based on second harmonic generation - Coherent anti-stokes Raman scattering (CARS) - Reduction of the observation volume - Far field method - 4Pi microscopy Microscopy on a mirror - Stimulated emission depletion (STED).

Learning Resources
Resources

- 1. M.Ohtsu, K.Kobayashi, T.Kawazoe and T.Yatsui, Principals of Nanophotonics, (Optics and ptoelectronics), CRC press, 2008.
- 2. Joseph W. Haus, Fundamentals and Applications of Nanophotonics, Elsevier Science,
- 3. BEA Saleh and AC Teich, Fundamentals of Photonics, John Wiley and Sons, 2007
- 4. Y. V. G.S. Murthy and C. Vijayan, Essentials of Nonlinear Optics, Wiley, 2014

Learning Assessmen	nt							
		J. 17	Continuous Learning	Cumr	notivo			
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	Forma CLA-1 Average (50%	e of unit test	CL	n Learning A-2 0%)	Summative Final Examination (40% weightage)		
		Theory	Practice	Theory	Practice	Theory	Practice	
Level 1	Remember	20%	45 144 144	-20%		20%	-	
Level 2	Understand	20%		20%	3 -	20%	-	
Level 3	Apply	30%	A STATE OF THE STA	30%		30%	-	
Level 4	Analyze	30%		30%		30%	-	
Level 5	Evaluate					-	-	
Level 6	Create	3 1	- JUN	-	- H	-	-	
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Course Designers	- (3)	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
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(Deemed to be University u/s 3 of UGC Act, 1956)

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